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## Advances in Condensed-Matter and Materials Physics Rudimentary Research to Topical Technology

Edited by Jagannathan Thirumalai and Sergey Ivanovich Pokutnyi





# Advances in Condensed-Matter and Materials Physics - Rudimentary Research to Topical Technology

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#### Contributors

Likius Shipwiisho Daniel, Ateeq Rahman, Veikko Uahengo, Elise Shilongo, Serafettin Demic, Yenal Gokpek, Mustafa Can, Ceylan Zafer, Gulsum Ersu, P Kiran, Xian Zhang, Xiaoyang Zheng, Anca Armăşelu, Ljudmila Shchurova, Vladimir Namiot, Wen-Ping Wu, Emanuele Enrico, Luca Fasolo, Angelo Greco, Mohsin Ganaie, Jagannathan Thirumalai

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### Meet the editors



Dr Jagannathan Thirumalai received his Ph.D. from Alagappa University, Karaikudi in 2010. He was also awarded the Post-doctoral Fellowship from Pohang University of Science and Technology (POSTECH), Republic of Korea, in 2013. He worked as Assistant Professor in physics at the B.S. Abdur Rahman University, Chennai, India (2011 to 2016). Currently, he is working as Assistant Professor & Head of the physics department, SAS-

TRA Deemed University, Kumbakonam (T. N.), India. His research interests focus on luminescence, self-assembled nanomaterials, and thin film opto-electronic devices. He has published more than 50 SCOPUS/ISI indexed papers and 8 book chapters and is a member of several national and international societies like RSC, OSA, etc. He has edited two books with IntechOpen publishers. He served as a principal investigator for a funded project on the application of luminescence-based thin film opto-electronic devices, funded by the Science and Engineering Research Board (SERB), India. As an expert in opto-electronics and nanotechnology area, he has been invited as an external and internal examiner to MSc and PhD theses, invited to talk in some forums, and review papers for international and national journals.



Sergey Ivanovich Pokutnyi is a professor of theoretical physics, doctor of physical and mathematical sciences at the Chuiko Institute of Surface Chemistry National Academy of Sciences of Ukraine, Kyiv. His current research interests are theoretical quantum optics and theoretical optical spectroscopy of nanosystems (electron, exciton, and biexciton states); theory of condensed matter (theory of excitons in nanosystems, theory of

local electron states in nanosystems, theory of transfer energy electron excitation states in nanosystems); nanophotonics; nanosystems (search for nanoheterostructures consisting of quantum dots, which could be used to create optical nanolasers working on exciton junctions at room transitions; strongly absorbing light nanostructures containing dielectric, semiconductor quantum dots); and magnetoelectro-optical nanoheterosystems emitting electromagnetic waves in the spectrum of terahertz frequencies.

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# Preface

Our daily lives are in the reign of technology anew. The thirst towards innovation, speed, and miniaturization demands micro and macro structural understanding of materials. Nano science forms a prominent experimental focus in biological systems, chemical sensing, and photonics. Apart from regular solids; superconductors, liquid crystals, soft polymers, and non-equilibrium materials are finding their applications in various fields. The advances in theory are almost confronted in experiments. Thus the need to comprehend the conventional and contemporary information. Hence condensed matter and material science research, which includes thermal, elastic, optical, electrical, and magnetic properties of solid and liquid substances, has provoked such a high impact in recent years.

The rise of matter from an interaction of a large number of atoms and electrons is deciphered in depth. Even the fundamental particles lead to complex behaviors in systems consisting of particles. Advancement in the quantum realm proffers deep knowledge over structure, transport, and utility of solids at the atomic and electronic levels. Some of the experimentally revolutionizing ideas include the Josephson effect, integer and fractional quantum Hall effect, Aharanov-Bohm effect, mesoscopic physics, dissipative quantum physics, high temperature super conductors, and non-linear dynamics. Topological phases of matter, strongly correlated spin-orbit coupled systems, spin liquids and other magnetic systems are some of the quantum streams under exploration. Some outcomes of this knowledge prove some correct and others add on to the conventional material science. Constant review and update is required in such a vibrant field of science to avoid chaos in understanding. This book serves this purpose in a systematic way.

This book consists of ten chapters that are presenting concepts, perspectives, characteristic properties, and its prospects. This book signifies the introduction of the viewpoint on the achievements and their applications, excitons in two-dimensional materials, the excitonic and biexcitonic properties of low dimensional semiconductors, deliberations on electrical and optical behavior of amorphous semiconductor, superconducting Josephson-based metamaterials for quantum limited parametric applications, nanocarbon polymer composites, graphene modified by self-assembled monolayers, molecular dynamics simulation, G-Jitter effects, and compact source of terahertz radiation based on an open corrugated waveguide.

Finally, I would like to thank all the contributors of the chapters in this book for their extreme efforts in the construction of outstanding work. I would like to express my sincere gratefulness to Ms. Dolores Kuzelj, Author Service Manager, for the effective support in the construction of this book.

Jagannathan Thirumalai

SASTRA Deemed University, Thanjavur, Tamil Nadu, India

#### Sergey Ivanovich Pokutnyi

Chuiko Institute of Surface Chemistry of National Academy of Sciences of Ukraine, Kyiv, Ukraine

#### Chapter 1

### Introductory Chapter: The Testimony of Condensed Matter Physics - A Viewpoint on the Achievements and Their Applications

Jagannathan Thirumalai

#### 1. A succinct testimony of advances in condensed matter physics

One of the important topics in the protuberant area of physics is condensed matter physics and it broadly encompasses the microscopic and macroscopic physical properties of materials. In condensed matter physics, the basic laws of general physics include quantum physics laws, electromagnetism, and statistical mechanics. There is a wide variety in the branch of condensed matter physics such as crystallography, metallurgy, elasticity, and magnetism. Again, this condensed matter physics is also known as solid state physics. Thus, basically, condensed matter physics deals with the solid state of substances. The study of condensed matter physics deals with the substances in their obstinate material or solid state by means of crystallography, quantum mechanics, electromagnetism, semiconductors, and metallurgy and looks after the theoretical concepts of materials science and so on. Further, the exploration comprises both crystalline and non-crystalline solids in which the position of atoms is in the form of ordered three-dimensional lattice, such as diamond and sodium chloride, and on the non-crystalline (amorphous) materials in which the position of atoms is more irregular, like in glass, respectively. Studies on condensed matter physics show significant properties in solid materials especially in the atomic scale. The structure and properties of materials in solids are a general subject matter of scientific community for epochs; however, a distinct area moving in the designation of solid state physics and did not materialized in anticipation of the 1940s. One of the largest branches of condensed matter physics is solid state physics. The industrial and solid state physicists developed that and only through the research on solid state materials, the scientific applications and innovations are made conceivable [1–5]. Gargantuan group of people of solid state physicists also transpired in Europe after World War II, more specifically in Germany, England, and the Soviet Union [1–5]. In the Europe and the United States, solid state condensed matter turns out to be a protuberant field based on its systematic explorations into semiconductors, dielectrics, magnetic materials, superconductivity, electron and nuclear magnetic resonance, and its relevant occurrences. However, in the period of Cold War, major researches focused on solid state physics were not limited to only solids, which led some physicists in the 1970s and 1980s to found the field of solid state condensed matter physics, which systematized the universal method used to scrutinize solids, liquids, plasmas, and

Period	Happenings/achievements/folks	Nobel laureates	Ref.
-3000 BC	Stone Age		[1-4]
3000–	-		
500 BC	Iron Age		
500 BC-	Demokritos: idea that an "atom" exists		
Early	Aristotle: all metals are a mixture of sulfur and mercury		
Theories	Revival of the idea of an atom by Newton and others		
ca. 1700	Thomas Newcomen builds the first commercial steam		
Eighteenth	engine to pump water out of mines		
century	Musschenbroek and Kleist developed the Leyden jar, an		
1712	early form of capacitor		
1745	Alois Senefelder invents the lithography printing		
1796	technique		
1799 Nimeteenth	George Medhurst invents the first motorized air		
Nineteenth	compressor		
century	Physics is considered to be "solved" by classical		
1802 1820	mechanics, electromagnetism, and thermodynamics.		
1820	Metallurgy becomes important and is described by empirical laws		
1859	Humphry Davy invents the arc lamp		
1853	Classification of crystal symmetries (Brillouin)		
1855	Edmond Becquerel invents a method for the photovoltaic		
1897	effect, effectively producing the first solar cell		
10)/	Gaston Planté invents the first rechargeable (lead acid)		
	battery		
	Wiedemann-Franz Law (for thermal and electrical		
	conductivity)		
	Hall effect		
	Thomson discovered the electron using a cathode ray tube		
1900	Drude (and Lorentz): classical electron gas in metals	Onnes 1913	
1911	Onnes (and Holst) discover superconductivity in mercury	Van Laue 1914	
1912	Van Laue discovers diffraction of X-rays by crystals	H&L. Bragg 1915	
1913	W.H. & W.L. Bragg use X-rays to analyze crystals	Einstein 1921	
1905	Fundamentals of photoemission (Einstein)	Raman 1930	
1907–1913	Specific heat of solids (Einstein, Debye, and Born)	D., T. 1937	
1920s	Raman scattering	Anderson, Mott, Van	
1925–1928	Electron diffraction (Davisson, Thomson)	Vleck 1977	
1926–1928	Quantum mechanics (Schrödinger, Heisenberg, Pauli, and	Alvén, Néel 1970	
1928–1933	Dirac)	S., B., B. 1956	
1947	Sommerfeld, Pauli: the electron gas with Dirac statistics		
	The quantum theory of an electron in a solid.		
	Band structure (Bloch, Peierls, Brillouin, Van Vleck)		
	Magnetism (Pauli, Landau, Heisenberg, Bethe)		
	Transistor effect (Shockley, Bardeen, Brattain)		
1950s	Development of quantum field theory (Feynman, etc.)	Ginzburg, Leggett,	_
1950	Ginzburg-Landau: phenomenological theory of	Abrikosov, 2003	
Late 1950s	superconductors	Landau 1962	
1956	Theory of interacting electrons in solids (Landau, Migdal)	B.,S., 1994	
1957	Neutron scattering and diffraction (Brockhouse, Shull)	W. Shockley, J.	
1958	Invention of the transistor	Bardeen, and W.	
1960s	Bardeen, Cooper, Schriefer: theory of superconductivity	Brattain	
1970s	Josephson effect of electron tunneling in superconductors	B.,C.,S. 1972	
1972	The understanding of the resistance minimum in metals:	Esaki, Giaever,	
1980	the Kondo effect (Kondo, Anderson 1969)	Josephson 1973	
1982	Density functional theory (Kohn, Pople)	Anderson, Mott, Van	
1985	Theory of liquid crystals	Vleck 1977	
1986	The renormalization group	1998 (Chemistry)	
1988	Superfluid He3 (Lee, Osheroff, Richardson)	de Gennes 1991	
	The integer quantum hall effect	Wilson 1982	
1988	The integer quantum nun erreet		
1988 1991	The fractional quantum hall effect (Tsui, Störmer,	L.,O.,R. 1996	

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Period	Happenings/achievements/folks	Nobel laureates	Ref
	Fullerenes C60 (Curl, Kroto, Smalley)	T, S., L. 1998	
	Discovery of high-temperature superconductivity	1996 (Chemistry)	
	Discovery of the muon neutrino	Müller, Bednorz 1987	
	Giant magnetoresistance	Lederman, Schwartz	
	Carbon nanotubes (Iijima)	& Steinberger, 1988	
	Experimental Bose-Einstein condensation (Ketterle,	Fert, Grünberg 2007	
	Cornell, Wieman)	K., C.,. W. 2001	
2003	Single graphene sheets discovered	Geim, Novoselov	_
2007	Discovery of giant magnetoresistance (GMR)	2010	
2008	Discovery of the mechanism of spontaneous broken	Fert, Grünberg 2007	
2009	symmetry in subatomic physics	Yoichiro Nambu,	
2010	Invention of an imaging semiconductor circuit-the CCD	2008	
2012	sensor	Boyle, Smith, 2009	
2013	Two-dimensional material graphene	Geim, Novoselov,	
2014	Measuring and manipulation of individual quantum	2010	
2015	systems	Haroche, Wineland,	
2016	Discovery-understanding the origin of mass of subatomic	2012	
2017	particles	Englert, Higgs, 2013	
2018	Invention of efficient blue light-emitting diode	Akasaki, Amano,	
2019	Discovery of neutrino (have mass) oscillations	Nakamura, 2014	
	Theoretical discoveries of topological phase transitions and	Kajita, McDonald,	
	phases of matter	2015	
	Decisive contributions to the LIGO detector and the	Haldane, Kosterlitz,	
	observation of gravitational waves	2016	
	Invention-laser physics: optical tweezers and their	Thorne, Barish, 2017	
	application to biological systems	Ashkin, 2018	
	Invention-laser physics: generating high-intensity, ultra-	Mourou, Strickland,	
	short optical pulses	2018	
	Theoretical discoveries in physical cosmology	Peebles, 2019	
	Discovery of an exoplanet orbiting a solar-type star	Mayor, Queloz, 2019	

<sup>1</sup>*Ref.* [1].

<sup>2</sup>*Ref.* [3]. <sup>3</sup>*Ref.* [4].

 $^{4}Ref. [5].$ 

#### Table 1.

Squat historical achievements of condensed matter physics.

additional complex matter [1–5]. Thus, solid state physics forms a theoretical basis of materials science. The main theme of solid state condensed matter physics is the exertion to interpret the well-established microscopic interactions, in many-body systems, into higher-level descriptions containing a smaller number of degrees of freedom. In the recent decades, the sophisticated nature of these protuberant fields has shown interesting properties and concomitant phenomena that frequently insinuate into a bonanza of fundamental physics. Though the viewpoint is mutable persistently with innovative discoveries, the elementary defies in condensed matter physics are to forecast and perceive novel phenomena and its materials properties are frequently assertive at the frontlines of quantum mechanics [2]. Today, condensed matter experiments are mainly deliberated on the nature and structure of condensed state of compact materials where relations between adjacent electrons, molecules, and atoms regulate the solid properties with crystal systems and so on. Also, in physics, condensed matter physics has got a unique niche. Progresses in this field of solid state condensed matter are ever so often important for scientific achievements and for enlightening our ultimate understanding about the nature of materials. A strong revolution instigated its rapid growth in condensed matter physics with strong investigation in physics of scattering, photonics, advanced

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materials physics, surface analysis, low-temperature physics, low-dimensional electronic systems, structure of biological chemistry, and high-temperature superconductors. However, most discoveries and inventions concern the goings-on of short historical achievements of condensed matter physics, as abridged in **Table 1**, with some additional literatures in condensed matter physics, on the basis of historical accomplishments in different eras.

### 2. Topical advancements in recent advancements in the field of condensed matter and materials physics

The recent advancements in the field of condensed matter and aterials physics through fabrication of electronic devices such as computers and mobiles, opto-electronic devices such as fiber optics and lasers with different types, magnetic devices such as magnetic resonance imaging (MRI) and vibrating magneto devices, silicon-based logic and memory bits. The entire perception of contemporary technology is established upon the ideologies of condensed matter and materials physics. Routine things like the building that is made up of electrical wiring, the windowpane, and a refrigerator door equipped with the magnet, are all reliant on the principles resultant from condensed matter and materials physics. Further,

Field	Studies/application	Experiments (examples)
Superconductors	• Iron pnictide superconductor family	• F-doped LaOFeAs [6]
	• <i>Majorana fermions</i> (particles that are their own antiparticle)	• Gauge bosons and Higgs bosons [7]
	• <i>Plutonium</i> -based heavy-fermion systems	• Plutonium, owing to strong electron-electron interactions [8]
	• Superconducting qubits allow arbitrary rotations in the Bloch sphere with pulsed microwave signals, thus implementing arbitrary single qubit gates	• <i>Superconducting qubits</i> are leading candidates in the reach of modern supercomputers [9]
Topological materials	• First example of a conducting material with a nontrivial electronic structure topology	• Weyl metal [10]
	<ul> <li>Isolated quantum many-body systems (statistical and quantum physics)</li> </ul>	• Ultra cold quantum gases [11]
	• Symmetry-protected topological (SPT) phases	Topological defects [12]
	Anyon condensation is the inverse process of passing from C/G to C	• Bose condensation is central to our understanding of quantum phases of matter [13]
Spin liquids	• Nematic Fermi fluids Correlated electron fluids can exhibit a startling array of complex phases, among which one of the more surprising is the electron nematic, a translationally invariant metallic phase with a spontaneously generated spatial anisotropy	• Sr <sub>3</sub> Ru <sub>2</sub> O <sub>7</sub> [14]

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Field	Studies/application	Experiments (examples)
	• Non-Fermi liquids are unconventional metals whose physical properties deviate qualitatively from those of noninteracting fermions due to strong quantum fluctuations near Fermi surfaces	• Non-Fermi liquid, also known as "strange metal," also called the Luttinger liquid [15]
Water science	• Fouling resistant <i>oil-water</i> separation	• Superhydrophilic lithium exchanged vermiculite as a thin coating layer on microfiltration membranes to resist fouling [16]
	• Swimming droplets are artificial microswimmers based on liquid droplets that show self-propelled motion when immersed in a second liquid	• Mechanisms involve self- propulsion, microswimmers, Marangoni stress in the biological systems [17]
	• Wave turbulence on water surface- gravity waves on the surface of an infinitely deep fluid	• Nonlinear Hamiltonian equations govern the water-wave system and describe the premises of the weak wave turbulence theory [18]
Quantum materials & spintronics	• <i>Fracton</i> phases constitute a new class of quantum state of matter	• Emergent topological quasiparticle excitation [19]
	• Quantum spin Hall effect It is a state of matter proposed to exist in special, two-dimensional, semiconductors that have a quantized spin-Hall conductance and a vanishing charge-Hall conductance	• Crystalline solids, and ferromagnet: [20]
	• <i>Quantum anomalous Hall effect</i> Quantized Hall effect realized in a system without an external magnetic field	• Topological structure in many- electron systems and may have potential applications in future electronic devices [21]
	• Quantum Monte Carlo simulations encompass a large family of computational methods whose common aim is the study of complex quantum systems	• Quantum criticality, quantum spin liquid [22]
	• <i>Quantum turbulence</i> -the chaotic motion of a fluid at high flow rates (cooled to temperatures close to absolute zero)	<ul> <li><sup>4</sup>He (He II) &amp; <sup>3</sup>He-B (Type-II SC)</li> <li>[23]</li> </ul>
	• <i>Quantum-thermal fluctuations</i> of electromagnetic waves are the cornerstone of quantum statistics and inherent to phenomena such as thermal radiation and van der Waals forces	• Three manifestations: (a) the Stefan-Boltzmann law, (b) the heat transfer between two bodies, (c) Casimir forces [24]
	<ul> <li>Spintronics encompasses the ever-evolving field of magnetic electronics</li> </ul>	• Switching magnetic moments by spin-polarized currents, and photonic fields [25]
Magnetoelectric (ME)	<ul> <li>Multiferroics are materials that combine coupled electric and magnetic dipoles</li> </ul>	• Magnetoelectric effect, spiral magnetic order [26]

Field	Studies/application	Experiments (examples)
Physics with atoms in an optical lattice and some theorems	• The <i>Fermi-Hubbard model</i> is a key concept in condensed matter physics and provides crucial insights into electronic and magnetic properties of materials	• Key experiments in the metallic, band-insulating, superfluid, and Mott-insulating regimes [27]
	• <i>Nambu-Goldstone modes</i> (NGMs) that govern the low-energy property of the system	• This theorem ranges from high- energy, particle physics to condensed matter and atomic physics [28]
Medical	• Arrhythmogenesis was one of the first biomarkers of particulate matter (PM) cardiovascular toxicity observed in controlled animal studies	<ul> <li>Cardiac arrhythmias, excitable media, spiral &amp; scroll waves, turbulence, nonlinear dynamics [29]</li> </ul>
	• <i>Viral Shells</i> -studied the condensed matter physics to the assembly and maturation of viral capsids [30]	• Three-dimensional morphological subunits in a protein shell of a virus
	• Apiece <i>organism</i> follows its own evolutionary course and it also obeys a set of common ( <i>Newton's law to</i> <i>Neurons</i> ) laws	• Insect flight-physics of behavior (fly must sense its orientation in order to balance in air) [31]
	• Intracellular oscillations and waves- dynamic processes in living cells are highly organized in space and time	• At the interface between physics and biology, the underlying molecular mechanism of spatiotemporal formation remains owing defies [32]

#### Table 2.

List of recent advancements in the field of condensed matter physics and materials physics.

**Table 2** shows the list of recent advancements in the field of condensed matter and materials physics.

#### 3. Conclusion

In summary, condensed matter physics is living in the form of several technical and high-tech challenges in our everyday life. The field of condensed matter and materials physics finds major developments and brings out the rudimentary comprehending toward the concepts, phenomena, and materials that facilitate scientific improvements and leads to entering into a new-fangled epoch, motivated by new competences in the research related to neutron, cyclotron, and synchrotron, probing and imagining in the atomic scale, nano-/micro-fabrication, and supercomputing, etc. These competencies offer prospects to scrutinize the nature of materials at complex levels with degrees of microscopic control that are exceptional. The modern era providing assurances to revolutionize the systematic technological advancements in preparing materials which leads in developing the knowledge elsewhere and through the physics of impeccable coordination the tangible solid materials that develop day-to-day environment. Understanding the basic concepts and techniques in the opto-electronic process provides information about the assemblies of multifaceted atoms and multicomponent materials and phenomena of non-equilibrium, and biological ideologies will stimulate improvements in

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technological scale from micro-/nano-electronics to structure of materials to the field of medicine. The new era retains the possibilities of ground-breaking advancements in condensed matter physics that will subsidize the national security, economic growth, and the excellence of life.

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#### **Conflict of interest**

The authors declare that there is no conflict of interests regarding the publication of this paper.

#### Notes/thanks/other declarations

Nil.

#### Author details

Jagannathan Thirumalai Department of Physics, School of Electrical and Electronics Engineering, Srinivasa Ramanujan Centre, SASTRA Deemed University, Tamil Nadu, India

\*Address all correspondence to: thirumalaijg@gmail.com; thirumalai@src.sastra.edu

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#### Chapter 2

### Excitons in Two-Dimensional Materials

Xiaoyang Zheng and Xian Zhang

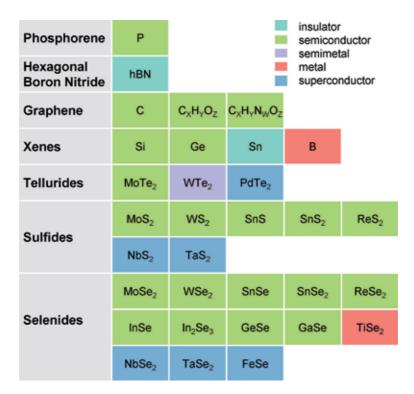
#### Abstract

Because of the reduced dielectric screening and enhanced Coulomb interactions, two-dimensional (2D) materials like phosphorene and transition metal dichalcogenides (TMDs) exhibit strong excitonic effects, resulting in fascinating many-particle phenomena covering both intralayer and interlayer excitons. Their intrinsic band gaps and strong excitonic emissions allow the possibility to tune the inherent optical, electrical, and optoelectronic properties of 2D materials via a variety of external stimuli, making them potential candidates for novel optoelectronic applications. In this review, we summarize exciton physics and devices in 2D semiconductors and insulators, especially in phosphorene, TMDs, and their van der Waals heterostructures (vdWHs). In the first part, we discuss the remarkably versatile excitonic landscape, including bright and dark excitons, trions, biexcitons, and interlayer excitons. In the second part, we examine common control methods to tune excitonic effects via electrical, magnetic, optical, and mechanical means. In the next stage, we provide recent advances on the optoelectronic device applications, such as electroluminescent devices, photovoltaic solar cells, and photodetectors. We conclude with a brief discussion on their potential to exploit vdWHs toward unique exciton physics and devices.

**Keywords:** excitons, two-dimensional materials, semiconductors, heterostructures, optoelectronics

#### 1. Introduction

Since the first 'modern' 2D material, monolayer graphene, was mechanically exfoliated in 2004 [1], the family of 2D materials has been extensively flourishing, covering insulators, semiconductors, semimetals, metals, and superconductors (**Figure 1**). In addition to semimetal graphene, other actively researched 2D materials include wide-bandgap insulator hexagonal boron nitride (hBN) [2], direct bandgap semiconductor phosphorene [3], Xenes (e.g., Monolayers of silicon (silicene), germanium (germanene) and tin (stanene)) [4], and transition metal dichalcogenides (TMDs) with the chemical formula MX<sub>2</sub> (M: transition metal; X: chalcogen) [5]. Compared with bulk materials, 2D materials exhibit some unparallel characteristics: removal of van der Waals interactions, an increase in the ratio of surface area-to-volume, and confinement of electrons in a plane. The change in properties, caused by a reduction in the dimensionality of 2D materials, makes them becoming the promising candidates for next-generation electronics and optoelectronics [6–8].



#### Figure 1.

The gallery of 2D materials.

Whereas these materials are marvelous per se, the more astounding discovery is that these 2D crystals can be combined freely to create layered compounds, paving a way for design of new functional materials and nano-devices [9, 10]. Such designer materials are called van der Waals heterostructures (vdWHs) since the atomically thin layers are not attached through a chemical reaction but rather held together via a weak van der Waals interaction. By stacking together any number of atomically thin layers, the concept provides a huge potential to tailor the unique 2D electronic states with atomic scale precision, opening the door to broaden the versatility of 2D materials and devices. Such stacked vdWHs are quite distinctive from the traditional 3D semiconductor heterostructures, as each layer acts simultaneously as the bulk material and the interface, reducing the amount of charge displacement within each layer. These vdWHs have already gained an insight into the discovery of considerably engaging physical phenomena. For instance, by combining semiconducting monolayers with graphene, one can fabricate optically active heterostructures used for photovoltaic and light-emitting devices [11–13].

Because of the charge confinement and reduced dielectric screening, the optical properties of semiconducting 2D materials are dominated by excitonic effects [14–20]. When a material goes from bulk to 2D, there is less material to screen the electric field, giving rise to an increase in Coulomb interaction and more strongly-bound electron–hole pairs (excitons). In addition, since the excitons are confined in a plane that is thinner than their Bohr radius in most 2D semiconductors, quantum confinement enhances the exciton binding energy, altering the wavelength of light they absorb and emit. These two distinctively physical phenomena naturally make the excitons bound even at room temperature with a binding energy of hundreds of meV [21]. As a consequence, such materials' two-dimensionality makes the excitons easily tunable, with a variety of external stimuli or internal stacking layers, enabling them potential candidates for various applications in optics and optoelectronics.

In this chapter, we provide a topical summary towards recent frontier research progress related to excitons in atomically thin 2D materials and vdWHs. To begin with, we clarify the different types of excitons in 2D materials, including bright and dark excitons, trions, biexcitons, and interlayer excitons. Moreover, we analyze the electronic structures and excitonic effects for two typical 2D materials (i.e., TMDs and phosphorene), as well as the excited-state dynamics in vdWHs. Furthermore, we address how external stimuli, such applied electric fields, strain, magnetic fields, and light, modulate the excitonic behavior and emission in 2D materials. Afterward, we introduce several representative optoelectronic and photonic applications based on excitonic effects of 2D materials. Finally, we give our personal insights into the challenges and outlooks in this field.

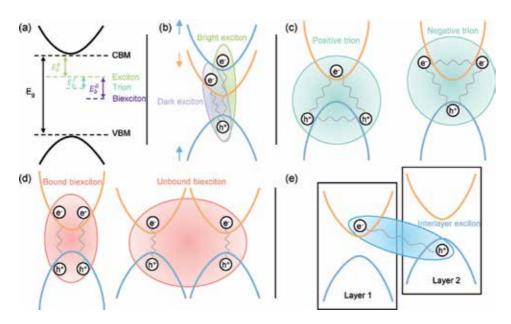
#### 2. Exciton physics in 2D semiconductors and insulators

When the dimension of crystals converts from 3D to 2D, the electronic Coulomb screening is dramatically reduced out of quantum confinement. As a consequence, dielectric constant  $\epsilon$  can fall to  $\epsilon = 1$  from  $\epsilon \gg 1$  in conventional bulk materials [22, 23]. Generally, the binding energies of the strongly bound excitons can reach up to 30% of the quasiparticle (QP) band gap because of the tremendous decrease in dielectric constant, rising to the magnitude of 0.1-1 eV [21, 24]. The large binding energies, which lead to a strong absorption of excitons linking to light, can not only contribute to a substantial modification in the optical spectrum both below and above the QP band gap, but also ensure a long lifetime of excitons in room temperature. Since the large binding energies of excitons in 2D monolayer hBN was initially predicted theoretically in 2006 [25], the research relating to excitons of 2D materials boomed, ranging from monolayer 2D semiconductors and insulators to vdWHs.

#### 2.1 Excitons, trions, biexcitons, and interlayer excitons

Excitons are hydrogen-like bound states of a negatively charged electron and a positively charged hole which are attracted to each other by the electrostatic Coulomb force [26]. It is an electrically neutral quasiparticle that exists mostly in semiconductors, as well as some insulators and liquids, derived from the photoexcitation. Excitons are the main mechanism for light emission and recombination because of their large oscillator strength and enhanced light-matter interaction [27]. When it comes to low-dimension crystals, the types of excitons experience a boom. Weak dielectric screening and strong geometrical confinement mutually contribute to an extremely strong Coulomb interaction, bringing in engaging many-particle phenomena: bright and dark excitons, trions, biexcitons, and interlayer excitons.

Excitons can be bright or dark subject to the spin orientation of the individual carriers: the electron and the hole, as shown in **Figure 2(b)**. If the electron and hole have opposite spins, the two particles can easily recombine through the emission of a photon. These electron-hole pairs are called bright excitons. Whereas if they have the same spins, the electron and hole cannot easily recombine via direct emission of a photon due to the lack of required spin momentum conservation. These electron-hole pairs are called dark excitons becoming promising qubits because dark excitons cannot emit light and are thus unable to relax to a lower energy level. As a consequence, dark excitons have relatively long radiative lifetimes, lasting for over a microsecond, a period that is a thousand times longer than bright excitons and long enough to function as a qubit. By harnessing the recombination time to create 'fast' or 'slow' light, the highly stable, non-radiative nature of dark excitons paves a way for optically controlled control information



#### Figure 2.

Different exciton types in atomically thin nanomaterials and related heterostructures. (a) The schematic for the energy level. (b) Excitons are coulomb-bound electron hole pairs (ovals in the picture): Bright excitons consist of electrons and holes with antiparallel spins, while dark excitons consist of electrons and holes with parallel spins. (c) Trions emerge when an additional electron (hole) joins the exciton. (d) Biexcitons are created from two free excitons with different total momenta. (e) Interlayer excitons appear when electrons and holes are located in different layers.

processing. For instance, according to inducing light emission from dark excitons in monolayer WSe<sub>2</sub>, it is possible to selectively control spin and valley, making dark excitons possible to encode and transport information on a chip [28, 29].

Because of the significant Coulomb interactions in 2D materials, exciton can capture an additional charge to form charged exciton known as trion, a localized excitation consisting of three charged quasiparticles (Figure 2(c)). Compared to exciton, a neutral electron-hole pair, trion can be negative or positive depending on its charged state: a negative trion (negative e-e-h) is a complex of two electrons and one hole and a positive trion (negative e-e-h) is a complex of two holes and one electron. Trion states were predicted theoretically [30] and then observed experimentally in various 2D materials, by means of temperaturedependent photoluminescence (PL) [31] and nonlinear optical spectroscopy [32], and scanning tunneling spectroscopy [33]. Trions play a significant role in in manipulating electron spins and the valley degree of freedom for the reasons below. First, the trion binding energies are surprisingly large, reaching to about 15-45 meV in monolayer TMDs [34-36] and 100 meV in monolayer phosphorene on SiO2/Si substrate [37]. In addition, trions possess an extended population relaxation time up to tens of picoseconds [38, 39]. Finally, trions have an impact on both transport and optical properties and can be easily detected and tuned experimentally [40]. As a consequence, the electrical manipulation and detection of trion, as well as its enhanced stability, make it promising for trion-based optoelectronics.

Biexcitons, also known as exciton molecules, are created from two free excitons. Biexciton configurations can be distinguished from unbound or bound biexciton cases (**Figure 2(d**)). The bound biexciton is considered as a single particle since Coulomb interaction is dominant in this complex; while the unbound biexciton is regarded as two-exciton isolated from each other because

of the predominance of the repulsive Coulomb interaction [41, 42]. Similar to trions stably existing in 2D materials, biexcitons can also exist in room temperature. Among 2D materials, biexcitons were firstly observed in monolayer TMDs [43, 44], followed by predicting their binding energies of biexcitons via computational simulation [45, 46].

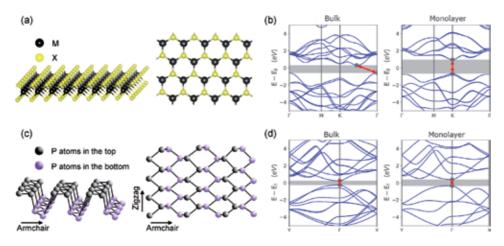
In addition to above-mentioned intralayer excitons, interlayer excitons, where the involved electrons and holes are located in different layers, can also form in bilayer or few-layer 2D materials especially in vdWHs because of the strong Coulomb interaction (**Figure 2(e)**). After optically exciting a coherent intralayer exciton, the hole can tunnel to the other layer forming an incoherent exciton with the assistance of emission and absorption of phonons. Generally, these interlayer excitons occupy the energetically lower excitonic state than the excitons confined within one layer owing to an offset in the alignment of the monolayer band structures [47, 48]. Similar to excitons in one layer, interlayer excitons can also be either bright or dark depending on spin and momentum of the states involved [49, 50].

#### 2.2 Excitons in atomically thin 2D materials

Among 2D semiconductors and insulators, TMDs and phosphorene have drawn tremendous attention owing to their intrinsic band gaps and strong excitonic emissions, making them potential candidates for high-performance optoelectronic applications in the visible to near-infrared regime [51]. The electronic and optical properties of 2D materials rely on their electronic band structure, which demonstrates the movement of electrons in the material and results from the periodicity of its crystal structure. When the dimension of a material degrades from bulk to 2D, the periodicity will disappear in the direction perpendicular to the plane, changing the band structure dramatically. This means by changing the number of layers in the 2D material, one can tune the band structures (e.g., a MoS<sub>2</sub> will become emissive when reducing to monolayer), as well as tailor the binding energies of excitons (e.g., a monolayer 2D material will absorb/emit higher energy light than a bilayer).

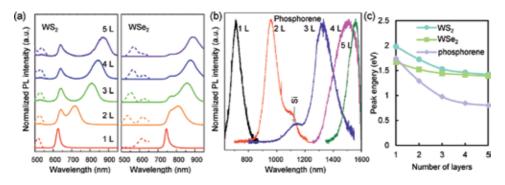
All TMDs have a hexagonal structure, with each monolayer consisting of the metal layer sandwiched between two chalcogenide layers (X-M-X). The two most common crystal structures are the semiconducting 2H-phase with trigonal symmetry (e.g., MoS<sub>2</sub>, WS<sub>2</sub>, MoSe<sub>2</sub>, WSe<sub>2</sub>, as shown in **Figure 3(a)**) and the metallic 1 T phase (e.g., WTe<sub>2</sub>). For the semiconducting 2H-phase TMDs, they are well-known to possess an indirect band gap in bulk crystals; however, when mechanically exfoliated to a monolayer, these crystals experience a crossover from indirect to direct bandgap since the lack of interlayer interaction (**Figure 3(b**)). In addition, a decreasing layer numbers in TMDs attributes to larger absorption energy and strong photoluminescence (PL) emission in the visible spectrum, accompanying with enhanced excitonic effects, because of the reduced electronic Coulomb screening (**Figure 4(a)**) [53].

More importantly, TMDs are time-reversal symmetry but spatial inversion asymmetric. Since the strong spin–orbit coupling, the time-reversal symmetry dictates the spin splitting to have opposite spins at the K and K' valleys of the Brillouin zones, making the excitons in TMDs are called valley excitons, which is different from the transition at the  $\Gamma$  valley in other 2D semiconductors such as phosphorene. As shown in **Figure 5**, the spin splitting is pretty strong in the valence band, in which spin splitting values are calculated theoretically up to 0.15 eV in 2H-MoS<sub>2</sub> monolayer and 0.46 eV in 2H-WSe<sub>2</sub> monolayer [56]. On the other hand, the broken inversion symmetry of TMD systems gives rise to a valley-dependent optical selection rule. This unique characteristic arouses the potential to control valley polarization and electronic valley. In this sense, a valley refers to the region in an electronic



#### Figure 3.

Atomic structures and electronic structures of TMDs and phosphorene: Side view (left) and top view (right) of the atomic structures of the monolayer semiconducting 2H-phase TMDs (a) and of the monolayer phosphorene (c); band structures of bulk and monolayer  $MOS_2$  (b) and phosphorene (d) [52]. Note that the bandgap shows a widening in phosphorene and both a widening and a crossover from indirect to direct bandgap in  $MOS_2$ . Reproduced with permission [52]. Copyright 2019 Ossila ltd.

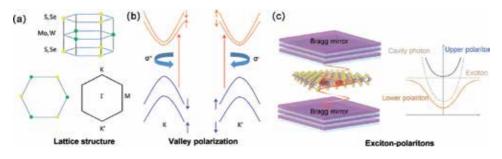


#### Figure 4.

The effects of layer number on the PL spectra and peak energy of TMDs and phosphorene. (a, b) normalized PL spectra of 2H-WS<sub>2</sub>, 2H-WSe<sub>2</sub> and phosphorene flakes consisting of 1-5 layers. Each PL spectra is normalized to its peak intensity and system background [37, 53]. (c) Evolution of PL peak energy with layer number of 2H-WS<sub>2</sub>, 2H-WSe<sub>2</sub>, and phosphorene from (a, b), showing an increase in peak energy as the layer number reduces. (a) Reproduced with permission [53]. Copyright 2012 American Chemical Society. (b) Reproduced with permission [37]. Copyright 2015 Springer Nature Publishing AG.

band structure where excitons are localized; valley polarization refers to the ratio of valley populations; and electronic valley refers a degree of freedom that is akin to charge and spin. As a consequence, optical transitions such as excitons in opposite valleys are able to be excited selectively using light with disparate chirality, paving the way to enable valleytronic devices based on photon polarizations [54, 55].

As shown in **Figure 3(c)**, phosphorene possesses a puckered orthorhombic lattice structure with P atoms distributed on two parallel planes and each P atom is covalently bonded to three adjacent atoms, resulting in strong in-plane anisotropy. Unlike TMDs that exhibit an indirect-to-direct bandgap transition when scaled down from bilayer to monolayer, phosphorene retains a direct band gap all the time, as shown in **Figure 3(d)** [57, 58]. As the layer number decrease from 5 to 1, bandgap energy of phosphorene rises remarkably because of the weaker coupling of the conduction band and the valence band caused by reduced interactions in thinner layers, showing a layer-dependent direct bandgap energies (**Figure 4(c)**). In contrast to TMDs whose PL emission occurs in the visible spectrum, the light emission



#### Figure 5.

Lattice structure, valley polarization, and exciton-polaritons in 2D TMDs. (a) The honeycomb lattice structure of monolayer TMDs, with broken inversion symmetry and the high-symmetry points in the first Brillouin zone. (b) Electronic bands around the K and K' points, which are spin-split by the spin-orbit interactions. The spin (up and down arrows) and valley (K and K') degrees of freedom are locked together. (c) Exciton-polariton states in a 2D semiconductor embedded inside a photonic microcavity. (a, b) reproduced with permission [54]. Copyright 2016 Springer Nature Publishing AG. (c) Reproduced with permission [55]. Copyright 2019 John Wiley & Sons, Inc.

of phosphorene mainly covers the near-infrared spectral regime (**Figure 4(a, b)**). Moreover, its structural anisotropy also strongly affects the excitonic effects and in phosphorene. The results from first-principles simulations demonstrate that excitonic effects can only be observed when the incident light is polarized along the armchair direction of the crystal [59].

To have an impact on excitonic effects and relevant applications, the binding energy of these quasiparticles must be clarified. As schematically illustrated in Figure 2(a), the exciton binding energy is the energy difference between the electronic bandgap  $(E_g)$  and optical bandgap  $(E_{opt})$ . When higher-order excitonic quasiparticles form, more energy, i.e., the binding energy of trion or biexciton, is needed. Thus, the binding energies of exciton, trion and biexciton can be expressed as  $E_b^E = E_g - E_E$ ,  $E_b^T = E_g - E_T$ , and  $E_b^B = E_g - E_B$ , respectively, where  $E_E$ ,  $E_T$ , and  $E_B$  are emission energies of exciton, trion, and biexciton. For the most 2D conductors and insulators, a robust linear scaling law exists between the quasiparticle bandgap  $(E_{\sigma})$ and the exciton binding energy  $(E_b^E)$ , namely,  $E_b^E \approx E_g/4$ , regardless of their lattice configuration, bonding characteristic, and the topological property (Figure 6) [21]. It is worth emphasizing that the results from simulations and experiments cover almost all kinds of popular 2D monolayer semiconductors and insulators, including topological crystalline insulator (TCI) and topological insulator (TI) [60–62], TMDs [21, 63–66], nitrides (MXenes) [67], phosphorene [21, 68], IV/III-V compounds [21], and graphene derivatives [21]. Such an agreement between simulation and experiment results indicates that the linear scaling law can be used effectively to predict the exciton binding energy for all the 2D monolayer semiconductors and insulators. On the other hand, although comparatively lower than exciton binding energies, the binding energies of trion and biexciton in 2D materials is significantly larger than that in quasi-2D quantum wells (1-5 meV) [69]. For example, the binding energies of trion and biexciton in TMDs reach up to 45 meV and 60 meV, respectively [42, 44, 70].

#### 2.3 Excitons in vdWHs

Composed of stacks of atomically thin 2D materials, the properties of vdWHs are determined not only by the constituent monolayers but also by the layer interactions. In particular, the excited-state dynamics is unique, such as the formation of interlayer excitons [47], ultrafast charge transfer between the layers [71, 72], the existence of long-lived spin and valley polarization in resident carriers [73, 74], and

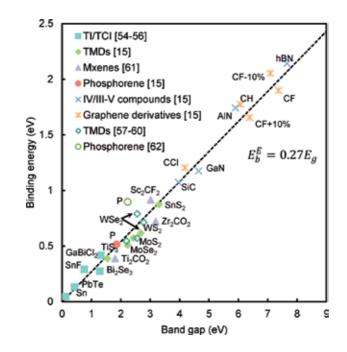


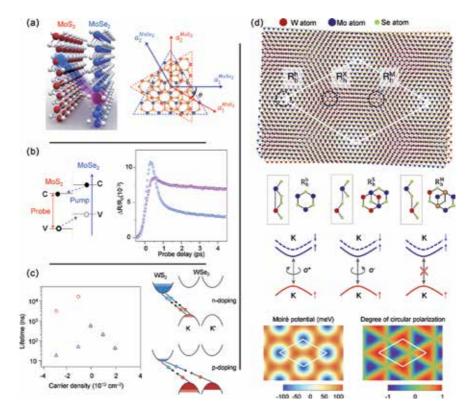
Figure 6.

Linear relationship between quasiparticle bandgap (Eg) and exciton binding energy (E b E). Reproduced with permission [21]. Copyright 2017 American Physical Society.

moiré-trapped valley excitons in moire superlattices in vdWHs [75–78]. In terms of 2D vdWHs, the semiconducting vdWHs composed of stacked TMDC layers are the most widely studied due to their prominent exciton states and accessibility to the valley degree of freedom. More interestingly, the introduction of moiré superlattices (**Figure 7(a)**), a periodic pattern formed by stacking two monolayer 2D materials with lattice mismatch or rotational misalignment, enables to modulate the electronic band structure and the optical properties of vdWHs [79].

After demonstrating the appearance of interlayer excitons in PL spectra, the research on exciton dynamics in vdWHs flourishes. The discovery of intralayer excitons in 2D materials can be traced back to 2015, when long-lived interlayer excitons were demonstrated in monolayer MoSe<sub>2</sub>/Wse<sub>2</sub> heterostructures, where a pronounced additional resonance was observed at an energy below the intralayer excitons [80]. Compared with the intralayer excitons in the weak excitation regime, the PL intensity of this low-energy peak is rather prominent, which attributes to the presence of interlayer excitons as their spectral position is highly occupied. Furthermore, measuring the binding energy of interlayer excitons directly is also demonstrated in WSe<sub>2</sub>/WS<sub>2</sub> heterobilayers, where a novel 1 s–2p resonance are measured by phase-locked mid-infrared pulses [81]. For other excited-state dynamics, such as ultrafast kinetics, long lifetimes, and moiré excitons, some research indicate they have something to do with interlayer excitons [71–78].

Empirically, charge transfer between layers of vertically stacking vdWHs is supposed to be much slow. However, transient absorption measurements, which are implemented by resonantly injecting excitons using ultrafast laser pulse, show a sub-picosecond charge separation in vdWHs: the holes injected in MoS<sub>2</sub> takes 200 fs transferring to MoSe<sub>2</sub> and even only 50 fs transferring to WS<sub>2</sub>, as shown in **Figure 7(b)** [73, 74]. It is noteworthy that this process is reversible, i.e., holes transfer to MoSe<sub>2</sub> on the same ultrafast time scale when excitons are selectively injected in MoS<sub>2</sub> using excitation resonant with the higher-energy exciton feature in MoS<sub>2</sub>.



#### Figure 7.

Excitonic effects in vdWHs. (a) Sketch of MoS<sub>2</sub>/MoSe<sub>2</sub> heterobilayer (left) and its moiré superlattice (right) [10]. (b) Schematic of a pump-probe configuration (left), and time-resolved differential reflection of a MoS<sub>2</sub>/MoSe<sub>2</sub> heterobilayer (blue) and of MoS<sub>2</sub> monolayer (purple) (right) [71]. (c) Comparison between spin-valley lifetime (circles) and hole population lifetime (triangles) under different carrier concentration in MoS<sub>2</sub>/MoSe<sub>2</sub> heterostructure (left), and schematic illustration of the interlayer electron-hole recombination process in electron-doped and hole-doped heterostructures [74]. (d) Moiré superlattice modulates the electronic and optical properties in WSe<sub>2</sub>/MoSe<sub>2</sub> heterostructure: Three different local atomic alignments and their corresponding schematic (top), the moiré potential of the interlayer exciton transition (left lower), and spatial map of the optical selection rules for K-valley excitons (right lower) [76]. (a) Reproduced with permission [71]. Copyright 2016 American Association for the Advancement of Science. (b) Reproduced with permission [71]. Copyright 2014, American Chemical Society. (c) Reproduced with permission [74]. Copyright 2018 American Association for the Advancement of Science. (d) Reproduced with permission [76]. Copyright 2019 Springer Nature Publishing AG.

In addition, another interesting phenomenon is that when mismatching the bilayer vdWHs with different twist angle, the charge transfer signal keeps a constant period within 40 fs, while the recombination lifetime of these indirect excitons varies with the twist angle without any clear trend [82].

In contrast to the ultrafast charge transfer dynamics in vdWHs (<1 ps), spin and valley relaxation dynamics take place on considerably longer timescale [73, 74]. For the two distinctive relaxation processes in vdWHs (i.e., the population decay of optically excited excitons, and the exciton spin–valley lifetime which determines the information storage time in the spin– valley degree of freedom), they both are significantly longer than the monolayer case. For instance, by tuning the carrier concentration, holes' spin–valley lifetime and population lifetime possess a doping-dependent pattern in a WSe<sub>2</sub>/WS<sub>2</sub> heterostructure [74]: in charge-neutral and electron-doped heterostructures (i.e., neutral and positive carrier concentrations), the spin–valley lifetime is closed to the population lifetime; nevertheless, in hole-doping heterostructures (i.e., negative carrier concentration), the spin-valley lifetime becomes orders of magnitude longer than the population lifetime (**Figure 7(c)**). The remarkable dynamics of dopingdependent lifetime attributes to the distinctive interlayer electron-hole recombination process in the heterostructure, as shown in **Figure 7(c)**. In electron-doped or charge-neutral heterostructures, all holes in WSe<sub>2</sub> are pump-generated excess holes; hence, when the hole population decays to zero out of interlayer electron-hole recombination, no holes can remain, let alone valley-polarized holes. The valley lifetime is thus limited by the lifetime of the total hole excess. On the contrary, in hole-doped case, the original hole density is much higher than the photo-generated density, give an equal probability for the recombination of excess electrons in WS<sub>2</sub> with holes from both valleys of WSe<sub>2</sub>.

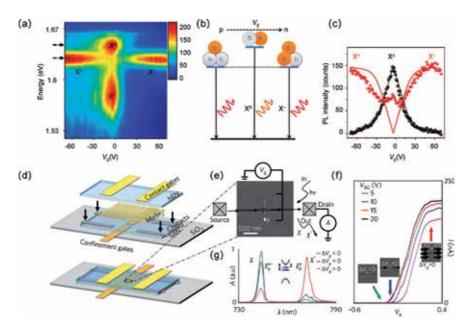
Since 2019, important breakthroughs about excitons in vdWHs has been obtained, especially three independent research simultaneously reporting the observation of moiré excitons in TMDs vdWHs, which lays a firm foundation to the engineering artificial excitonic crystals using vdWHs for nanophotonics and quantum information applications [75–77]. For example, in  $MOSe_2/WSe_2$  heterobilayers with a small twist angle of ~1°, there are three points at which the local atomic registration preserves the threefold rotational symmetry  $\hat{C}3$  in the moiré supercell. The local energy extrema in the three high-symmetry points not only localizes the excitons but also provides an array of identical quantum-dot potentials (**Figure 7(d**)) [75]. The research on moiré excitons in TMDs vdWHs has been promoted after experimentally confirming the hybridization of excitonic bands that can result in a resonant enhancement of moiré superlattice effects.

#### 3. Tuning methods of excitons

To have an impact on industrial applications especially photovoltaics, the binding energies of excitons in 2D semiconductors and insulators must be delicately designed and tuned. More importantly, these common control measures, from electrical to optical methods, function more potently in 2D materials than in 3D materials.

#### 3.1 Electrical tuning

Since the electric field can hardly modulate the dielectric constant in monolayer 2D materials [83], early electrical tuning for excitonic behavior is mostly based on carrier density-dependent many-body Coulomb interactions, namely charged excitons or trions [84, 85]. By increasing electron doping density using different gate voltage (-100 to +80 V) in monolayer MoS<sub>2</sub> field-effect transistors, Mak et al. firstly reported the observation of tightly bound negative trions by means of absorption and photoluminescence spectroscopy [84]. These negative trions hold a large trion binding energy up to ~20 meV, and can be optically created with valley and spin polarized holes. At the same time, Ross et al. also observed positive and negative trions along with neutral excitons in monolayer MoSe<sub>2</sub> field-effect transistors via photoluminescence [85]. The exciton charging effects showed a reversible electrostatic tunability, as shown in **Figure 8(a–c)**. More interestingly, the positive and negative trions exhibited a nearly identical binding energy (~30 meV), implying the same effective mass for electrons and holes. Another work demonstrated continuous tuning of the exciton binding energy in monolayer WS<sub>2</sub> field-effect transistors, finding the ground and excited excitonic states as a function of gate voltage [87].



#### Figure 8.

Electrical tuning of excitons. (a-c) Electrical control in monolayer 2D materials [85]: (a) MoSe<sub>2</sub> PL is plotted as a function of back-gate voltage, showing a transition from positive Trion to negative Trion as gate voltage increases. (b) Illustration of the gate-dependent transitions and quasiparticles. (c) the relationship between Trion and exciton peak intensity and gate voltage at dashed arrows in (a). Solid lines are fits based on the mass action model. (d-g) Electrical control in vdWHs [86]: (d) optoelectronic transport device consisting of hBN/ MoSe<sub>2</sub>/hBN heterostructure. (e) SEM image of a gate-defined monolayer MoSe<sub>2</sub> quantum dot. (f) Typically measured current across the device as a function of local gate voltage  $V_g$  at different silicon backgate voltage VBG. (g) Recombination emission signals of excitons and trions as a function of emission wavelength at different  $V_g$  values. (a-c) Reproduced with permission [85]. Copyright 2013 Springer Nature Publishing AG. (d-g) Reproduced with permission [86]. Copyright 2018 Springer Nature Publishing AG.

The above-mentioned works are related to monolayer 2D materials, while when it comes to heterostructures, the electrical tuning functions more efficiently [86, 88]. Employing a van der Waals heterostructure consisting of hBN/MoSe<sub>2</sub>/hBN (**Figure 8(d, e)**), Wang el al. obtained homogeneous 2D electron gases by controlling disorder in TMDs, which allows for excellent electrical control of both charge and excitonic degrees of freedom [86]. Measuring the optoelectronic transport in the gate-defined heterostructure, they demonstrated gate-defined and tunable confinement of charged exciton, i.e., confinement happens when local gate voltages  $\Delta V_g$  is zero or negative while being absent when  $\Delta V_g$  local gate voltages are positive (**Figure 8(f)**). To further demonstrate controlled localization of charged excitons, they excited the device with a laser source at  $\lambda = 660$  nm, observing both the exciton and trion recombination in PL spectra (**Figure 8(g)**). The ratio between trion and exciton recombination emission declines as  $\Delta V_g$  becomes more negative, because of local depletion of trions as the device transits from the accumulation regime ( $\Delta V_g > 0$ ) to confinement ( $\Delta V_g = 0$ ) and depletion regimes ( $\Delta V_g < 0$ ), respectively.

#### 3.2 Magnetic tuning

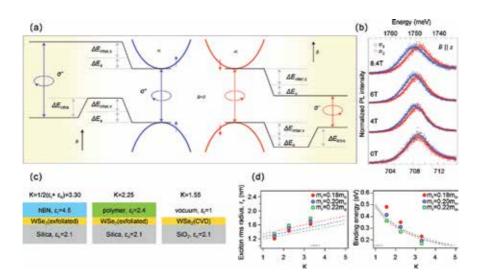
TMDs have drawn more attention with respect to magnetic tuning than other 2D materials, since they preserve time-reversal symmetry with excitons formed at K and K' points at the boundary of the Brillouin zone, which restricts valley polarization. However, when imposing magnetic fields, time-reversal symmetry can be broken, which splits the degeneracy between the nominally time-reversed pairs

of exciton optical transitions at K and K' valley: this is the valley Zeeman effect, as shown in **Figure 9(a, b)** [89, 91–94]. Based on the Zeeman effect, magnetic manipulation is effectively used on valley pseudospin [91], valley splitting and polarization [92], and valley angular momentums [89]. For high-order excitonic quasiparticles, valley Zeeman effect also exhibit significant effects on trions [94] and biexcitons [90] under applied magnetic fields.

In addition, magnetic fields, which change the surrounding dielectric environment, can also have an impact on the size and binding energy of excitons. By encapsulating the flakes with different materials on a monolayer WSe<sub>2</sub>, Stier et al. changed the average dielectric constant,  $k = (\varepsilon_t + \varepsilon_b)/2$ , ranging from 1.55 to 3.0 (**Figure 9(c**)) [95]. The average energy of the field-split exciton transitions was measured in pulsed magnetic fields to 65 T, exhibiting an increasing trend with field which reveals the diamagnetic shift can infer both exciton binding energy and radius. They demonstrated increased environmental screening will enlarge exciton size but reduce exciton binding energy in 2D semiconductors, which shows a quantitatively agreement with theoretical models (**Figure 9(d**)).

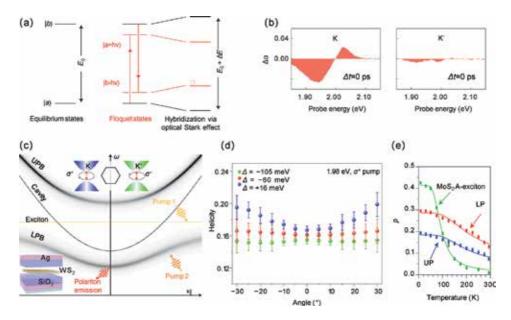
#### 3.3 Optical tuning

To control excitonic effects by breaking time-reversal symmetry in TMDs, imposing an intense circularly polarized light can also achieve the aim based on optical Stark effect, a phenomenon that photon-dressed states (Floquet states) can hybridize with the equilibrium states resulting in energy repulsion between the two states [96, 97],



#### Figure 9.

Magnetic tuning of excitons. (a, b) valley Zeeman effect [89]. (a)valley Zeeman effect in a finite out-of-plane B, the degeneracy between the ±K valleys is attributed to three factors: The spin-Zeeman effect ( $\Delta Es$ ), the intercellular orbital magnetic moment ( $\Delta Einter$ ), and the intracellular contribution from the d ± id orbitals of the valence band ( $\Delta Eintra$ ). The signs of these contributions are opposite in the two valleys. (b) Normalized polarization-resolved PL spectra of the neutral exciton peak as a function of the out-of-plane magnetic field (B), indicating a B-dependent splitting phenomenon via valley Zeeman effect. (c, d) electrical control by surrounding dielectric environment [90]: (c) the surrounding dielectric environments are changing by encapsulating hBN, polymer, or nothing on WSe<sub>2</sub> monolayer on silica substrate, where the average dielectric constant is defined as k = (et + eb)/2 (et and eb are the relative dielectric constants of the bottom substrate and the top encapsulation overlayer, respectively). (d) Exciton root-mean-square (rms) radius rX and exciton binding energy as a function of k (points and lines are the results from experiments and screened Keldysh model, respectively), where me, mr, and ro are the exciton mass, the reduced mass of the exciton, and the characteristic screening length, respectively. (a, b) reproduced with permission [89]. Copyright 2013 Springer Nature Publishing AG. (c, d) reproduced with permission [90]. Copyright 2016 American Physical Society.

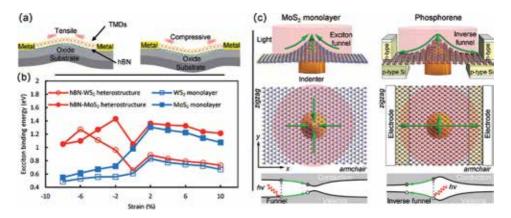


#### Figure 10.

Optical tuning of excitons. (a, b) optical stark effect [96]. (a) Illustration of optical stark effect for two-level system. Ground state  $|a\rangle$  and excited state  $|b\rangle$  can hybridize with Floquet states  $|a + \hbar\omega\rangle$  and  $|b + \hbar\omega\rangle$ , bringing in shifted energy levels. (b) the valley selectivity of the optical stark effect, showing an effect only at K valley by  $\sigma$  – polarization pump pulses. (c–e) valley polaritons via optical pumping [98, 99]. (c) Schematic of the valley polariton phenomena. The lower polariton branch (LBP) and the upper polariton branch (UPB) are the solid curves. The valley-polarization phenomena, caused by the broken inversion symmetry, is inserted in the top. (d) Polariton emission with angle-dependent helicity. Angle-resolved helicity was measured for three detuned cavities  $\Delta$  at the  $\sigma^*$  excitation, where only the positive detuned cavities shows increasing helicity as a function of angle. (e) Exciton-polariton (UP) and lower polariton (LP) branches change with temperature. (a, b) reproduced with permission [96]. Copyright 2014 Springer Nature Publishing AG. (c, d) reproduced with permission [96]. Copyright AG.

as shown in **Figure 10(a, b)**. The interaction between Floquet and equilibrium states can not only bring in a wider energy level separation, but also enhance the magnitude of the energy repulsion if they are energetically close. Based on the optical Stark effect triggered off by circularly polarized light, two independent works demonstrated that the exciton level in K and K' valleys can be selectively tuned by as much as 18 meV in WS<sub>2</sub> monolayer and 10 meV in WSe<sub>2</sub> monolayer, respectively.

Besides, optical control and manipulation have been shown effective towards valley polaritons, a half-light half-matter quasiparticles arising from hybridization of an exciton mode and a cavity mode. Owing to the large exciton binding energy and oscillator strength in TMDs, spin–valley coupling can persist at room temperature when excitons are coherently coupled to cavity photons, leading to a stable exciton-polariton formation [98–101]. Exciton polaritons are interacting bosons with very light mass, and can be independently combined in the intracavity and extracavity field. A schematic of the valley-polariton phenomena is shown in Figure 10(c), where the microcavity structure consists of silver mirrors with a silicon dioxide cavity layer embedded with the WS<sub>2</sub> monolayer. The valley-polarized exciton-polaritons are optical pumped using two pumps to excite the exciton reservoir and the lower polariton branch, showing an angle-dependent helicity because of the excitonic component of the polariton states [98]. In addition, another work based on similar method demonstrates that exciton-polaritons possess a temperature-dependent emission polarization, exhibiting stronger valley polarization at room temperature compared with bare excitons [99], as shown in Figure 10(d).



#### Figure 11.

Mechanical tuning of excitons. (a, b) Exciton binding energies under compressive and tensile strain [103]. (a) Schematics of hBN-TMDs heterostructures nanodevices with tensile and compressive strain. (b) Exciton binding energies of TMD monolayer and hBN-TMD heterostructures as functions of strain. (c) Funnel effect of Excitons under indentation. When an indenter creates an inhomogeneous strain profile that modulates the gap, excitons (in green) in  $MoS_2$  concentrate on isotropically the center, while excitons in phosphorene disperse, especially along the armchair direction [109]. (a, b) reproduced with permission [103]. Copyright 2019 Springer Nature Publishing AG. (c) Reproduced with permission [109]. Copyright 2016 American Physical Society.

#### 3.4 Mechanical tuning

2D materials possess excellent mechanical flexibility, making them stable under high compressive, tensile, and bending strain [102]. Applying mechanical strain on 2D materials, their band gaps will reduce, increase, or transit from direct to indirect, thus resulting in a strain-dependent exciton binding energy [103–108]. Based on density functional theory, Su et al. investigated the natural physical properties of TMD monolayers and hBN- TMD heterostructures, finding that they have distinctive bandgap and exciton binding energy under compressive strain (**Figure 11(a**)) [103]. MS<sub>2</sub> monolayers exhibit direct-to-indirect transition, while hBN-TMD heterostructures keep direct band-gap characters because of the strong charge transfer between hBN and TMD monolayers. With increasing compressive strain, the exciton binding energies of TMD monolayers gradually reduce, but the binding energies of hBN- TMD heterostructures experience a dramatically growth before decreasing (**Figure 11(b**)).

Another mechanical tuning method is by implying heterogeneous strain on 2D materials, which would result in a spatially varying bandgap with tunable exciton binding energy distribution, namely funnel effect [110–112]. In a TMDs monolayer, excitons will move towards high tensile strain region, resulting in a funnel-like band energy profile. In contrast, excitons in phosphorene are pushed away from high tensile strain region, exhibits inverse funnel effect of excitons, which is more-over highly anisotropic with more excitons flowing along the armchair direction (**Figure 11(c**)) [109]. Funnel effect is a rare method for control exciton movement, paving a way for creating a continuously varying bandgap profile in an initially homogeneous, atomically thin 2D materials.

#### 4. Optoelectronic devices

2D materials possess strong light-matter coupling and direct band gaps from visible to infrared spectral regimes with strong excitonic resonances and large optical oscillation strength. Recent observation of valley polarization,

exciton-polaritons, optically pumped lasing, exciton-polaritons, and singlephoton emission highlights the potential for 2D materials for applications in novel optoelectronic devices. Combined with external stimuli, like electrical and magnetic fields, optical pumps, and strain, exciton effects in 2D materials show a highly tunability and flexibility in electroluminescent devices, photovoltaic solar cells, and photodetectors.

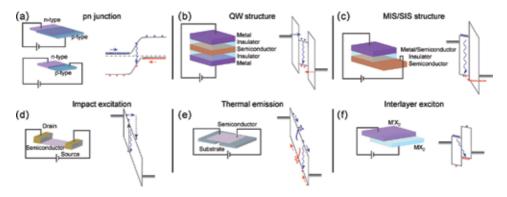
#### 4.1 Electroluminescent devices

Excitonic electroluminescence (EL) emission in 2D materials is key to fully exploiting the EL devices [54, 113]. Based on different carrier injection and transport mechanisms, light-emitting devices have distinctive structures, depending on their mechanism of exciton generation: bipolar carrier injection in p-n heterojunction [114, 115], quantum well heterostructures [116], unipolar injection [117], impact excitation [118], thermal excitation [119], and interlayer excitons [48] (**Figure 12**).

As exciton emission induced by bipolar carrier injection, p-n heterojunction is the simplest device to achieving EL. Depending on the contacting way the two monolayers connect, it can be vertical or lateral. Typical p-n junction is MS<sub>2</sub>/MSe<sub>2</sub> heterostructure, since their counterparts lack the caliber to function effectively [120, 121]. For instance, MoS<sub>2</sub> and WS<sub>2</sub>, in which sulfur vacancies act as electron donors, are often naturally n-type; while WSe<sub>2</sub> and MoSe<sub>2</sub> are typically ambipolar but often unconsciously p-doped by adsorbed moisture [122, 123].

Quantum well (QW) heterostructures consist of semiconductor layer sandwiched between insulator layers and metal electrodes. EL in QW heterostructures can be observed by bipolar recombination of injected electrons and holes in the semiconductor layer when applied a bias in the metal electrodes. Since the long lifetime of carriers and enhanced exciton formation in the semiconductor layer (typical one is TMDs), the emission efficiency of multiple QW devices is much higher than that of single QW devices, and can be improved by preparing alternating layers of TMDs [116, 124].

Unipolar injection happens in a metal-insulator-semiconductor (MIS) or a semiconductor-insulator-semiconductor (SIS) heterostructures when a positive bias applied to the metal and semiconductor layers. The common insulator layer is hBN since its ability to transport holes but block electrons. If the bias is increased



#### Figure 12.

EL device structures and emission mechanisms [54]. (a) Vertical and lateral p-n junctions. (b) Quantum well heterojunction structure. (c) Metal–insulator–semiconductor (MIS) and semiconductor–insulator–semiconductor (SIS) structure. (d) Lateral unipolar device where emission is induced by impact excitation. (e) Locally suspended thermal emission device. (f) Hetero-bilayer device exhibiting interlayer exciton emission. Reproduced with permission [54]. Copyright 2016 Springer Nature Publishing AG.

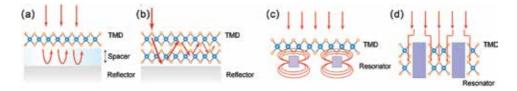
above a threshold, EL will be observed at extremely low current densities below  $1 \text{ nA} \mu \text{m}^{-2}$ , attributed to the unipolar tunneling across the hBN layer, which transfers holes from one metal/semiconductor layer (e.g., graphene and TMDs) to another electron-rich semiconductor layer (e.g., TMDs) [125].

The remaining three emission mechanism is relatively simple. For impact excitation devices, excitons are generated by impact excitation of excitons in the high field regime rather than bipolar recombination. For thermal emission devices, a semiconductor monolayer or few layers are partly suspended on a substrate, and thermal excitation and emission are evoked by locally heating the high current density regime. For bilayer emission devices, emission occurs due to the recombination of electrons and holes residing in the adjacent layers.

#### 4.2 Photovoltaic solar cells

2D materials possess large exciton binding energy with the bandgap ranging from visible to near-infrared part of the spectrum, making them attractive as candidates for photovoltaic solar cells [126, 127]. Light absorption in the active layers of a photovoltaic cell significantly determines device efficiency. To improve light absorption of 2D semiconductor photovoltaics in the ultrathin limit, light trapping designs are need, such as use of plasmonic metal particles, shells, or resonators to amplify photocurrent and photoluminescence. For large area photovoltaic applications, a common strategy is thin film interference, in which a highly reflective metal (e.g., Au or Ag) is used as a part of an "open cavity" to enhance absorption due to multipass light interactions within the semiconductor (Figure 13(a)) [128]. If the semiconductor layer is a monolayer absorber, an atomically thin absorber with  $\lambda/4$  in thickness can be sandwiched between conductor layer and reflector layer, enabling destructive interference at the interface and thus resulting in significant absorption enhancement (Figure 13(b)) [129]. Another strategy to enhance light trapping is by the use of nanostructured resonators, which are coupled to or etched in thin film absorbers (**Figure 13(c, d**)) [130, 131].

Compared with free-standing monolayer with merely 10% absorption [132], the above-mentioned strategy exhibits outstanding strength for TMDC devices. For example, TMD-reflector coupled photovoltaics can have high broadband absorption of 90% and quantum efficiency of 70% [133, 134]. Accompanied with reflector, resonator, or antennas, 2D semiconductor photovoltaics trapping nearly 100% of the incident light may be achieved for nanoscale thick active layers. However, improving light absorption in sub-nanoscale thick monolayers faces more challenging, because not only the low absorption of monolayer (~10%) but also the limited technique to fabricate nanoscopic resonators or antennas [135].



#### Figure 13.

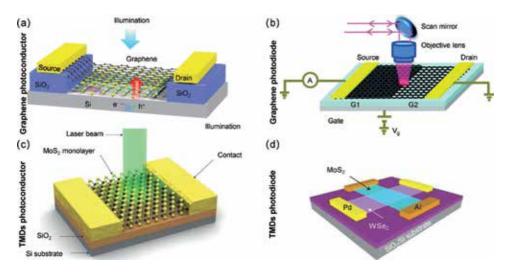
Possible light trapping configurations for enhancing sunlight absorption for Photovoltaics [126]. (a) Salisbury screen-like configuration where a spacer with  $\sim \lambda/4$  thickness sandwichs between a low loss metal reflector and a monolayer absorber. (b) Multilayer vdWH absorber directly placed on a smooth reflective metal reflector. (c) TMD monolayer coupled with resonators/antennas. (d) Multilayer vdWH absorber etched by nanometer scale antennas/resonators. Reproduced with permission [126]. Copyright 2017 American Chemical Society.

# 4.3 Photodetectors

Photodetection is a process converting light signals to electric signals, consisting of three physical mechanisms: light harvesting, exciton separation, and charge carrier transport to respective electrodes. According to the operation modes, photodetectors can be divided into two categories: photoconduction (i.e., photoconductor) and photocurrent (i.e., photodiode) [136, 137]. The former one refers to the overall conductivity change out of photoexcited carriers, and the latter one involves a junction which converts photoexcited carriers into current. Generally, photoconduction-based devices possess higher quantum efficiency than photocurrent-based devices, since transporting carriers can circulate many times before recombination in photoconductors. However, the response in photocurrent-based devices is faster than that in photoconduction-based devices, because of the short carrier lifetime that transporting carriers (electrons and holes) are both involved in the photocurrent generation and recombine with their counterpart after reaching to their own electrodes.

Two common 2D materials used for photodetectors are graphene [138–140] and TMDs (**Figure 14**) [55, 143, 144]. Based on photothermal with weak photovoltaic effect, graphene photodetectors usually show higher dark currents and smaller responsivity, but much wider operational bandwidths. In contrast, TMDs photodetectors operating on photovoltaic effect, exhibiting lower dark currents and higher responsivity.

For graphene-based photoconductors, typical devices are hybrid, adding a light absorption material, such as quantum dots [145], perovskites [146], silicon [147], carbon nanotubes [148], and TMDs [141], as active layer to improve the responsivity. For graphene-based photodiodes, this earliest reported one is metal–graphene– metal photodiodes, in which photocurrent was generated by local illumination of the metal/graphene interfaces of a back-gated graphene field-effect transistor. The



#### Figure 14.

Typical 2D photodetectors. (a) Schematic of a hybrid graphene photoconductor [141]. (b) Schematic of a single-bilayer graphene interface junction, in which photocurrent generation is dominant by photothermoelectric effect [142]. (c) Schematic of monolayer  $MOS_2$  lateral photoconductor [143]. (d) Schematic of vertical p-n photodiode formed by monolayer  $MOS_2$  and  $WSe_2$ , in which a photocurrent hot spot is produced at the heterojunction [120]. (a) Reproduced with permission [141]. Copyright 2017 Springer Nature Publishing AG. (b) Reproduced with permission [142]. Copyright 2009 American Chemical Society. (c) Reproduced with permission [120]. Copyright 2013 Springer Nature Publishing AG. (d) Reproduced with permission [120]. Copyright 2014 Springer Nature Publishing AG. (d) Reproduced with permission [120]. Copyright 2014 Springer Nature Publishing AG. (d) Reproduced with permission [120]. Copyright 2014 Springer Nature Publishing AG. (d) Reproduced with permission [120]. Copyright 2014 Springer Nature Publishing AG. (d) Reproduced with permission [120]. Copyright 2015 Springer Nature Publishing AG. (d) Reproduced with permission [120]. Copyright 2014 Springer Nature Publishing AG. (d) Reproduced with permission [120]. Copyright 2014 Springer Nature Publishing AG.

resulting current can be attributed to either photovoltaic effect [149] or photo-thermoelectric effect [142]. To additionally improve the performance, common structures are graphene–semiconductor heterojunction photodiodes, in which planar junctions of graphene and group-IV elements or other compound semiconductors act as Schottky diodes [150, 151].

For TMD photodetectors, devices can have in-plane or out-of-plane structures, based on the semiconductor layers stacking laterally or vertically. In-plane devices take advantage of better control of the material's properties via electrostatic gating [143]. But out-of-plane devices can bear a much higher bias field (up to ~1 V nm<sup>-1</sup>), enabling a reduced excitonic binding energy in multilayer structures for more efficient exciton dissociations [152]. TMDs-based photoconductors are usually enhanced by illuminating the semiconductor-metal contacts [40] and in short-channel devices [153], and their conductance can be changed by doping and trapping of photogenerated carriers by impurity states [154, 155]. On the other hand, TMDs-based photodiodes exhibit higher tunability based on the photocurrent mode, consisting of an in-plane or out-of-plane junction where a built-in electric field is created [120, 156, 157]. In this situation, electrostatic gates can further tune the device doping levels, owing to the very small interlayer separation (<1 nm) which produces extremely high built-in electric fields (~1 V nm<sup>-1</sup>).

## 5. Summary and perspective

In summary, 2D materials exhibit excitonic effects due to spatial confinement and reduced screening at the 2D limit, resulting in fascinating many-particle phenomena, such as excitons, trions, biexcitons, and interlayer excitons. Enhanced binding energies owing to the strong Coulomb interaction make these quasiparticles easy to characterize and control. In addition, the sensitivity of these quasiparticles to a variety of external stimuli allows the possibility of modulating the inherent optical, electrical, and optoelectronic properties of 2D materials, making them potential candidates for novel optoelectronic applications.

In addition to well-studied 2D materials, such as graphene, phosphorene, and TMDs, the family of 2D crystals is continuously growing, making excitonic effects versatile in different 2D systems. In particular, assembling vdWHs, which now can be mechanically assembled or grown by ample methods, can open up a new route for exploring unique exciton physics and applications. For example, an in-plane moiré superlattice, formed by vertically stacking two monolayer semiconductors mismatching or rotationally misaligning, can modulate the electronic band structure and thus lead to electronic phenomena, such as fractal quantum Hall effect, unconventional superconductivity, and tunable Mott insulators.

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# **Conflict of interest**

The authors declare no conflict of interest.

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# **Author details**

Xiaoyang Zheng and Xian Zhang<sup>\*</sup> Stevens Institute of Technology, Hoboken, New Jersey, United States

\*Address all correspondence to: xzhang4@stevens.edu

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# Chapter 3

# Recent Advancement on the Excitonic and Biexcitonic Properties of Low-Dimensional Semiconductors

Anca Armășelu

# Abstract

Knowing excitonic and biexcitonic properties of low-dimensional semiconductors systems is extremely important for the discovery of new physical effects and for the development of novel optoelectronics applications. This review work furnishes an interdisciplinary analysis of the fundamental features of excitons and biexcitons in two-dimensional semiconductor structures, one-dimensional semiconductor structures, and zero-dimensional (0D) semiconductor structures. There is a focus on spectral and dynamical properties of excitons and biexcitons in quantum dots (QDs). A study of the recent advances in the field is given, emphasizing the latest theoretical results and latest experimental methods for probing exciton and biexciton dynamics. This review presents an outlook on future applications of engineered multiexcitonic states including the photovoltaics, lasing, and the utilization of QDs in quantum technologies.

**Keywords:** excitonic states, biexcitonic states, multiexcitonic states, reduced dimensionality semiconductors, quantum wells, quantum wires, quantum dots, applications

# 1. Introduction

The scientific significance in the field of the physics of excitons comprises both basic research and applied research, this area of physics being one of the most actively studied subjects. The interest in the physics of excitons has raised actively over the past two decades, this interest being provoked by the unique properties of excitons that provide the development's context of optoelectronic and photovoltaic of various device applications such as electrically driven light emitters [1–3], photovoltaic solar cells [4–6], photodetectors [7, 8], and lasers [9–12].

An important concern for the researchers of this field is to obtain a decrease of the dimension of the macroscopic semiconductor systems to nanoscale, this thing leading not only to manufacturing and observing low-dimensional semiconductor structures (LDSs) but also to the emergence and development of new electronic and optical properties that are significantly different from bulk semiconductors properties. Because the essential distinction between low-dimensional semiconductor structures and bulk semiconductor structures can be explained using the terminology of improved excitonic effects that are determined by exciton localization result, it is crucial that, in these quantum-confined materials, the excitonic properties to be better understood and mastered to be able to use them in the development of the innovative and proficient optoelectronic devices utilizing these types of the materials.

Numerous researches have already shown that exploring the excitons' behavior in low-dimensional semiconductor systems can find new ways of controlling the fundamental exciton properties for light generation and light harvesting and finding novel materials for the next-generation high-efficiency excitonic lightharvesting tools at low cost [13–15].

Excitons in low-dimensional semiconductor structures have been widely investigated latterly. A low-dimensional semiconductor structure is a system which presents quantum confinement effects, the movement of electrons or other particles (holes, excitons, etc.) being limited in one or more dimensions.

The promising area of excitonics represents the science and manufacturing of the excitons in disordered and low dimensionality semiconductors (organic semiconductors, hybrid perovskites, colloidal semiconductor nanoparticles) [16–23] and guarantees much quicker efficiency of harmonizing with fiber optics, realizing some novel stages to perform exciton-based computation at room temperatures [24].

It is known that the absorption by a semiconductor of a photon with energy equal to or greater than its bandgap stimulates an electron from the valence band into the conduction band, the vacancy left behind in the valence band being characterized as a hole which is a quasiparticle carrying positive charge. The Coulomb attraction type between these particles with electrical charges of opposite sign provides a quantum structure of electron-hole pair type which is electrical neutral, called exciton. Excitons have numerous characteristics similar to those of atomic hydrogen [25, 26]. Using this type of hydrogen atom model, in crystalline materials, two types of excitons can be discussed in the two limiting cases of a small dielectric constant when the exciton is tightly bound Frenkel-like (the electron and the hole are tightly bound; the Coulomb interaction is poorly screened) in contrast with large dielectric constant when the exciton is weakly bound Wannier-like (the Coulomb interaction is strongly screened by the valence electrons, the electron, and the hole being weakly bound) [27–32]. For a semiconductor exciton named Wannier exciton which has a radius greater than lattice spacing, the effective-mass approximation can be used [33-40].

The entire gamut of low-dimensional semiconductor systems comprises quantum dots (QDs) or zero-dimensional (0D) systems if the excitons are dimensionally confined in all directions, quantum wires (QWRs) or one-dimensional systems (1D) if they are semiconductor nanocrystals in which the excitons are confined only in the diameter direction and quantum wells (QWs), or two-dimensional systems (2D) if the quantum confinement occurs in the thickness direction, while the particle motion is free in the other two directions [41–43].

It has been shown that in the quantum confinement conditions, the size and shape of semiconductor nanocrystals show an influence on the exciton fine structure, this being presented like the mode in which the energetic states of the exciton are divided by crystal field asymmetry consequences and low-dimensional semiconductor structures shape anisotropy [41–50].

Besides the hydrogen characteristics of the exciton, it is known that in QWs, QWRs, and QDs, there are hydrogen atom-like exciton pair-state populations or larger bound systems called biexcitons [25–27, 51–56].

Various researchers have shown that with the rise of the exciton binding energy value in low-dimensional semiconductor systems, the biexciton binding energy

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value with growth confinement is also raised [25, 57–67]. All of the papers in this field have shown that by improving the biexciton creation in reduced dimensional semiconductor structures, the quantum yield (QY) of photovoltaic cells has been enhanced [57, 68–71]. Also, biexcitons are important for quantum-information and computation areas due to their stunning benefit for the creation of coherent combination of quantum states, in this sense being used to find new platforms for the obtaining of future and scalable quantum-information applications such as some greater efficiency non-blinking single-photon sources of biexciton, entangled light sources, and laser based on biexciton states [72–75].

Multiple exciton generation (MEG) in low-dimensional semiconductors is the procedure by which multiple electron-hole pairs, or excitons, are created after the absorption of a single high-energy photon (larger than two times the bandgap energy) and is an encouraging research direction to maximize the solar energy conversion efficiencies in semiconductor solar cells at a possibly much diminished price [76–78]. Numerous studies have shown that the photo-physical properties of MEG are due to the character of inherent multiexciton interaction [79, 80].

This present chapter reviews the recent advancement in the understanding of the excitons' and biexcitons' behavior in LDSs, this fact being important for new experiments and optoelectronic devices.

The second section of this paper comprises three important parts that analyze the way in which the properties of excitons and biexcitons in two-dimensional structures, one-dimensional semiconductor structures, and zero-dimensional semiconductor structures are influenced by the nanometric dimensions case.

The final section recapitulates the fundamental and special issues that have been debated.

# 2. Excitonic and biexcitonic properties in low-dimensional semiconductors

This part of the chapter contains some crucial and novel concepts of excitonic and biexcitonic properties of semiconductor structures of low dimensionality (e.g., QWs, QWRs, QDs) which are relevant for the characterization of the active constituents in advanced tools.

#### 2.1 Excitons and biexcitons in two-dimensional semiconductor structures

This section presents a subject of an enormous significance for the excitons and biexcitons effects in two-dimensional semiconductor structures. In 2005, Klingshirn [25] reported some essence results which emphasize the optical properties of excitons in QWs, in coupled quantum wells (CQWs), and superlattices.

In the last years, in the area of excitons in LDSs, there has been much study which integrates experimental, theoretical, and technical features about the effective-mass theory of excitons and explains numerical procedures to compute the optical absorption comprising Coulomb interaction cases [81–84].

Xiao and coworkers [85, 86] emphasized the case of the excitons functioning in some layered two-dimensional (2D) semiconductors, presenting new different methods of the obtaining of some propitious materials structure (like molybdenum disulfide MoS<sub>2</sub>) with perfect properties for the evolving of the operable optoelectronics and photonics such as light-emitting diodes (LEDs), lasers, optical modulators, and solar cells based on 2D materials. In Ref. [87] the study of the enhanced Coulomb interactions in WSe<sub>2</sub>-MoSe<sub>2</sub>-WSe<sub>2</sub> trilayer van der Waals (vdW) heterostructures via neutral and charged interlayer excitons dynamics is mentioned. In the situation of cryogenic temperatures, an increasing photoluminescence quantum yield in the conditions of the inclusion of a WSe<sub>2</sub> layer in the trilayer composition in contrast with the example of the bilayer heterostructures has been reported.

Owing to the fact that the class of 2D materials presents some distinctive features, which are highly dissimilar in comparison with those of their threedimensional (3D) correspondents, it is used for the next-generation ultra-thin electronics [88]. In this context some researchers explained the role of the expansion of indirect excitons (an indirect exciton—IX—is a bound pair of an electron and hole in separated QW layers [89]), which is observed in vdW transition metal dichalcogenide (TMD) heterostructures at room temperature, this study helping for the progress of excitonic devices with energy-productive computation and ideal connection quality for optical communication cases [90, 91]. Various theoretical and experimental analyses have been developed for the improvement of the excitonic devices that use IXs propagation in different types of single QWs and coupled QWs [92, 93]. Fedichkin and his colleagues [94] studied a novel exciton transport model in a polar (Al, Ga)N/GaN QWs calculating the propagation lengths up to 12  $\mu$ m at room temperature and up to 20  $\mu$ m at 10 K.

In Ref. [95] a theoretical portrayal of the ground and excited states of the excitons for GaAs/AlGaAs and InGaAs/GaAs finite square QWs of different widths is presented which eases the elucidation of the experimental reflectance and photoluminescence spectra of excitons in QWs.

Some works examined new different excitonic properties of the 2D organicinorganic halide perovskite materials showing that this type of perovskite is very qualified to be used for the construction of the photonics devices [96–98] containing LEDs [99, 100], photodetectors [101], transistors, and lasing applications [102]. Wang et al. [103] provided a valuable research about the special characteristics of the long-lived exciton, trion, and biexciton cases in CdSe/CdTe colloidal QWs, proposing a novel model of light harvester with minimal energy losses.

#### 2.2 Excitons and biexcitons in one-dimensional semiconductor structures

One-dimensional semiconductor structures have obtained a remarkable consideration within the last decade. 1D semiconductor nanostructures including wires, rods, belts, and tubes possess two dimensions smaller than 100 nm [104]. Among these types of 1D nanostructures, semiconductor QWRs have been investigated thoroughly for a broad range of materials. This type of 1D nanostructures is used for an essential study due to their exclusive constitutional and physical properties comparative with their bulk correspondents. Crottini et al. [105] communicated the 1D biexcitons behavior in high-quality disorder-free semiconductor QWRs, evaluating the biexciton binding energy value at 1.2 meV.

Sitt and his coworkers [106] reviewed the excitonic comportment of a diversity of heterostructured nanorods (NRs) which are used for a series of applications comprising solid-state lighting, lasers, multicolor emission, bio-labeling, photondetecting devices, and solar cells. In the same work [106], some multiexciton effects are shown, and the dynamics of charge carriers is presented in core/shell NRs with potential applications in the optical gain field and in the light-harvesting section.

For the case of the single crystalline silicon nanowires (SiNWs), which is a key structure for nanoscale tools including field-effect transistors, logic circuits, sensors, lasers, Yang [107] described some excitonic effects and the case of the optical absorption spectra using the Bethe-Salpeter equation.

In Ref. [108] the physical properties of elongated inorganic particles are reported in the case of the nanoparticle shape modification from spherical to rod-like with the help of the exciton storage process. Recent Advancement on the Excitonic and Biexcitonic Properties of Low-Dimensional... DOI: http://dx.doi.org/10.5772/intechopen.90147

# 2.3 Excitons and biexcitons in zero-dimensional semiconductor structures

Zero-dimensional semiconductor structures have captivated a notable interest owing to the fact that the motion is confined in all three directions, the size of a QDs being smaller than or comparable to the bulk exciton Bohr radius [109–112]. In this part of the chapter, some recent progresses in the topic which deals with the excitonic and biexcitonic effects for QDs applications case are emphasized, including computing and communication field, light-emitting devices, solar cells area, and biological domain [113, 114].

Pokutnyi [115–120] realized the foremost theoretical analyses that accurately describe different absorption mechanisms in such nanosystems, discussing many issues related to the complicated interrelationship between the morphology of the zero-dimensional semiconductor structures and their electronics and their optical properties and which help to the progress of novel proficient optoelectronic devices.

Plumhof and his colleagues [121] proved that QDs with an adequately small excitonic fine structure splitting (FSS) can be utilized as some valuable deterministic sources of polarization-entangled photon pairs to improve the building blocks' quality for quantum communication technology.

Golasa et al. [122] presented some new statistical properties of neutral excitons, biexcitons, and trions for the case of QDs which are created in the InAs/GaAs wetting layer (WL), confirming that the WLQDs structure is a useful model to be applied in the area of quantum-information processing applications.

Singh and his team of researchers [123] found a new multipulse time-resolved fluorescence experiment for the CdSe/CdS core/shell QDs case, this work being a crucial spectroscopic procedure which can separate and measure the recombination times of multiexcited state for the proposed sample.

In Ref. [124] a comprehensive review is furnished about the appropriately engineered core/graded-shell QDs revealing advantageous optical properties and unique photoluminescence assets of QDs for liquid crystal displays backlighting technologies and organic light-emitting diode tools. In different papers which have to do with the quantum dot-based-light-emitting diodes (QD-LEDs) results [124–127], it is mentioned that for the improvement of the QD-LED performance, two processes must be diminished: trapping of carriers at surface defects and Auger recombination of excitons.

Important studies reveal many novel and interesting experimental and theoretical results on LDSs exhibiting high quantum yield as a result of MEG occurrence with the aim of the improvement of the solar devices field. Considering that Shockley and Queisser determined a basic threshold value for the efficiency of a traditional p-n solar cell of 30%, these essential results prove that there is a possibility to exceed the Shockley-Quiesser threshold employing quantum effects for a recently developed low-cost third-generation solar cell [77, 128–130].

#### 3. Conclusions

In recent decades, low-dimensional semiconductor structures have become one of the most dynamic research areas in nanoscience, the excitons showing some notably novel attributes due to confinement consequence case. In this chapter a review of some modern experimental and theoretical discoveries on excitonic and biexcitonic effects in low-dimensional semiconductors is presented. The paper furnishes an outstandingly multipurpose excitonic aspect of the optoelectronic applications field, including photodetectors and opto-valleytronic tools, computing and communication domain, and light-emitting devices. Advances in Condensed-Matter and Materials Physics - Rudimentary Research to Topical...

# **Author details**

Anca Armășelu Faculty of Electrical Engineering and Computer Science, Department of Electrical Engineering and Applied Physics, Transilvania University of Brasov, Brasov, Romania

\*Address all correspondence to: ancas@unitbv.ro

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# **Chapter 4**

# Study of Morphological, Electrical and Optical behaviour of Amorphous Chalcogenide Semiconductor

Mohsin Ganaie and Mohammad Zulfequar

# Abstract

Amorphous chalcogenide semiconductor plays a key role in search for novel functional materials with excellent optical and electrical properties. The science of chalcogenide semiconductor (CS) show broad spectrum of soluble alloy and a wider band gap device that access the optimal energy bandgap. The electronic properties of these alloys can be tuned by controlling the proportion of (S, Se, Te). The chalcogenide semiconducting (CS) alloys are promising candidates because of low band gap (1.0-1.6 eV) and high extinction coefficient in the visible region of solar spectrum. The band structure of amorphous semiconductor governed the transport properties and evaluates various factors such as Tauc gap, defect states, mobility edges. In the extended and localized state of amorphous semiconductor an electron goes various transition, absorption/ emission, transport which is due to drift and diffusion under DC electric fields. CS, including sulfides, selenides, and tellurides, have been broadly utilized in variety of energy conversion and storage devices for example, solar cells, fuel cells, light-emitting diodes, IR detector, Li/Na-ion batteries, supercapacitors, thermoelectric devices, etc. Here, we report various morphological electrical, structural, and optical properties of InSeS thin films prepared by Melt Quenching thermal evaporation technique.

**Keywords:** amorphous chalcogenide semiconductor, electrical properties, optical properties

### 1. Introduction

Solid can be found to prepare either in crystalline state (periodic) or in noncrystalline (disordered) state on the basis of their atomic-scale structure. The crystal has periodicity in its atomic structure and exhibit a property called long-range order or translational periodicity; positions repeat in space in a regular array to an infinite extend, as shown in **Figure 1a**. While non-crystalline state is disordered structure, does not possess long range order (or translational periodicity) as indicated in **Figure 1b** [1, 2], and also do not exhibit any discrete diffraction pattern [3, 4].

The non-crystalline solid is further divided into glassy and amorphous, which does or does not have glass transition temperature respectively [5]. The terms amorphous and non-crystalline are synonymous under this definition. The term

glassy have the same structural meaning; and has been reserved for amorphous solid, which have been prepared by melt-quenching and exhibits a glass transition. Whereas amorphous refer to non-crystalline material that can only be prepared in thin film form on glass substrate, which are sufficiently cool to prevent crystallization. Glassy materials are sub-set of amorphous solids; all glasses are amorphous but all amorphous are not necessarily glasses [6, 7].

Furthermore, the structure of amorphous materials is neither periodic as that in crystal nor completely random as that in gas. Short range order similar to crystalline materials exist in these disordered solids. The amorphous solid extend a vast range between completely perfect and completely random structure. An amorphous material does not take a definite phase, but is meta-stable or quasi-equilibrium.

The thermodynamic of liquid–solid transition is that when liquid is cooled, two events may occur either crystallization may take place at melting point Tm or the liquid will become supercooled for the temperature below Tm. As the temperature of supercooled is decreases the viscosity increases and ultimately reaches a value, which is typically of solid ( $\approx 10^{14.6}$  poise), at this stage liquid is said to be in glassy state. These changes can be observed by monitoring the change in its volume as a function of temperature as shown in **Figure 2**. The crystallization process is

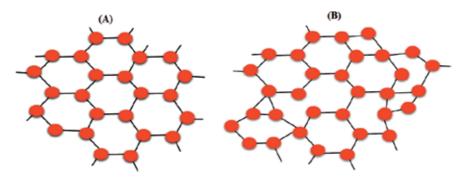
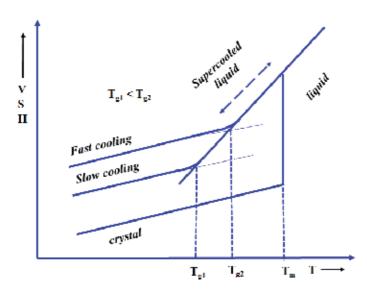


Figure 1. Comparison of short-range order in crystal (A) and non-crystal (B).



#### Figure 2.

Schematic illustration of change in volume with temperature, effect of cooling rate on glass transition temperatures is also shown.

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manifested by an abrupt change in the thermodynamic variable at melting temperature Tm, which is discontinuous process. Whereas glass formation is characterized by a gradual break in the slope is a continuous process, and the region where this transition occur is known as glass transition temperature Tg. Other thermodynamic variables such as entropy (S) and enthalpy (H) exhibits a similar behavior with change in temperature. In the temperature interval between Tm and Tg2, the liquid is referred to as the undercooled or supercooled [8]. The glass transition temperature Tg is different for different cooling rate, it is found that, slower the rate of cooling, the larger is the region for which the liquid may be supercooled. Thus, the glassy transition temperature of a particular material is not an intrinsic property, but depends on the thermal history of the materials. According to the nucleation theory, a liquid with a high viscosity between Tm and Tg typically exhibits a high glass forming ability with a low critical cooling rate for glass formation [9]. Thus, the glass formation is a matter bypass crystallization and nearly all materials can be prepared in a glassy state, if cooled fast enough [10, 11].

The electronic density of states in crystal is well defined by block wave function which extends throughout the solid; therefore the wave vector k is helpful in describing the electronic behavior and band gap in crystalline semiconductor. However, the definition of the band gap is not as straightforward for amorphous semiconductors, since there is no well-defined density of states, but there exist a continuous range of states with in the energy level. Due to the disorderness which causes the localization of electron, i.e. the wave function is confined within a small volume. Thus, the Shape of wave function of electron in crystal and non-crystal are extended and localized respectively. Consequently, their charge mobility in amorphous is smaller than that in crystal. The lattice vibration are also extended and localized in crystal and non-crystal, which give higher and lower thermal conductivities. This characteristic difference between the electronic band structure of crystalline and non-crystalline solids plays an important role in the electrical and optical properties. Also, their conductivity cannot generally be increased appreciably by the incorporation of impurities, because the impurity atom can satisfy only the valence requirement. Large fluctuations exist in the local arrangement of atoms, which can accommodate an impurity without leading to an extra electron or hole, thus exerting little effect on electrical properties. Due to disorderness in amorphous semiconductors it was believed that there is no use of these materials for technological applications [12, 13].

In 1955, Kolomiets and Gorunova from Ioffe Institute USSR [14], who discover the first semiconducting glass TlAsSe<sub>2</sub> [15] in the system Tl<sub>2</sub>Se.Sb<sub>2</sub>Se-TlSe.AsSe<sub>3</sub>. The investigation of Kolomiets, large number of chalcogenide glasses with varying Stoichiometry and composition can be synthesized. Later, in 1968, Ovshinsky and his co-workers [16] from Energy Conversion Devices discovered the memory and switching effects exhibited by some chalcogenide glasses. This shows that there is transition from crystalline phase to amorphous phase and back by switching the electric pulse, they called these materials as phase change materials. The switching effect consists of a sharp transition from high resistivity to low resistivity of the material, when an enough large electric field is applied. The observed switching process was reversible and could be repeated many times. Kolomiets and Nazarova [17] generalized that the amorphous semiconductors are always intrinsic and their conductivity cannot be affected with doping.

Ovshinsky, Fritzsche et al., and Kastner reports indicate that drastic change can be achieved in conductivity and activation energy by suitable preparation technique [18, 19]. Amorphous semiconductor can serve as stable infrared transmitting materials, which can use as optical materials for military purposes as lenses in night goggles, photovoltaic solar cells with high efficiencies [20, 21]. They have a wide range of photo-induced effects having a majority of applications. After this a new effect has been observed such as photo doping radiometry, holography, optical memory effect having a huge potential application for imaging and electrophotog-raphy (Xerography).

More recently, the thin film form of these materials have gained much interest due to their structural, morphological and transport properties for their considerable use in various technological purposes. II–VI group semiconductor materials, plays a prominent part in the modern material science and technology and also for fabrication of large area arrays sensors, interface items, photo conductors, anti-reflector coating, IR detectors, optical fibers, etc. [22, 23]. The binary alloys of amorphous semiconductor are technologically important materials due to their direct and rather large gap [24]. These materials can be engineered for better application purpose by varying the composition parameter.

## 2. Classification and preparation of amorphous semiconductors

Amorphous semiconductor can be classified as tetrahedral-bonded Si like a material such as amorphous hydrogenated silicon (a-Si-H) and related alloys like Si-Ge:H which is four fold coordinated and leads to the symmetrical bonding and also result in the formation of rigid structure having a wider application in thin film transistor, photovoltaic, sensors etc. The second class includes Chalcogenide glasses which have at least one chalcogenide atom, VI group of periodic table (S, Se, and Te) as their major constituent. The four-fold coordination of Si leads to the formation of highly symmetrical and rigid structures. On the other hand, twofold coordination in chalcogens is highly asymmetrical and the structure gives rise to greater degree of flexibility. Thus, the structure of chalcogenide is more complex than that of tetrahedral-bonded Si like material. Chalcogenide semiconductors consist of chain or ring like structures and have lone pair, so they are also called lone pair semiconductor. The oxygen is excluded in chalcogenide group which form a special class of material called as semiconducting oxide glasses. The present monograph is dedicated to the second group of materials, i.e., amorphous chalcogenide semiconductor. The classification of amorphous semiconductor is shown in Table 1.

The electronic density of states in crystal is well defined by block wave function which extends throughout the solid; therefore the wave vector k is helpful in describing the electronic behavior and band gap in crystalline semiconductor. However, the definition of the band gap is not as straightforward for amorphous semiconductors, since there is no well-defined density of states, but there exist a continuous range of states with in the energy level. Due to the disorderness which causes the localization of electron, i.e., the wave function is confined within a small volume. Thus, the shape of wave function of electron in crystal and non-crystal are extended and localized respectively. Consequently, their charge mobility in amorphous is smaller than that in crystal. The lattice vibration are also extended and localized in crystal and non-crystal, which give higher and lower thermal conductivities. This characteristic difference between the electronic band structure of crystalline and non-crystalline solids plays an important role in the electrical and optical properties. Also, their conductivity cannot generally be increased appreciably by the incorporation of impurities, because the impurity atom can satisfy only the valence requirement. Large fluctuations exist in the local arrangement of atoms, which can accommodate an impurity without leading to an extra electron or hole, thus exerting little effect on electrical properties. Due to disorderness in amorphous semiconductors it was believed that there is no use of these materials for technological applications.

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Tetrahedrally bonded semiconductor		Amorphous chalcogenide semiconductor		Semiconducting oxide glasses
С	InSb	S	Cd-Se-S	V <sub>2</sub> O <sub>5</sub> -P <sub>2</sub> O <sub>5</sub>
Si	GaAs	Se	In-Se-S	MnO-Al <sub>2</sub> O <sub>3</sub> -SiO <sub>2</sub>
Ge	Si-Ge:H	Te	MWCNT/SeTe	V <sub>2</sub> O <sub>5</sub> -PbO-Fe <sub>2</sub> O <sub>3</sub>

Table 1.

Classification of amorphous semiconductor.

Amorphous solid can prepared from all phases of matter, solid, liquid or vapor as starting materials, but the deposition from vapor or liquid phases are more considerable. Since amorphous solid are less thermodynamically stable (it possesses a greater free energy). The preparation of amorphous material can be regarded as the addition of excess of free energy. Many preparation techniques are possible, depending on what kinds of materials are required for research and/or applications. Melt quenching is one of the oldest techniques use to prepare amorphous solid especially, bulk glasses. When thin films are required different techniques are used such as, thermal evaporation, chemical vapor deposition, Gel desiccation, Electrolytic deposition, Sputtering, Chemical reaction, Reaction amorphization, Irradiation, Shock-wave transformation, Shear amorphization, Glow discharge decomposition. In this thesis, thermal evaporation technique is used for the preparation of amorphous semiconductors in thin film form under a vacuum of  $10^{-6}$  Torr.

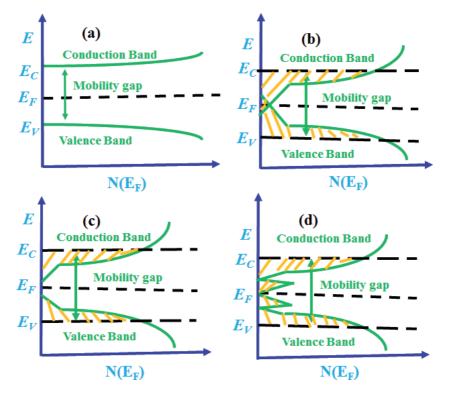
# 3. Band models of amorphous semiconductors

The significance of the band theory is used to explain or predict the properties of materials like electrical and optical. The band itself denotes the number of electronic states per unit energy per electron. In case of crystalline solid, the band diagram is represented in **Figure 3a**, which shows two results, Sharpe definite edges where the density of states decreases to zero and the wave function is extended throughout the solid. Band theory of amorphous semiconductor was first explained by Mott [25]. Based on Anderson's theory [26] sufficiently large amount of disorder results in the localization of all electronic states in the band. These localized states do not occupy all the energy states in the band, but form a tail above and below the band. The localized and delocalized regions (tail states) can be found separately by the mobility edge.

Several models have been proposed to account for the high density of defect level and also for the band structure of amorphous semiconductors, where the energy distribution and density of states (DOS) is main concerned. The existence of localized states in the tails of valence band and conduction band and of a mobility edge separating the extended states from the localized states.

#### 3.1 Cohen-Fritzsche-Ovshinsky (CFO) model

In 1969, the energy state described by Cohen, Fritzsche and Ovshinsky [27] assumed that tail states exist across the gap that separates the localized states from the extended ones. In their energy band model, the disorder is sufficiently high that causes conduction and valence band tails overlap in the mid gap leadings to appreciable density of states in the overlapping band, **Figure 3b** shows CFO model.



#### Figure 3.

Schematic density of states diagrams for amorphous semiconductors. (a) Crystalline semiconductor, (b) Cohen-Fritzsche-Ovshinsky model, (c) Davis-Mott model showing a band of compensated levels near the middle of the band gap, and (d) Marshall and Owen model [19].

There is a sharp mobility edges in each band that separate the extended states from the localized states. As a result of band overlapping redistribution of electron must take place which form filled states in the conduction band tail, which are negatively charged and empty states in the valence band which are positively charged. The CFO model was especially proposed to understand the electrical switching properties in chalcogenide glasses. The primary objection to the CFO model is the high transparency observed in the chalcogenide glass, below a well-defined absorption edge.

#### 3.2 Davis and Mott (DM) model

Davis and Mott [28] suggest a model for electrical conduction in amorphous solid in which tail of localized states should be narrow and should extend a few tenths of an electron volt into the forbidden gap. Defects in the random network such as dangling bonds, vacancies etc., give rise to the band compensation level near the middle of the gap. The central compensated band may be spilt in to a donor and accepter band results in the pinning of Fermi level at center. It was suggested by Mott that as the transition from extended to localized states, mobility drop by several order of magnitudes producing mobility edge. **Figure 3c** shows Davis Mott model, here  $E_C$  and  $E_V$  represent the energies at  $E_C$  and  $E_V$  act as pseudo gap and define as a mobility gap.

Deviation from the 8-N rule will raise the topological defects, unsatisfied, or broken, or dangling bond, these kinds of defects should presents in large quantities of amorphous network. Anderson postulated [29] that negative effective correlation Study of Morphological, Electrical and Optical behaviour of Amorphous Chalcogenide... DOI: http://dx.doi.org/10.5772/intechopen.90512

energy, or negative –U, centers in these amorphous chalcogenide semiconductors is due to the strong electron–phonon coupling.

Marshall-Owen [30] modified the Davis-Mott model suggested that the position of Fermi level is determined by well separated band of donor and acceptor level with some overlapping in the upper and lower halves of the mobility gap respectively **Figure 3d**. The self-concentration of the donor and acceptor takes places in such a way that Fermi-level remain in the mid of the gap.

#### 3.3 Street and Mott model

Based on Anderson's idea, Street and Mott [31] proposed the model of charged defects states, instead of neutral dangling bonds in the band gap region around the Fermi level in amorphous chalcogenide materials. A bond is transferred from one chalcogenide atom to another resulting in two defects: one negatively charged, and other positively charged, labeled respectively ( $D^-$  and  $D^+$ ), D stand for atom having dangling bond. These ( $D^-$  and  $D^+$ ) exist in a more stable way than neutral  $D^0$ . It is proposed that the reaction is isothermal, and exothermic in nature. These charged defects states are electron-spin resonance (ESR) inactive, because all electrons are paired. This model assumes that electron–phonon interaction makes electron pairing energetically favorable at defects.

$$2 D^0 \rightleftharpoons D^+ + D^- \tag{1}$$

This model successfully explains variety of external induced phenomena in chalcogenide semiconductor such as photoconductivity, thermal process, luminance etc.

#### 3.4 Kastner Adler and Fritzsche (KAF) model

Later on Kastner, Adler and Fritzsche [32] proposed a model know a valencealternation pair (VAP) for the formation of over-coordinated defects through the involvement of lone-pair electron. Amorphous chalcogenide are therefore called lone-pair (LP) semiconductors. The tetrahedrally bonded amorphous chalcogenide semiconductor only two of the three p orbitals can be utilized for bonding, which split into the bonding ( $\sigma$ ) and anti-bonding ( $\sigma^*$ ) molecular states, that are subsequently broadened into the valence and conduction bands respectively. One normally finds chalcogens in twofold coordination. This leaves one non-bonding electron pair, termed lone pair (LP), these lone-pair, electrons form a band near the original p-state energy.

Emin [33], in 1975, proposed that charge carriers in amorphous semiconductor may enter self-trapped states (small-polarons) which is due to the polarization in the surrounding lattice. Emin suggest that the presence of disorder tends to slow down the carriers, which may leads to the localization of carrier in that states. Emin explain various experimental data of amorphous semiconductors such as thermos-physics, Hall-mobility, DC conductivity in the framework of exciting polarons theories.

#### 4. Preparation of amorphous semiconductors

#### 4.1 Melt-quenching technique

Melt quenching is one of the oldest technique use to prepare amorphous solid especially bulk glasses, In this method a melt is rapidly cooled by simply turning off the furnace, or rapid cooling in ice cooled water or liquid nitrogen depending upon the required cooling rate. Upon cooling a liquid below its melting point it will crystallize to form glasses. Amorphous material is formed by the process of continuous hardening (i.e., increase in viscosity) of the melt. An essential feature of glass formation from melt is fast cooling which prevent nucleation and growth [34].

The constituent elements having high purity (99.999%) with desired compositional ratio, according to their atomic mass ratio have been weight using electronic balance least count ( $10^{-4}$  gm.) were sealed in Quartz ampoules and maintaining a vacuum of order ( $10^{-6}$  Torr). The flow chart for the preparation of amorphous semiconductor is given in **Figure 4**.

The sealed ampoules were then placed in a rocking furnace where continuous heating is done at rate of 4–5 K/min to ensure the homogenization of the melt. In case of amorphous semiconductors materials, an ice cooled water is used to produce the glassy state. The quenched samples were removed by breaking the quartz ampoules. The obtained shiny bulk samples are grinded into fine powder using pastel and mortal.

#### 4.2 Thermal evaporation technique

This technique is mostly use for the preparation of materials in thin film form, in which a material to be evaporated is placed in a boat. Schematic diagram of vacuum chamber is shown in **Figure 5**. Vacuum chamber containing molybdenum boat, where the source material is placed. The boat is connected with high voltage potential difference through which boat can be heated till the material is evaporated. The material which is placed in the boat must have low melting point than the molybdenum, which can evaporate easily and uniformly spread on substrate.



#### Figure 4.

Design flow chart for preparation of bulk amorphous samples.

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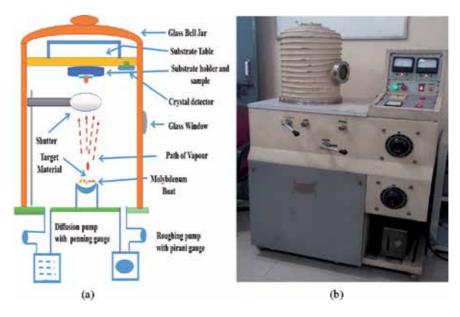


Figure 5.

(a) Schematic diagram of thermal evaporation technique (b) photograph of thermal evaporation coating unit to be used.

The evaporation rate can be controlled with the help of shutter, which is located above the boat and the thickness of the deposited film can be controlled with the help of single crystal thickness monitor, which is mounted near the sample holder.

The evaporation is performed in a vacuum to avoid the contamination; chamber is evacuated by diffusion pump and backed by rotary pump. The rotary pump used to evacuate the chamber to a pressure within the operating range of a diffusion pump; this is known as rough vacuum. Once the chamber reached at the vacuum equal to  $10^{-3}$  Torr. An oil diffusion pump which can produce a vacuum of  $10^{-6}$  Torr in the chamber must be maintained for the evaporation of materials. The pirani gauge and penning gauge is used to measure the pressure. The distance between the substrate and the target materials should not be more than 15 cm. Substrate temperature is important parameter, if higher the temperature of the substrate, the material will crystallize, room temperature is quite enough for the amorphization of the materials.

#### 5. Basic properties of amorphous semiconductors

#### 5.1 Structural properties

Amorphous semiconductors a new discovery in 1954 by Kolomiets and Goryunova shows that these materials possess semiconducting properties, first tried group VI elements (S, Se, Te) in place of oxygen elements, which was used to prepare oxide glasses. Following the pioneering work by Ioffe and Regel [35], Ioffe realized that amorphous semiconductor attracts a lot of attention due to their unique properties. The amorphous materials could behave as semiconductor and the band gap depends on the short range order rather than long range order. Also amorphous material possesses a large number of defects, which in turn creates a large number of localized states. In crystalline materials, the band structure is completely determined by translation symmetry in its structure, since all equivalent interatomic distance and bond angles are equal. But in amorphous material bond angle and bond lengths are nearly equal. The short order range on atomic scale is usually similar to that in corresponding crystal. Little variation in the bond length and bond angle and other imperfection results in broadening of the band edges.

There have been many discussions on the type of structure that has been developed for amorphous materials depending on their chemical nature. In order to obtain complete structure of amorphous semiconductors, following experimental tools are presented. The overall aspect of the chemical structure that constitute short range order and long range order are obtained by using X-ray, electron and neutron beams. Extended X-ray absorption fine structure (EXAFS) is a probe particularly sensitivity for investigating the local structure around the atoms. The morphology of the samples and the inhomogeneity present in the form of phase separation and voids can be examined by transmission electron microscopes (TEM) and scanning electron microscope (SEM). The Raman and infra-red spectroscopy are the mean suitable for examine the degree of disorder and chemical bonding. The medium range of amorphous network can be well understood by small angle scattering. Differential thermal analysis is used to study the variation in structures with temperature.

# 5.2 Electrical properties

The band states that exist near the middle of the gap arises the defects such as dangling bond, interstitial etc. These structural defects play an important role in electrical properties. Since all the electronic wave function in crystal are extended and in non-crystal the wave function of electron and hole are localized. In consequences the electron/hole mobility and the absorption in non-crystal become smaller that in corresponding crystal. Amorphous semiconductor basically has low thermal and electrical conductivity, since their band gap is large and the Fermi level lie within the gap. When talk about the electronic properties of amorphous semiconductors, the electrical conductivities at room temperature are in the range of  $10^{-2}$  to  $10^{-15} \Omega^{-1}$  cm<sup>-1</sup>. Conductivity is directly proportional to the electron/hole transport properties in the materials.

Electrical properties are primarily determined by electronic density of states, the electronic properties yielded valuable ideas like mobility edge, charge defects and activation energy. Amorphous semiconductors exhibit smaller conductivity than the corresponding crystal. Generally there are two type of conduction, band conduction (DC conduction) and hopping conduction. The band conduction occurs when the carriers would excite beyond the mobility edges into non-localized states.

The charge transport properties significantly depends on the energy spectrum Ev and Ec denote the mobility edges for the valence and conduction bands, respectively. Electronic states in the mobility gap between these energies are spatially localized. The states below Ev and above Ec can be occupied by delocalized holes and electrons respectively. The nature of charge carrier transport gets altered, when the carrier crosses the mobility edges, Ec and Ev. The transport above Ec is the band conduction type for electrons and the transport below Ev is band conduction for holes. Mostly the conductivity in amorphous semiconductor at higher temperatures is dominated by band conduction. **Figure 6** shows the different types of conduction in amorphous semiconductor.

Davis and Mott predict the DC conductivity of amorphous semiconductor, depending on the temperature range, three conduction mechanism are possible [36].

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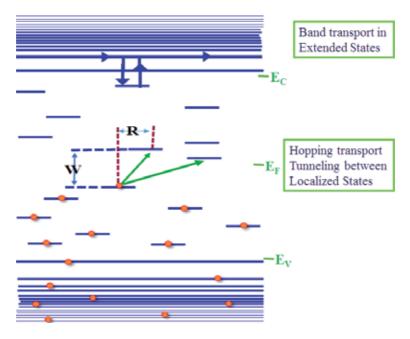


Figure 6.

Different types of conduction in amorphous semiconductor.

# 5.3 Optical properties

Amorphous semiconductor are the promising candidate for the photonic application owing to their interesting optical properties like high absorption coefficient, high efficiency of radiative recombination, high photosensitivity and nearly matching band gaps with visible region of solar spectrum. The design and realization of optical components based on these materials requires detailed information on their optical properties like electronic band structure, optical transition and relaxation mechanism and also a huge amount of information about their structure, opto-electronic behavior, transport of charge carriers, etc. The band gap represents the minimum energy difference between the top of valence band and the bottom of conduction band. However the minimum of the conduction band and maximum of the valence band occur at the same value of momentum, the energy difference is released as photon, this is called direct band gap semiconductor. In an indirect band gap semiconductor, the maximum energy of the valence band occurs at different value of momentum to the minimum of the conduction band energy (Figure 7). Both the transition direct and indirect gives rise to the frequency dependence of absorption coefficient near the absorption edge.

In amorphous semiconductors there are three distinct regions for optical absorption curve.

a. High absorption region ( $\alpha \ge 10^4$  cm<sup>-1</sup>) which gives the optical band gap between the valence band and conduction band, the absorption coefficient has the following frequency dependence [37].

$$\alpha h \upsilon = A \left( h \upsilon - E_g \right)^n \tag{2}$$

where A,  $E_g$ , v, h are constant, optical band gap, frequency of incident radiation and plank's constant respectively. The index 'n' is associated with the type of

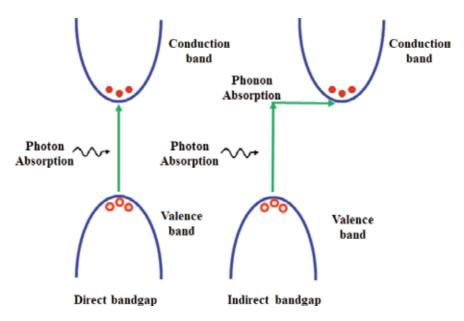


Figure 7. Schematic representation of direct and indirect band gap.

transition, which takes the values n = 1/2, 2, 3 and 3/2 for direct allowed, indirect allowed, indirect forbidden and direct forbidden transitions, respectively.

b.Spectral region with ( $\alpha = 10^2 - 10^4$  cm<sup>-1</sup>) is known as Urbach's exponential tail region. In this region the optical transition takes places between localized tail states and extended tail states. The absorption coefficient can be fitted by an Urbach law.

$$(Ah\nu)^{n} = \alpha_{0} \exp\left[{}^{h\vartheta/E_{u}}\right]$$
(3)

The exponential factor Eu indicates width of band tails of the localized states and is independent of temperature. At low temperature has a value of about 0.05–0.08 eV for most of amorphous semiconductor [38].

c. The region ( $\alpha \le 10^2$  cm<sup>-1</sup>) involves the low energy absorption region, defects and impurities originates in this region [39].

Extensive researches on amorphous Chalcogenide semiconductors attract the attentions of researchers and engineers begins nearly at the end of 1990s, when significant change in the physical, electrical, phase, physicochemical and structural properties induced by light of appropriate energy and intensity has been investigated. The properties include photoconductivity, photovoltaic, photoluminescence, and non-linear optical phenomena that are connected with purely electronic effects.

a. At high temperature, conduction may take place by carriers into the excited states beyond the mobility edges, electron in the conduction extended states and hole in the valence extended states. This yield an activated type temperature dependence for the conductivity of electron as [40].

$$(\sigma_{dc}) = \sigma_0 \exp\left[-\frac{\text{Ec} - \text{Ev}}{KT}\right]$$
(4)

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where  $\text{Ec} - \text{Ev} = \Delta E$  are the activation energy, the electron at or or above Ec move freely, while below it move through an activated hopping.  $\sigma_0$  is the pre-exponential factor.

b. At intermediate temperatures, conduction occurs by thermally assisted tunneling of carriers excited into localized gap state near the mobility edges; at  $E_A$  and  $E_B$ .

The thermal assisted tunneling process means localized electron jump from site to site with the exchange of phonon, this process is called hopping conduction. If the conductivity is carried by electron then conduction will be [41]

$$(\sigma_{dc}) = \sigma_1 \exp\left[-\frac{\mathbf{E} - \mathbf{E}\mathbf{v} - \Delta \mathbf{W}\mathbf{1}}{KT}\right]$$
(5)

where  $\Delta W1$  is the hopping energy in addition to the activation energy (Ec – Ev) needed to raise the electron to the appropriate localized states at energy E. Where  $E = E_A$  and  $E_B$  is the extremity of the conduction and valence band tail.  $\sigma_1$  is expected to be less than  $\sigma_0$  by a factor of  $10^2$  to  $10^4$ .

c. At low temperature, conduction occurs by thermally assisted tunneling of carriers between the localized states near the Fermi energy E<sub>F</sub>.

The carriers move between the states located at  $E_F$  via phonon assisted tunneling process, which is analogous to impurity conduction observed in heavily doped and highly compensated semiconductors at low temperatures, the conductivity is given by [42]

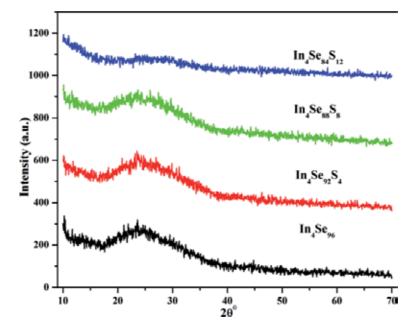
$$(\sigma_{dc}) = \sigma_2 \exp\left[-\frac{\Delta W2}{KT}\right] \tag{6}$$

where  $\sigma_0 < \sigma_1$ ,  $\Delta W_2$  has the same physical meaning as  $\Delta W_1$ . Since the density of states near  $E_F$  and the range of their wave-functions is probably smaller near  $E_F$  than near  $E_A$  or  $E_B$ .

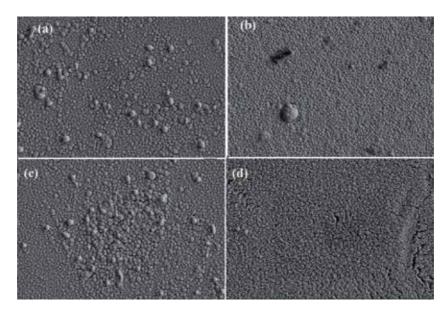
# 6. Results

Bulk ternary  $In_4Se_{96-x}S_x$  (where x = 0, 4, 8, 12) semiconductor were prepared by melt-quenching method from high purity (99.999%) reagents. **Figure 8** show the amorphous nature of the prepared samples was carried out by a Rigaku Ultima IV X-ray diffractometer (XRD).

Morphological analysis were done by Scanning Electron Microscope (SEM), Scanning electron microscope is an influential procedure to learning the morphology, growth mechanism, particle size, shape and distribution of particles in the films. Surface morphology of thin films samples have been studied by scanning electron microscopy (FESEM) apparatus shown in **Figure 9**. We acquire SEM micrograph from Model: **S**igma by Carl Zeiss employed with Gemini Column (Patented technology of Corl Zeiss) which enables inlense secondary electron detection. SEM micrographs acknowledge the inclusive consistency of the thin film on glass substrate, which assert that the average grain size of the films increases from 130 to 160 nm and 190 nm with 4 and 8% of Sulfur doping, at 12% of sulfur doping it decreases to 135 nm. Thus, the improvement of development of particle size and the vanishing of small gaps between the grains after doping shows that the disorderness decreases with Sulfur concentration.



**Figure 8.** The X-ray diffraction pattern of  $In_4Se_{96-x}S_x$  (where x = 0, 4, 8, 12) thin films.



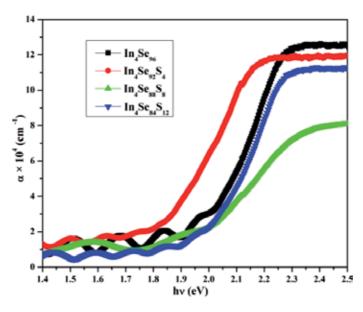


To measure the UV–Visible absorption and transmission spectra along with the energy band tail width and optical band gap in thin film of  $In_4Se_{96-x}S_x$  (where x = 0, 4, 8, 12) has been recorded in the wavelength range of 190–1100 nm by UV–Vis spectrophotometer (Model: Comspec M550) is shown in **Figure 8**.

The relation between absorption coefficient and optical band gap is given by Tauc relation [32].

$$\alpha h \nu = A \left( h \nu - E_{g} \right)^{n} \tag{7}$$

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**Figure 10.** Absorption coefficient ( $\alpha$ ) versus hv of  $In_4Se_{96-x}S_x$  (where x = 0, 4, 8, 12) thin films.

where A is constant called the band tailing parameter,  $E_g$  is the optical band gap, which is situated between the localized states near the mobility edges,  $\nu$  is the frequency of incident radiation and h is the plank's constant. The index 'n' is associated with the type of transition. The values of absorption coefficient ( $\alpha$ ) are in the range of 10<sup>4</sup> cm<sup>-1</sup>. With growing the sulfur concentration, the band gap is lifted to higher energy. The upsurge in optical band gap on addition of sulfur in In-Se thin films may be due to reduction in disorderness of the system and also due to decrease in density of localized states. It is well known that during the deposition of thin film, amorphous semiconductor covers large number of defects states such as dangling bond composed with some saturated bond. The addition of sulfur in In-Se system consequences the reduction of unsaturated defects making a number of saturated bonds, which is accountable for the increase in optical band gap [43] (**Figure 10**).

# 7. Conclusions

Form the above studies, one can conclude Powder sample of InSeS chalcogenide semiconductors have been successfully prepared by Melt-quenching technique and then deposited by thermal evaporation technique on ultra-clean glass substrate show smooth coverage. XRD confirm the amorphous nature of the prepared thin film. The films are highly absorptive, furthermore, the optical band gap cover the complete visible region of solar spectrum. The structural, optical and morphological studies of InSeS thin film show that it is a promising material for PV application and have the potential to be transferred in industry applications.

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# **Author details**

Mohsin Ganaie<sup>1\*</sup> and Mohammad Zulfequar<sup>2</sup>

1 Centre for Energy Studies, Indian Institute of Technology Delhi, Hauz Khas, New Delhi, India

2 Department of Physics, Jamia Millia Islamia, New Delhi, India

\*Address all correspondence to: mohsin.ganaie@gmail.com

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# Chapter 5

# Superconducting Josephson-Based Metamaterials for Quantum-Limited Parametric Amplification: A Review

Luca Fasolo, Angelo Greco and Emanuele Enrico

# Abstract

In the last few years, several groups have proposed and developed their own platforms demonstrating quantum-limited linear parametric amplification, with evident applications in quantum information and computation, electrical and optical metrology, radio astronomy, and basic physics concerning axion detection. Here, we propose a short review on the physics behind parametric amplification via metamaterials composed by coplanar waveguides embedding several Josephson junctions. We present and compare different schemes that exploit the nonlinearity of the Josephson current-phase relation to mix the so-called signal, idler, and pump tones. The chapter then presents and compares three different theoretical models, developed in the last few years, to predict the dynamics of these nonlinear systems in the particular case of a 4-wave mixing process and under the degenerate undepleted pump assumption. We will demonstrate that, under the same assumption, all the results are comparable in terms of amplification of the output fields.

**Keywords:** superconductivity, metamaterial, Josephson effect, parametric amplification, microwave photonics

# 1. Introduction

In the last decade, microwave quantum electronics received a substantial boost by the advancements in superconducting circuits and dilution refrigerators technologies. These platforms allow experiments to be easily carried out in the mK regime, where the detection and manipulation of signals in the range 3 - 12 GHz reaches energy sensitivities comparable to a single photon [1].

Solid state microwave quantum electronics is founded on a building block that has no analogous in quantum optics: the Josephson junction [2]. This, in fact, is a unique nondissipative and nonlinear component that represents the key element of a large series of quantum experiments.

Furthermore, microwave quantum electronics allows the exploration of the socalled ultrastrong coupling regime [3], hard to be reached in quantum optics, and it is worth mentioning that nonlinear resonator can be exploited to access relativistic quantum effects and quantum vacuum effects. To give an example, the Lamb shift [4] effect has been observed in superconducting artificial atom [5], while the dynamical Casimir effect [6, 7] has been promoted by properly engineered superconducting waveguide [8].

From the very beginning, superconducting electronics has been pushed by the strong interest coming from the quantum computation and information community. However, it has been only recently shown that a new concept of 1D metamaterial with embedded several Josephson junctions enables strong photon-photon on-chip interactions [9], allowing experimentalists to engineer dispersion relations that drive the waves traveling along artificial waveguides [10, 11]. These concepts and technologies allow the control and tunability of the wave mixing process. As an example, a weak signal traveling in a metamaterial can interact with a strong pump tone at a different frequency, activating the so-called parametric amplification [12]. The class of devices where these phenomena are promoted is commonly known as traveling-wave Josephson parametric amplifiers (TWJPA) and represents the solid state analogous to optical  $\chi^n$  nonlinear crystals [13].

It has been shown that TWJPAs can act as quantum parametric amplifiers by reaching the so-called quantum limit [14]. With the purpose of a comparison to the state-of-the-art commercially available low-noise amplifiers, these latter can operate at  $\omega/2\pi = 4$  GHz adding  $k_B T_n/\hbar\omega \approx 10$  noise photons having a noise temperature of  $T_n = 2$  K, while Josephson-based amplifiers can reduce this added noise up to 1/2 photon, or even 0, depending on its working configuration.

The capability to beat the quantum limit is related to the so-called phasesensitive amplification process, where the metamaterial can operate in degenerate mode (degenerate parametric amplifier, DPA), acting on two waves (signal and idler) at the same frequency ( $\omega_s = \omega_i$ ) by amplifying and de-amplifying their position and momentum quadratures, respectively. In this view, DPA enables the preparation of squeezed states in the microwave regime. Even in the nondegenerate mode (nondegenerate parametric amplifier, NDPA, i.e.,  $\omega_s \neq \omega_i$ ), the phasepreserving nature of the quantum parametric amplification results in the entanglement condition among the signal and idler generated photons, composing a twomode squeezed state [15]. It is worth mentioning how such a quantum state is an example of Einstein-Podolsky-Rosen state [16], where correlations between signal and idler are stronger than that allowed by classical theory [17].

It should be evident how superconducting electronics not only has demonstrated to be an ideal platform for microwave quantum parametric amplification but also has pushed forward the research field focusing on the generation of nonclassical radiation with attractive potential applications in metrology and quantum information processing.

# 2. Historical evolution of the traveling-wave parametric amplifiers

The theory of a new concept of microwave amplifier was developed by Cullen [12] in 1959. In his paper, Cullen showed a novel mechanism of periodic transfer of power between a pump tone and a signal traveling in a transmission line composed of a voltage dependent capacitance per unit length. A nonlinear component of an RLC circuit can change periodically the resonance frequency of the whole system, leading to a novel way of making broadband amplification, the so-called parametric amplification. In **Figure 1**, we report two toy models for parametric amplification in mechanical systems with their electrical counterparts.

One of the first realizations of Cullen's idea was made by Mavaddat et al. in 1962 [19]. The signal line was basically a low pass filter, in which the shunt elements were similar varactor diodes. There, the nonlinearity was given by the specific capacitance-voltage relation of the varactor diodes, which is highly nonlinear for

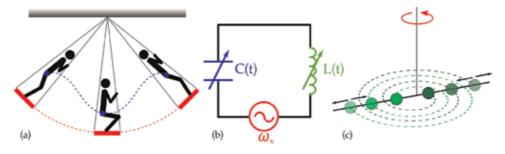


Figure 1.

(a) Sketch of a swing process. An oscillating system at a frequency  $\omega_s$  is excited by parametric amplification via periodical changes of the center of mass position at a frequency  $\omega_p = 2\omega_s$ . (b) LC circuit with variable (nonlinear) C and L components. The case in which the capacitance C is periodically changed in time is the circuit analogous to the mechanical system represented in (a), while the case having an oscillating inductance L mimics the condition sketched in (c), consisting in a torque pendulum with variable inertia momentum [18].

relative small voltage values. In this pioneering experiment, a gain of 10 dB and a bandwidth of 3 MHz were shown.

After the theorizing and the subsequent discovery of the Josephson effect [2], it was understood that an easy way to embed a nonlinear component into a transmission line and simultaneously reduce losses was to build a nonlinear inductance made of superconducting material, exploiting a Josephson junction as a source of nonlinearity following the vanguard idea by Sweeny and Mahler [13]. There, the parametric amplifier was modeled by a first-order small-signal theory with the same approach adopted to predict the behavior of GaAsFET transmission line amplifiers. The proposed design consisted of a superconducting thin-film niobium transmission line, composed by a coplanar waveguide integrating a large number of Josephson junctions.

The first realization of a traveling-wave parametric amplifier embedding a series of Josephson junctions was possible due to the PARTS process developed at IBM [9]. Exploiting niobium/aluminum technology, Yurke et al. [20] reported the construction and characterization of a coplanar waveguide, in which the central trace was composed by an array of 1000 Josephson junctions. The experiment was there performed in reflection mode, by terminating one end of the device with a short, leading to a relative high gain of 16 dB but a narrow bandwidth of 125 MHz and a noise temperature of 0.5  $\pm$  0.1 K. The mismatch between the theoretical model and the experimental data has resulted in the understanding of a lack of a complete description of the physics behind this device when working in a small-signal regime. The study of the collective behavior of groups of Josephson junctions forming a transmission line has been an active field of study of several theoretical works [21, 22]. Subsequently, the use of numerical analysis [23] helped in clarifying how wave propagation acts inside this kind of transmission line, giving information on cutoff propagation, dispersive behavior, and shock-wave formation. An analytical model of a Josephson traveling-wave amplifier of greater complexity was developed by Yaakobi et al. [24]. There, a transmission line made of a series of capacitively shunted Josephson junctions was considered.

One of the main limitations concerning the maximum achievable gain, common to all the TWJPAs concepts, is represented by the phase mismatch between the different tones into the line. In particular, it has to be noticed that even though the incoming waves can be in phase, photon-photon interactions between different tones (cross-phase modulation) or the same tone (self-phase modulation) lead to a modification of the phase of the traveling tones themselves. Indeed, quantum mechanically speaking, the power transport between the pump and the signal waves takes place through a photon energy conversion between the pump and the signal. This means that for an efficient energy exchange, conservation of both energy and momentum needs to take place. The latter condition is the corpuscular analogous to the phase matching requirement between the different electromagnetic waves. An engineering solution to overcome this problem is represented by the so-called resonant phase matching (RPM) [11]. O'Brien et al. analyzed this method theoretically on a simple transmission line made of a series of Josephson junctions capacitively shunted to ground operating in the so-called 4-wave mixing (4WM) regime. In their model, they shunted the transmission line with several LC resonators with a resonance frequency slightly above the pump tone. Doing this, they were able to show the rise of a stop band in the dispersion relation, which is able to re-phase the pump with the signal tones by changing the pump wave vector, favoring the wave mixing.

O'Brien's design was realized not long after [10] using Al technology. In their design, the unit cell of the transmission line was composed by three single nonlinear Josephson cells, the shunt capacitor was made using low-loss amorphous silicon dielectric and a resonator was placed after each group of 17 unit cells. The device showed a maximum gain of 12 dB over a 4 GHz bandwidth centered on  $\approx$ 5 GHz. Moreover, the authors explain that variations of 2–3 dB in the gain most likely come from imperfect impedance matching between sections and at the level of the bond pads.

A similar design was adopted by Macklin et al. [14] to prove experimentally the capability of a TWJPA combined with the RPM technique to be used as a reliable tool for qubits readout. In this paper, the TWJPA, based on Nb technology and a different RPM periodicity, was first characterized, showing a gain of 20 dB over a 3 GHz bandwidth. Moreover, the quantum efficiency of the amplifier was tested when coupled with a 3D transmon qubit, leading to an efficiency value of  $0.49 \pm 0.01$ . A key point of this experiment was the proof that a single TWJPA could be able to perform the readout of more than 20 qubits, thanks to its high dynamic range and multiplexing capabilities. RPM has shown remarkable capabilities and is a promising technique to overcome phase mismatch. It can be implemented in multiple ways [25], by the way, it has to be noticed that this method requires an increase of design complexity, lower tolerances on the constructing parameters, and longer propagation lengths (2 cm–1 m).

Another option to solve the mismatch problem was suggested by Bell and Samlov [26], who proposed a self-phase matching transmission line embedding a series of asymmetric superconducting quantum interference devices (SQUIDs). The remarkable feature of this design is that it does not need any resonant circuit to achieve phase matching. This TWJPA is indeed able to tune the nonlinearity of its SQUIDs just through the use of an external magnetic field. Zhang et al. realized that this design [27] proves the wide tunability on positive and negative values of the Kerr nonlinearity by a magnetic flux and its capability to assist phase matching in the 4WM process. The 4WM process is intrinsically affected by phase mismatch because it takes origin from a cubic (Kerr-like) nonlinearity of the current-phase relation of the SQUIDs composing the TWJPA, getting unwanted effects from selfphase and cross-phase modulations.

Zorin showed [28] that by embedding a chain of rf-SQUIDs into a coplanar waveguide, it is possible to tune both the second and third order nonlinearities of their phase-current relation. This is a totally a novel approach to the TWJPA, since the possibility to use a quadratic term as a source of nonlinearity, allows to work in the 3-Wave Mixing regime (3WM), as theorized by Cullen 57 years before. It is well-known that 3WM has several advantages when compared to 4WM. Firstly, it allows to operate with a minimal phase mismatch. Secondly, it requires a lesser

pump power to achieve the same amplification per unit length. Eventually, it separates signal and idler from pump tones, easing the engineering of the experimental setup by removing the requirement of heavy filtering in the middle of the amplification band. A proof of principle based on the Zorin's layout [29] showed a gain reaching 11 dB over a 3 GHz bandwidth.

A step forward in controlling the metamaterial nonlinearities was attempted by Miano et al. [30] achieving an independent tune of both second and third order terms in the current-phase relation by adjusting the bias current in some inductive circuits surrounding the transmission line. This technology takes the name of symmetric traveling-wave parametric amplifier (STWPA), its peculiarity arising from the symmetric arrangement of the rf-SQUIDs that compose the transmission line. This device concept represents the state-of-the-art in the field, allowing the exploration a wide portion of the control parameters space, leading to a maximum estimated gain of 17 dB and a 4 GHz bandwidth.

# 3. Theoretical models for a 4WM process in a TWJPA

In the last decade, different theoretical models have been developed to predict the behavior of an electric transmission line containing an array of Josephson junctions, employed as nonlinear elements. In this section, we will focus on those models developed to predict the behavior of a TWJPA in the particular case of a 4WM process, under undepleted degenerate pump approximation (i.e., assuming that the power held by the pump wave is at first approximation constant and larger than the one owned by the signal and the idler). We will firstly focus on the classical theory proposed by Yaakobi et al. in 2013 [24] and O'Brien et al. in 2014 [11], in which the behavior of the transmission line is derived imposing the current conservation in the system. This starting assumption leads to the definition of a partial differential nonlinear equation that can be turned into a system of coupled mode equations, providing the expression of the amplitude of the pump, signal, and idler tones along the transmission line. Subsequently, we will discuss two different quantum approaches for the description of the parametric amplifier dynamics. The first one, proposed by Grimsmo and Blais in 2017 [31], exploits a Hamiltonian based on continuous-mode operators to derive, in an interaction picture frame, a device's output field. The second one instead, proposed by van der Reep in 2019 [32], derives a system of coupled mode equations for the creation and annihilation quantum operators starting from a Hamiltonian based on discrete-mode operators.

The theories presented in this chapter will be based on a series of simplifying assumptions, whose experimental realization could be difficult to be obtained. For instance, in a real device, the undepleted pump approximation is hardly respected along the entire extension of the device because, along the line, the pump tone transfers a non-negligible amount of energy to the signal and idler one. The depletion effects, resulting in a reduction of the gain and of the dynamics-range of the amplifier, have been studied both in a classical and quantum frame [28, 33].

In all of these models, a lossless electrical circuit composed by the repetition of an elementary cell, whose structure is shown in **Figure 2**, is taken into account. In order to standardize the notations, we assume that the Josephson junctions embedded in the transmission line are identical (i.e., they have the same critical current  $I_c$ ) and that the current flowing through the *n*-th junction can be expressed through the nonlinear relation

$$I_{J,n} = I_c \sin\left(\varphi_n\right) \tag{1}$$

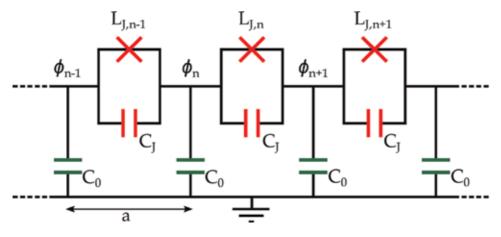


Figure 2.

Electrical equivalent representation of a repetition of Josephson junctions embedded in a transmission line. The junctions are modeled as an LC resonant circuit. The length of the unitary cell length is represented by a.

where  $\varphi_n(t)$  is the phase difference across the junction of the macroscopic wave functions of the two superconductive electrodes. The relation between  $\varphi_n$  and the voltage-difference across the junction is given by the Faraday's induction law

$$\Delta V_n = V_{n+1} - V_n = \frac{\Phi_0}{2\pi} \frac{d\varphi_n}{dt} = \frac{\Phi_0}{2\pi} \frac{d}{dt} \left[ \phi_{n+1} - \phi_n \right]$$
(2)

where  $\Phi_0 = h/(2e)$  is the magnetic quantum flux (with *h* the Planck constant and *e* the elementary charge), whereas  $\phi_n(t)$  is the absolute phase in the *n*-th node of the circuit. The phase at the *n*-th node ( $\phi_n$ ) can be converted into a flux at the *n*-th node, and vice versa, through the relation  $\Phi_n = (\Phi_0/2\pi)\phi_n$ .

Furthermore, we define  $C_J$  the capacitance associated to the *n*-th Josephson junction and  $L_{J,n}$  its inductance, defined as

$$L_{J,n} = \frac{\Delta V_n}{dI_{J,n}/dt} = \frac{\Phi_0}{2\pi} \frac{1}{I_c \cos(\varphi_n)} = \frac{L_{J_0}}{\cos(\varphi_n)}$$
(3)

where  $L_{J_0} = \Phi_0/(2\pi I_c)$  is the inductance of the Josephson junction for a phase difference  $\varphi_n = 0$ .

The energy stored in the n-th Josephson junction can be expressed, using the definitions given in Eqs. (1) and (2), as

$$U_{J,n} = \int_{t_0}^t VI \ dt' = \int_{t_0}^t \frac{\Phi_0}{2\pi} \frac{d\varphi_n(t')}{dt'} \ I_c \sin(\varphi_n) \ dt' = I_c \frac{\Phi_0}{2\pi} [1 - \cos(\varphi_n(t))], \quad (4)$$

under the assumption that  $\varphi_n(t_0) = 0$ , and approximated through a first-order power expansion as

$$U_{J,n} = I_c \frac{\Phi_0}{2\pi} [1 - \cos(\varphi_n)] = \frac{1}{2L_{J_0}} \Delta \Phi_n^2 - \frac{1}{24L_{J_0}} \left(\frac{2\pi}{\Phi_0}\right)^2 \Delta \Phi_n^4 + O\left(\Delta \Phi_n^6\right)$$
(5)

where  $\Delta \Phi_n = \Phi_{n+1} - \Phi_n$ .

Finally, we assume identical coupling capacitances  $C_0$  between the transmission line and ground.

# 3.1 The classical theoretical model

In this subsection, we will present the main steps for the derivation of the classical model presented in [11, 24]. Under proper assumption, this model allows to determine analytically the amplitude of the signal's and idler's waves along the transmission line.

Expressing the current flowing through each branch of the circuit presented in **Figure 2** in terms of absolute phases  $\phi_n$  and imposing the current conservation in the *n*-th node (i.e.,  $I_{J,n-1} + I_{C_J,n-1} = I_{J,n} + I_{C_J,n} + I_{C_0,n}$ ), a differential equation for the absolute phase, in the case of a weak nonlinearity, can be obtained:

$$-C_{0} \frac{d^{2}}{dt^{2}} [\phi_{n}] = -C_{J} \frac{d^{2}}{dt^{2}} [\phi_{n+1} + \phi_{n-1} - 2\phi_{n}] - \frac{1}{L_{J_{0}}} [\phi_{n+1} + \phi_{n-1} - 2\phi_{n}] + \frac{\Phi_{0}}{2\pi} \frac{1}{6I_{c}^{2}} \frac{1}{L_{J_{0}}^{3}} [(\phi_{n+1} - \phi_{n})^{3} - (\phi_{n} - \phi_{n-1})^{3}]$$
(6)

where the last term derives from the first-order approximation of the nonlinear behavior of the Josephson's inductance.

Assuming the length *a* of the elementary cell is much smaller than the wave lengths of the propagating waves  $\lambda$  (i.e.,  $a/\lambda \ll 1$ ), the discrete index *n* can be replaced by a continuous position *x* along the line (i.e.,  $\phi_n(t) \rightarrow \phi(x,t)$ ) and the phase differences can be expressed, at the second order approximation, as:

$$\phi_{n+1} - \phi_n \approx a \frac{\partial \phi}{\partial x} + \frac{1}{2} a^2 \frac{\partial^2 \phi}{\partial x^2}$$
(7)

$$\phi_n - \phi_{n-1} \approx a \frac{\partial \phi}{\partial x} - \frac{1}{2} a^2 \frac{\partial^2 \phi}{\partial x^2}$$
(8)

In this way, it is possible to define a nonlinear differential equation for the continuous absolute phase  $\phi(x, t)$ :

$$C_0 \quad \frac{\partial^2 \phi}{\partial t^2} - \frac{a^2}{L_{J_0}} \frac{\partial^2 \phi}{\partial x^2} - C_J \quad a^2 \quad \frac{\partial^4 \phi}{\partial x^2 \partial t^2} = -\frac{a^4}{2} \frac{\partial^2 \phi}{I_c^2} \frac{\partial^2 \phi}{\partial x^2} \left(\frac{\partial \phi}{\partial x}\right)^2 \tag{9}$$

In the case of a weakly nonlinear medium, the dispersion law can be derived from Eq. (9), considering the left-hand side being equal to zero and imposing a plane-wave solution  $\phi(x, t) \propto e^{i(kx-\omega t)}$ :

$$k(\omega) = \frac{\omega \sqrt{L_{J_0}C_0}}{a\sqrt{1 - L_{J_0}C_J\omega^2}}$$
(10)

The solutions of Eq. (9) can be expressed, as shown by O'Brien et al. [11], in the form of a superposition of three waves (pump, signal, and idler) whose amplitudes are complex functions of the position along the line:

$$\phi(x,t) = \sum_{n=p,s,i} \operatorname{Re} \left[ A_n(x) \ e^{i \ (k_n x - \omega_n t)} \right] = \frac{1}{2} \sum_{n=s,i,p} \left[ A_n(x) \ e^{i \ (k_n x - \omega_n t)} + c.c \right]$$
(11)

The case of a 4WM process with a degenerate pump can be taken into account by imposing the frequency matching condition  $2\omega_p = \omega_s + \omega_i$ . Replacing this

particular solution in Eq. (9) and assuming that, along the line, the amplitudes are slowly varying (i.e.,  $|\partial^2 A_n / \partial x^2| \ll k_n |\partial A_n / \partial x| \ll k_n^2 |A_n|$ ) and that  $|A_s|^2$  and  $|A_i|^2$  are negligible (i.e.,  $|A_{s,i}| \ll |A_p|$ , strong pump approximation), we obtain a system of three coupled differential equations for the amplitudes  $A_n(x)$  that describe the energy exchange between the three waves along the line:

$$\frac{\partial A_p}{\partial x} = i\vartheta_p \left| A_p \right|^2 A_p + 2iX_p A_p^* A_s A_i e^{i\Delta kx}$$
(12)

$$\frac{\partial A_{s(i)}}{\partial x} = i\vartheta_{s(i)} \left| A_p \right|^2 A_{s(i)} + iX_{s(i)}A_p^2 A_{i(s)}e^{i\Delta kx}$$
(13)

where  $\Delta k = 2k_p - k_s - k_i$  is the chromatic dispersion. The term  $\vartheta_p$  is responsible for the self-phase modulation of the pump tone, while  $\vartheta_{s(i)}$  is responsible for the cross-phase modulation between the pump tone and the signal or idler, respectively. These terms can be expressed as

$$\vartheta_p = \frac{a^4 k_p^5}{16 C_0 I_c^2 L_{J_0}^3 \omega_p^2} \quad \text{and} \quad \vartheta_{s(i)} = \frac{a^4 k_p^2 k_{s(i)}^3}{8 C_0 I_c^2 L_{J_0}^3 \omega_{s(i)}^2}$$
(14)

while the coupling constants  $X_n$ , depending on the circuit parameters, are defined as

$$X_p = \frac{a^4 k_p^2 k_s k_i (k_p - \Delta k)}{16 C_0 I_c^2 L_{J_0}^3 \omega_p^2} \quad \text{and} \quad X_{s(i)} = \frac{a^4 k_p^2 k_s k_i (k_{s(i)} + \Delta k)}{16 C_0 I_c^2 L_{J_0}^3 \omega_{s(i)}^2}$$
(15)

Expressing the complex amplitudes  $A_n(x)$  in a the co-rotating frame

$$A_{n}(x) = A_{n_{0}}e^{-i\vartheta_{n}|A_{p_{0}}|^{2}x}$$
(16)

it can be demonstrated that, working under the undepleted pump approximation  $|A_p(x)| = A_{p_0} \gg |A_{s(i)}(x)|$ , the amplitude of the signal can be expressed as

$$A_{s}(x) = \left[A_{s_{0}}\left(\cosh\left(g_{1}x\right) - \frac{i \Psi_{1}}{2g_{1}}\sinh\left(g_{1}x\right)\right) + i\frac{X_{s(i)}|A_{p_{0}}|^{2}}{g_{1}}A_{s(i)_{0}}^{*}\sinh\left(g_{1}x\right)\right]e^{-\frac{i\Psi_{1}}{2}x}$$
(17)

where  $\Psi_1 = \Delta k + (2\vartheta_p - \vartheta_s - \vartheta_i) |A_{p_0}|^2 = \Delta k + \vartheta |A_{p_0}|^2$  is the total phase mismatch and  $g_1$  is the exponential complex gain factor, defined as

$$g_{1} = \sqrt{X_{s}X_{i}^{*} \left|A_{p_{0}}\right|^{4} - \left(\frac{\Psi_{1}}{2}\right)^{2}}$$
(18)

The total gain of an amplifier, composed by the repetition of *N* elementary cells, can then be expressed as  $G_s(aN) = |A_s(aN)/A_{s_0}|^2$ .

## 3.2 Quantum Hamiltonian model based on continuous-mode operators

A standard method to treat quantum superconducting circuits is represented by the lumped element approach [34]. In this latter, the Hamiltonian of the quantum circuit is straightforwardly derived from its classical counterpart by promoting

fields to operators and properly imposing commutating relations. In this view, one can proceed by deriving the Lagrangian of a TWJPA composed by the repetition of N unitary cells, under first nonlinear order approximation, as

$$\mathcal{L} = \sum_{n=0}^{N-1} \left[ \frac{C_0}{2} \left( \frac{\partial \Phi_n}{\partial t} \right)^2 + \frac{C_J}{2} \left( \frac{\partial \Delta \Phi_n}{\partial t} \right)^2 - E_{J_0} \left( 1 - \cos\left( \frac{2\pi}{\Phi_0} \Delta \Phi_n \right) \right) \right] \approx$$
(19)

$$\approx \sum_{n=0}^{N-1} \left[ \frac{C_0}{2} \left( \frac{\partial \Phi_n}{\partial t} \right)^2 + \frac{C_J}{2} \left( \frac{\partial \Delta \Phi_n}{\partial t} \right)^2 - \frac{1}{2L_{J_0}} \Delta \Phi_n^2 - \frac{1}{24L_{J_0}} \left( \frac{2\pi}{\Phi_0} \right)^2 \Delta \Phi_n^4 \right]$$
(20)

where  $E_{J_0} = I_c \Phi_0/2\pi = I_c L_{J_0}$ . Under the assumption that  $a/\lambda \ll 1$  it is possible, as performed in the previous subsection, to replace the discrete index n with a continuous position x along the line (i.e.,  $\Phi_n(t) \to \Phi(x, t)$ ) and approximate, at the first order,  $\Delta \Phi_n \to a \ \partial \Phi(x, t)/\partial x$ . Furthermore, extending the system via two lossless semi-infinite transmission lines (characterized by a constant distributed capacitance  $c_0$  and a constant distributed inductance  $l_0$ ), the Lagrangian can be expressed through a space integral extending from  $x = -\infty$  to  $x = +\infty$  as

$$\mathcal{L}\left[\Phi, \frac{\partial\Phi}{\partial t}\right] = \frac{1}{2} \int_{-\infty}^{\infty} \left[ c(x) \left(\frac{\partial\Phi}{\partial t}\right)^2 + \frac{1}{\omega_J^2(x)l(x)} \left(\frac{\partial^2\Phi}{\partial x\partial t}\right) - \frac{1}{l(x)} \left(\frac{\partial\Phi}{\partial x}\right)^2 + \gamma(x) \left(\frac{\partial\Phi}{\partial x}\right)^4 \right] dx$$
(21)

where c(x) and l(x) are the distributed capacitance and inductance of the system, defined as

$$c(x) = \begin{cases} c_0 & x < 0 \\ C_J/a & 0 < x < z \\ c_0 & x > z \end{cases} \text{ and } l(x) = \begin{cases} l_0 & x < 0 \\ L_{J_0}/a & 0 < x < z \\ l_0 & x > z \end{cases}$$
(22)

$$\omega_{J}(x) = \begin{cases} \infty & x < 0\\ 1/\sqrt{L_{J_{0}}C_{J}} & 0 < x < z & \text{and} & \gamma(x) = \begin{cases} 0 & x < 0\\ \left(a^{3}E_{J_{0}}/12\right)\left(2\pi/\Phi_{0}\right)^{4} & 0 < x < z\\ 0 & x > z & \end{cases}$$
(23)

where z is the length of the TWJPA,  $\omega_J(x)$  is the junction's plasma frequency, and  $\gamma(x)$  is the term deriving from the nonlinearity of the junctions.

From Eq. (21), one can easily derive the Euler-Lagrange equation whose form, for 0 < x < z, is equal to Eq. (9), giving the same dispersion relation (Eq. (10)) under analogous assumptions. Instead, outside the nonlinear region, the wave vector turns out to be  $k_{\omega}(x) = \sqrt{c_0 l_0} \omega^2$ .

The Hamiltonian of the system can be derived from the Lagrangian by taking into account  $\pi(x,t) = \delta \mathcal{L}/\delta[\partial \Phi/\partial t]$ , the canonical momentum of the flux  $\Phi(x,t)$ :

$$H[\Phi, \pi] = \int_{-\infty}^{\infty} \left[ \pi \frac{\partial \Phi}{\partial t} \right] dx - \mathcal{L}$$
  
=  $\frac{1}{2} \int_{-\infty}^{\infty} \left[ c(x) \left( \frac{\partial \Phi}{\partial \Phi t} \right)^2 + \frac{1}{l(x)} \left( \frac{\partial \Phi}{\partial x} \right)^2 + \frac{1}{\omega_p^2(x)l(x)} \left( \frac{\partial^2 \Phi}{\partial x \partial t} \right)^2 \right] dx - \frac{\gamma}{2} \int_0^x \left[ \left( \frac{\partial \Phi}{\partial x} \right)^4 \right] dx$   
=  $H_0 + H_1$  (24)

where the term  $H_0$  represents the linear contributions to the energy of the system, while  $H_1$  is the first-order nonlinear contribution.

This Hamiltonian can be converted to its quantum form promoting the field  $\Phi(x,t)$  to the quantum operator  $\hat{\Phi}(x,t)$ .

In direct analogy with Eq. (11), one can express the flux operator in terms of continuous-mode functions [34], such as  $\hat{H}_0$  is diagonal in the plane-waves unperturbed modes decomposition:

$$\hat{\Phi}(x,t) = \sum_{\nu=L,R} \int_0^\infty \left[ \sqrt{\frac{\hbar l(x)}{4\pi k_\omega(x)}} \hat{a}_{\nu\omega} e^{-i(\pm k_\omega(x)x - \omega t)} + \text{H.c.} \right] d\omega$$
(25)

where the subscript *R* denotes a progressive wave, while *L* denotes a regressive wave (i.e.,  $\hat{a}_{R\omega}$  represents the annihilation operator of a right-moving field of frequency  $\omega$ ). In [35], it is demonstrated that by replacing the definition given in Eq. (25) into the linear Hamiltonian,  $\hat{H}_0$  takes the form

$$\hat{H}_{0} = \sum_{\nu=R,L} \int_{0}^{\infty} \left[ \hbar \omega \hat{a}_{\nu\omega}^{\dagger} \hat{a}_{\nu\omega} \right] d\omega$$
(26)

(where the zero-point energy, which does not influence the dynamics of the amplifier, has been omitted).

Using the expansion of  $\hat{\Phi}(x,t)$  introduced above, under the hypothesis of a strong right-moving classical pump centered in  $\omega_p$ , and that the fields  $\hat{a}_{\nu\omega}$  are small except for frequencies closed to the pump frequency (i.e., replacing  $\hat{a}_{\nu\omega}$  with  $\hat{a}_{\nu\omega} + b(\omega)$ , where  $b(\omega)$  is a complex valued function centered in  $\omega_p$ ), the nonlinear Hamiltonian  $\hat{H}_1$  can be expressed under strong pump approximation, at the first order in  $b(\omega)$ , as the sum of three different contributions:

$$\hat{H}_1 = \hat{H}_{CPM} + \hat{H}_{SQ} + H_{SPM} \tag{27}$$

In the expressions of these contributions, the fast rotating terms and the highly phase mismatched left-moving field have been neglected:

$$\hat{H}_{CPM} = -\frac{\hbar}{2\pi} \int_{0}^{\infty} d\omega_{s} d\omega_{i} d\Omega_{p} d\Omega_{p'} \sqrt{k_{\omega_{s}} k_{\omega_{i}}} \beta^{*} (\Omega_{p}) \beta(\Omega_{p'}) \Upsilon(\omega_{s}, \omega_{i}, \Omega_{p}, \Omega_{p'}) \hat{a}_{R\omega_{s}}^{\dagger} \hat{a}_{R\omega_{i}} + \text{H.c}$$
(28)

describes the cross-phase modulation,

$$\hat{H}_{SQ} = -\frac{\hbar}{4\pi} \int_{0}^{\infty} d\omega_{s} d\omega_{i} d\Omega_{p} d\Omega_{p'} \sqrt{k_{\omega_{s}} k_{\omega_{i}}} \beta(\Omega_{p}) \beta(\Omega_{p'}) \Upsilon(\omega_{s}, \Omega_{p}, \omega_{i}, \Omega_{p'}) \hat{a}_{R\omega_{s}}^{\dagger} \hat{a}_{R\omega_{i}}^{\dagger} + \text{H.c}$$
(29)

describes the broadband squeezing, and

$$egin{aligned} H_{SPM} &= -rac{\hbar}{4\pi} \int_{0}^{\infty} d\omega_{s} d\omega_{i} d\Omega_{p} d\Omega_{p'} \sqrt{k_{\omega_{s}} k \omega_{i}} eta^{*} \left(\Omega_{p}
ight) eta \left(\Omega_{p'}
ight) \Upsilon \left(\omega_{s}, \omega_{i}, \Omega_{p}, \Omega_{p'}
ight) b^{*} \left(\omega_{s}
ight) b(\omega_{i}) \ &+ ext{H.c.} \end{aligned}$$

describes the self-phase modulation.  $\beta(\Omega)$  is the dimensionless pump amplitude, proportional to the ratio between the pump current  $I_J(\Omega_p)$  and the critical current of the junctions  $I_c$ :

$$\beta(\Omega_p) = \frac{I_J(\Omega_p)}{4I_c} \tag{31}$$

The function  $\Upsilon(\omega_1, \omega_2, \omega_3, \omega_4)$  is the phase matching function, defined as

$$\Upsilon(\omega_1, \omega_2, \omega_3, \omega_4) = \int_0^z e^{-i(k_{\omega_1}(x) - k_{\omega_2}(x) + k_{\omega_3}(x) - k_{\omega_4}(x))} dx$$
(32)

Assuming the nonlinear Hamiltonian  $\hat{H}_1$  as a perturbative term of the Hamiltonian  $\hat{H}_0$  for which the continuous modes are noninteracting, and assuming the initial time of the interaction  $t_0 = -\infty$  and the final time  $t_1 = +\infty$ , it is possible to relate the input field of the system to the output one introducing the asymptotic output field

$$\hat{a}_{R\omega}^{out} = \hat{U}\hat{a}_{R\omega}\hat{U}^{\dagger}, \qquad (33)$$

where  $\hat{U}$  is the asymptotic unitary evolution operator (approximated to the first order in  $\hat{H}_1$ )

$$\hat{U} \equiv \hat{U}(-\infty,\infty) = e^{-\frac{i}{\hbar}\hat{K}_1} \quad \text{where} \quad \hat{K}_1 = \hat{K}_{CPM} + \hat{K}_{SQ} + K_{SPM}$$
(34)

Working in the monochromatic degenerate pump limit  $b(\Omega_{p'}) = b(\Omega_p) \rightarrow b(\Omega_p)\delta(\Omega_p - \omega_p) \equiv b_p$  (where  $\omega_p$  is the pump frequency), the propagators take the form

$$\hat{K}_{CPM} = -2\hbar \left| \beta_p \right|^2 z \int_0^\infty k_{\omega_s} \hat{a}^{\dagger}_{R\omega_s} \hat{a}_{R\omega_s} d\omega_s$$
(35)

$$\hat{K}_{SQ} = -\frac{i\hbar}{2} \left| \beta_p \right|^2 \int_0^\infty \sqrt{k_{\omega_s} k_{\omega_i}} \left[ \frac{1}{\Delta k} \left( e^{i\Delta kz} - 1 \right) \right] \hat{a}_{R\omega_s}^\dagger \hat{a}_{R\omega_i}^\dagger d\omega_s + \text{H.c.}$$
(36)

and

$$K_{SPM} = -\hbar z \left| \beta_p \right|^2 k_{\omega_p} b_p^* b_p \tag{37}$$

where  $\beta(\omega_p) \equiv \beta_p$  and  $\Delta k = 2k_{\omega_p} - k_{\omega_s} - k_{\omega_i}$  are the chromatic dispersions. Similar to the previous classical treatment, one can introduce the co-rotating framework by replacing the field operators with

$$\hat{a}_{R\omega_s}(z) = \hat{\tilde{a}}_{R\omega_s}(z) \ e^{2i|\beta_p|^2 k_{\omega_s} z} \quad \text{and} \quad b_p(z) = \tilde{b}_p(z) \ e^{i|\beta_p|^2 k_{\omega_p} z}$$
(38)

In this framework, one can derive the following differential equation

$$\frac{\partial \tilde{a}_{R\omega_s}(z)}{\partial z} = \frac{i}{\hbar} \left[ \frac{d}{dz} \hat{K}_1, \hat{a}_{R\omega_s} \right] = i\beta_p^2 \sqrt{k_{\omega_s} k_{\omega_i}} e^{i\Psi_2(\omega_s)z} \hat{a}_{R\omega_i}^{\dagger}$$
(39)

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and

$$\frac{\partial b_p(z)}{\partial z} = -\left\{\frac{dK_{SPM}}{dz}, \tilde{b}_p\right\} = 0$$
(40)

where  $\Psi_2(\omega_s) = \Delta k + 2 \left| \beta_p \right|^2 \left( k_{\omega_p} - k_{\omega_s} - k_{\omega_i} \right)$  is the total phase mismatch. These latter are formally identical to Eqs. (12) and (13), up to a frequency-dependent normalization of the wave-amplitudes, under the undepleted pump approximation. Reference [11] derives an exact solution for Eq. (39), being

$$\hat{a}_{R\omega_{s}}^{out}(z) = \left[ \left( \cosh\left(g_{2}(\omega_{s})z\right) - \frac{i\Psi_{2}(\omega_{s})}{2g_{2}(\omega_{s})} \sinh\left(g_{2}(\omega_{s})z\right) \right) \hat{a}_{R\omega_{s}} + i\frac{\beta_{p}^{2}\sqrt{k_{\omega_{s}}k_{\omega_{i}}}}{g_{2}(\omega_{s})} \sinh\left(g_{2}(\omega_{s})z\right) \ \hat{a}_{R\omega_{i}}^{\dagger} e^{i\frac{\Psi_{2}(\omega_{s})}{2}z} \right]$$

$$(41)$$

where

$$g_2(\omega_s) = \sqrt{\left|\beta_p^2\right|^2 k_{\omega_s} k_{\omega_i} - \left(\frac{\Psi_2(\omega_s)}{2}\right)^2}$$
(42)

If a state moves inside a TWJPA of length z = aN, the power gain will be  $G(\omega_s, aN) = \langle \hat{a}_{R\omega_s}^{out}(aN) | \hat{a}_{R\omega_s}^{out^{\dagger}}(aN) \rangle / \langle \hat{a}_{R\omega_s} | \hat{a}_{R\omega_s}^{\dagger} \rangle.$ 

## 3.3. Quantum Hamiltonian model based on discrete-mode operators

An alternative approach for the derivation of the quantum dynamics of a TWJPA is the one proposed in [32]. In this model, the quantum Hamiltonian for a 4WM parametric amplifier is expressed as the integral, along an arbitrary quantization length  $l_q$ , of the linear energy density stored in each element of the circuit. The energy stored per unit length in a Josephson junction can be derived from Eq. (5) by dividing each term by the elementary cell length *a* and replacing  $\Delta \Phi_n$  with its continuous counterpart. Instead, the energy stored per unit length in a capacitance C can be alternatively expressed in terms of flux difference  $\Delta \Phi$  or stored charge Q as

$$U_{C} = \frac{1}{a} \int_{t_{0}}^{t} VI \ dt' = \frac{1}{a} \int_{t_{0}}^{t} \frac{d\Delta\Phi}{dt'} \ C \frac{d}{dt'} \left[ \frac{d\Delta\Phi}{dt'} \right] \ dt' = \frac{1}{2} \frac{C}{a} \Delta\Phi(t) \frac{\partial^{2}\Delta\Phi}{\partial t^{2}}$$
(43)

$$= \frac{1}{a} \int_{t_0}^{t} \frac{Q}{C} \frac{dQ}{dt'} dt' = \frac{1}{2a} \frac{1}{C} Q^2(t)$$
(44)

under the assumption that  $\Delta \Phi(t_0) = 0$  and  $Q(t_0) = 0$ .

Therefore, the quantum Hamiltonian of the system can be expressed, with an approximation to the first nonlinear order, as

$$\hat{H} = \int_{l_q} \left[ U_J + U_{C_J} + U_{C_0} \right] dx \approx \\ \approx \int_{l_q} \left[ \left( \frac{1}{2aL_{J_0}} \Delta \hat{\Phi} - \frac{1}{24aL_{J_0}} \left( \frac{2\pi}{\Phi_0} \right)^2 \Delta \hat{\Phi}^3 + \frac{1}{2} \frac{C_J}{a} \frac{\partial^2 \Delta \hat{\Phi}}{\partial t^2} \right) \Delta \hat{\Phi} + \frac{1}{2a} \frac{1}{C_0} \hat{Q}_{C_0}^2 \right] dx$$

$$\tag{45}$$

where  $\hat{Q}$  and  $\hat{\Phi}$  are quantum operators. The former can be expressed, as suggested in [34] and adapted for discrete-mode operators in [36], as

$$\hat{Q}_{C_0} = \sum_n \frac{C_0}{a} \hat{V}_{C_0,n} = \sum_n \frac{C_0}{a} \sqrt{\frac{\hbar \omega_n a}{2C_0 l_q}} \left( \hat{a}_n \ e^{i(k_n x - \omega_n t)} + \text{H.c.} \right)$$
(46)

(here  $k_{-n} = -k_n$  and  $\omega_{-n} = \omega_n$ ).

Before defining the flux operator, it is necessary to define an effective inductance  $L_{eff}$  of the transmission line (modeled, as shown in **Figure 2**, as a parallel of the nonlinear Josephson inductance  $L_I$  and the capacitance  $C_I$ ):

$$\frac{1}{j\omega_n L_{eff}} = \frac{1}{j\omega_n L_J} + j\omega_n C_J \quad \text{hence} \quad L_{eff} = \frac{L_J}{1 - \omega^2 L_J C_J} \equiv L_J \Lambda_n \tag{47}$$

Using the telegrapher's equation [37], the discrete-mode current operator, under slowly varying amplitude approximation  $(\partial \hat{a}_n / \partial x \approx 0)$ , can be derived from the discrete-mode voltage operator as:

$$\hat{I}_{L_{eff}} = \sum_{n} \operatorname{sgn}(n) \sqrt{\frac{\hbar \omega_{n} a}{2L_{eff} l_{q}}} \left( \hat{a}_{n} \ e^{i(k_{n} x - \omega_{n} t)} + \text{H.c.} \right)$$
(48)

Therefore, the flux operator can be expressed as

$$\Delta \hat{\Phi} = \frac{L_J}{a} \hat{I}_{L_{eff}} \quad \text{where} \quad L_J(\Delta \Phi) = \frac{\Delta \Phi}{I_J} = \frac{\frac{2\pi}{\Phi_0} \Delta \Phi}{I_c \frac{2\pi}{\Phi_0} \sin\left(\frac{2\pi}{\Phi_0} \Delta \Phi\right)} = L_{J_0} \frac{\frac{2\pi}{\Phi_0} \Delta \Phi}{\sin\left(\frac{2\pi}{\Phi_0} \Delta \Phi\right)}$$
(49)

The recursive relation deriving from Eq. (49) can be solved iteratively. Exploiting a power series expansion of the sine function and considering just the first order of interaction, it results that

$$\Delta \hat{\Phi} = \sum_{n} \left[ \left[ 1 + \frac{\Lambda_n}{12} \left( \frac{2\pi}{\Phi_0} \Delta \hat{\Phi}^{(0)} \right)^2 + O\left[ \left( \frac{2\pi}{\Phi_0} \Delta \hat{\Phi}^{(0)} \right)^4 \right] \right] \Delta \hat{\Phi}_n^{(0)}$$
(50)

where  $\Delta \hat{\Phi}^{(0)}$  is the zero-order approximation of the flux quantum operator

$$\Delta \hat{\Phi}^{(0)} = \sum_{n} \Delta \hat{\Phi}_{n}^{(0)} = \sum_{n} \frac{k_{n}a}{\omega_{n}} \sqrt{\frac{\hbar \omega_{n}a}{2C_{0}l_{q}}} \left(\hat{a}_{n} \ e^{i(k_{n}x - \omega_{n}t)} + \text{H.c.}\right)$$
(51)

Substituting Eqs. (46) and (50) in Eq. (45), and limiting the expression to the first nonlinear order, the Hamiltonian for a 4WM amplifiers turns up

$$\begin{split} \hat{H} &= \sum_{n} \hbar \omega_{n} \left( \hat{a}_{n}^{\dagger} \hat{a}_{n} + \frac{1}{2} \right) + \sum_{n,m,l,k} \frac{-i\hbar^{2}a}{96L_{J_{0}}I_{c}^{2}l_{q}^{2}\Delta k_{nmlk}} e^{-i\Delta\omega_{nmlk}t} \left( e^{i\Delta k_{nmlk}l_{q}} - 1 \right) \\ &\times \{ \left( 1 - 4L_{J_{0}}\Lambda_{n}C_{J}\omega_{k}^{2} \right) \left( \hat{\hat{a}} + \text{H.c.} \right)_{n \times m \times l \times k} + 4L_{J_{0}}\Lambda_{n}C_{J} \left[ 2 \left( \omega \left( -i\hat{\hat{a}} + \text{H.c.} \right) \right)_{n \times m} \right) \\ &\times \left( \hat{\hat{a}} + \text{H.c.} \right)_{l \times k} + \left( \hat{\hat{a}} + \text{H.c} \right)_{n \times m} \left( \omega \left( -i\hat{\hat{a}} + \text{H.c.} \right) \right)_{l \times k} \right] \} \end{split}$$

$$(52)$$

where  $\tilde{a} \equiv \operatorname{sgn}(n)\sqrt{\Lambda_n \omega_n} \ \hat{a}_n$ ,  $\Delta k_{nmlk} \equiv \pm k_n \pm k_m \pm k_l \pm k_k$ ,  $\Delta \omega_{nmlk} \equiv \pm \omega_n \pm \omega_m \pm \omega_l \pm \omega_k$  (a  $\pm$  sign refers to a corresponding annihilation (creation) operator) and the subscript  $i \times j$  indicates a multiplication (i.e.,  $(\Lambda \omega)_{i \times j} = \Lambda_i \omega_i \Lambda_j \omega_j)$ .

Neglecting the constant zero-point energy and assuming a strong degenerate classical pump (as shown in [36])

$$\hat{a}_p \to -i\sqrt{\frac{\omega_p C_0 l_q}{2\hbar a}} A_p$$
 (53)

it is possible to approximate the Hamiltonian in Eq. (52) to the second order in  $\hat{a}_{s,i}^{(\dagger)}$  as

$$\hat{H}^{(CP)} \approx \sum_{n=s,i} \hbar \Big( \omega_n + \xi_n |A_p|^2 \Big) \hat{a}_n^{\dagger} \hat{a}_n - \hbar \Big( \chi A_p^2 \hat{a}_s^{\dagger} \hat{a}_i^{\dagger} + \text{H.c.} \Big)$$
(54)

where

$$\xi_n = \frac{k_p^2 a^2 \Lambda_n \omega_n}{32 I_c^2 L_{J_0}^2} \left(4 - 3\delta_{pn}\right) \left(1 + \frac{2}{3} \left(\frac{\Lambda_p}{\Lambda_n} + \frac{\Lambda_n}{\Lambda_p} - 2\right)\right)$$
(55)

represents the quantum self-phase modulation (when n = p) and the quantum cross-phase modulation (when n = s, i), whereas the coupling constant  $\chi$  is defined as

$$\chi = \frac{k_p^2 a^2 \sqrt{\Lambda_s \omega_s \Lambda_i \omega_i}}{16 l_c^2 L_{J_0}^2} \left( 1 + \frac{L_{J_0} C_J}{6} \left[ \omega_p \omega_s \left( -2\Lambda_p + 5\Lambda_s - 3\Lambda_i \right) \right. \right. \\ \left. + \omega_p \omega_i \left( -2\Lambda_p - 3\Lambda_s + 5\Lambda_i \right) + \omega_s \omega_i \left( 4\Lambda_p - 2\Lambda_s - 2\Lambda_i \right) \right] \right)$$
(56)

Starting from the Hamiltonian  $\hat{H}^{(CP)}$ , it is possible to calculate the Heisenberg equation of motion for the classical pump amplitude and for the quantum operators  $\hat{a}_s$  and  $\hat{a}_i$ , obtaining the coupled mode equations:

$$\frac{\partial A_p}{\partial t} = -i \Big( \omega_p + 2\xi_p |A_p|^2 \Big) A_p + 2i\chi^* A_p^* \hat{a}_s \hat{a}_i$$
(57)

$$\frac{\partial \hat{a}_{s(i)}}{\partial t} = -i \Big( \omega_{s(i)} + \xi_{s(i)} \big| A_p \big|^2 \Big) \hat{a}_{s(i)} + i \chi A_p^2 \hat{a}_{i(s)}^{\dagger}$$
(58)

In [32], the hypothesis under which the classical coupled mode equations Eqs. (12) and (13) can be obtained from Eqs. (57) and (58) is described in detail.

Moving to a co-rotating frame  $(\hat{a}_{s(i)} \rightarrow \hat{a}_{s(i)} e^{i\xi_{s(i)}|A_{p_0}|^2 z})$ , the Hamiltonian (Eq. (54)) can be expressed as

$$\hat{H}_{rot}^{CP} = -\hbar \left( \chi \left| A_p \right|^2 \hat{a}_s^{\dagger} \hat{a}_i^{\dagger} e^{-i\Psi_3 t} + \text{H.c.} \right)$$
(59)

where  $\Psi'_3 = \left(4\xi_p - \xi_s - \xi_i\right) |A_{p_0}|^2$ . In this frame, introducing the undepleted pump assumption (Eq. (58)) turns into

$$\frac{\partial \hat{a}_{s(i)}}{\partial t} = i\chi \left| A_{p_0} \right|^2 \hat{a}_{i(s)}^{\dagger} e^{-i\Psi_3' t}$$
(60)

whose solutions are

$$\hat{a}_{s(i)}(t) = \left[\hat{a}_{s(i)_{0}}\left(\cosh\left(g_{3}'t\right) + \frac{i\Psi_{3}'}{2g_{3}'}\sinh\left(g_{3}'t\right)\right) + \frac{i\chi|A_{p_{0}}|^{2}}{g_{3}'}\hat{a}_{i(s)_{0}}^{\dagger}\sinh\left(g_{3}'t\right)\right]$$
(61)

where the exponential complex gain factor is defined as

$$g'_{3} = \sqrt{|\chi|^{2} |A_{p_{0}}|^{4} - \left(\frac{\Psi'_{3}}{2}\right)^{2}}$$
 (62)

If a state spends a time *t* in the amplifier, the gain can be expressed as  $G_s^Q(t) = \langle \hat{a}_s^{\dagger}(t) \hat{a}_s(t) \rangle / \langle \hat{a}_{s_0}^{\dagger} \hat{a}_{s_0} \rangle$ .

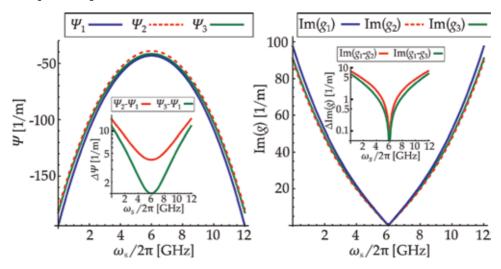
To make the results of this last treatment, in which the operators are expressed as a function of the time, comparable with the previous ones, in which the operators are expressed as a function of the space coordinate, we need to take into account the phase velocity of the tones. It turns out that:

$$\Psi_{3} = \Delta k + \left(4\xi_{p}\frac{\omega_{p}}{|k_{p}|} - \xi_{s}\frac{\omega_{s}}{|k_{s}|} - \xi_{i}\frac{\omega_{i}}{|k_{i}|}\right) \quad \text{and} \quad g_{3} = \sqrt{|\chi|^{2}|A_{p_{0}}|^{4}\left(\frac{\omega_{p}}{|k_{p}|}\right)^{2} - \left(\frac{\Psi_{3}}{2}\right)^{2}}$$
(63)

where  $\Delta k = 2k_p - k_s - k_i$  is the chromatic dispersion.

#### 3.4. Models comparison

The three exponential complex gain factors  $(g_i)$  and the three total phase mismatches  $(\Psi_i)$  derived in these models are analytically different but numerically similar, as shown in **Figure 3** (where the two insets report the differences between the quantum predictions and the classical ones).



#### Figure 3.

Comparison of total phase mismatches ( $\Psi_i$ ) and exponential complex gain factors ( $g_i$ ) predicted by the three treatments presented in Section 3. For these calculations, typical constructive parameters have been assumed:  $a = 50 \ \mu m$ ,  $I_c = 5 \ \mu A$ ,  $C_J = 300 \ fF$ , and  $C_o = 35 \ fF$ , in such a way that the characteristic impedance is  $Z \approx 50 \ \Omega$ . Furthermore  $\omega_p/2\pi = 6 \ GHz$  and  $I_p = Ic/2$ . In the insets, the differences between the quantum predictions and the classical ones are presented.

It is important to observe that in Eqs. (17), (41), and (61), the last term is always equal to zero in the case of a zero initial idler amplitude. In such a case, and under the hypothesis of a perfect phase matching ( $\Psi_i = 0$ ),  $g_i$  is real and the amplification gain increases exponentially with the line length; whereas, in the case of a nonzero phase mismatch,  $g_i$  is imaginary and the gain increases quadratically [11].

# 4. Conclusions

In the present chapter, we have presented the state-of-the-art of the experimental evidences in the field of Josephson junctions-based traveling-wave metamaterials through a historical review in Section 2. Moreover, in Section 3, we have reported three different theoretical approaches for the prediction of a TJWPA dynamics, in the particular case of a 4WM process. Assuming similar simplifying hypothesis, like the use of a classical undepleted degenerate pump, the presence of slowly varying fields along the transmission line and approximating the nonlinearities of the system up to the first order, a similar expression for the signal amplitude (or field annihilation/creation operators in the case of quantum theories) expressed in a co-rotating frame, is derived in the three treatments. Although the results of the quantum theories are similar to the classical ones, the description of the system dynamics with a quantum theory grants the possibility to evaluate photon-number distributions, squeezing effects and averages, standard deviations or higher-order moments of the measurements operators, taking into account the commutation relations between operators explicitly. For instance, detailed calculations of the output state of a TWJPA in the case of a single-photon input state and in the case of a coherent input state are presented in [32].

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# **Author details**

Luca Fasolo<sup>1,2†</sup>, Angelo Greco<sup>1,2†</sup> and Emanuele Enrico<sup>2\*</sup>

1 Politecnico di Torino, Torino, Italy

2 INRiM - Istituto Nazionale di Ricerca Metrologica, Torino, Italy

\*Address all correspondence to: e.enrico@inrim.it

<sup>†</sup> These authors contributed equally.

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# Chapter 6

# Mini Review: Recent Green Advances on the Preparation of $V_2O_5$ , ZnO, and NiO Nanosheets

Daniel Likius, Ateeq Rahman, Elise Shilongo and Veikko Uahengo

# Abstract

The past decade has seen a surge in the development of research on nanomaterial in the area of mixed metal oxides to fabricate ultrathin films, also known as nanosheets. In this review, different fabrication techniques of metal oxide nanosheets, such as vanadium, nickel, and zinc oxide, are presented. The chapter has also highlighted different ways of how to create smaller, affordable, lighter, and faster devices using vanadium, nickel, and zinc oxides. A detailed description of the synthesis and characterization using scanning electron microscope (SEM) and transmission electron microscope (TEM) for various shapes of nanomaterials is discussed in detail including factors that influence the orientation of nanosheets.

Keywords: nanosheets, nanoroses, nanoshapes, vanadium, nickel, zinc oxides

# 1. Introduction

Over the past decades, research efforts in nanoscience and nanotechnology has grown extensively globally due to the fabrication techniques of nanosheets that have attracted a great deal of research activities because of their unique physicochemical properties [1]. These properties have enabled scientists to be able to design and precise control over specialized morphologies of nanomaterials [2]. Consequently, the use of nanomaterials, the tremendous potential of "nano" approaches to revolutionize the ways in which matter is synthesized, fabricated and processed is already apparent. Currently, atoms, molecules, clusters and nanoparticles are used as functional and structural units for preparing advanced and totally new materials on the nanometer length scale [3–6]. The physicochemical properties of these nanomaterials usually depend on the meticulous property employed during the fabrication process: usually by changing the dimensions of the functional and structural units of the material as well as controlling their surface morphology, it is therefore possible to tailor functionalities in exceptional ways.

Moreover, the development of this multidisciplinary field was undoubtedly accelerated by the advent of relatively recent technologies that allow the visualization, design, characterization and manipulation of nanoscale systems. Generally, a nanosheet is a two-dimensional (2D) nanostructure with thickness in a scale ranging from 1 to 100 nm. Additionally, compare to other materials such as graphene, transition metal oxide nanosheets have attracted a lot of attention recently due to

their unique morphological advantages, and have shown a promising physicochemical properties for various applications. However, the fabrication of these transition metal oxide ultrafilms with controlled particles size and thickness remains a greater challenge for both fundamental study and applications. This chapter focuses on the synthesis of vanadium, nickel and zinc oxide nanosheets. The main basis for selecting these metal oxides chosen for investigation is based on the following highlights: vanadium (V), NiO, and ZnO are a highly abundant elements in the Earth's crust. Its oxides have been well known for multioxidation states (II–V) and various crystalline structures including VO<sub>2</sub>, V<sub>2</sub>O<sub>5</sub>, and V<sub>6</sub>O<sub>13</sub>. Vanadium, NiO and ZnO exhibit excellent interactions with molecules or ions, outstanding catalytic activities, and/ or strong electron–electron correlations [9–11].

Moreover, it also describes the morphological structures characterized by SEM and TEM techniques which include the demonstration on how these transition metal oxides change their morphology and tunable mesoporosity depend on the starting materials and heat treatment temperature.

# 2. Vanadium oxide nanosheets' preparation and characterization by SEM and TEM

Due to the chemical structure stability as well as the excellent physicochemical properties of vanadium oxides, these properties have attracted extensive attention for decades [7-10]. One of these vanadium oxides is vanadium pentoxide  $(V_2O_5)$ which is known as one of the best materials in nanotechnology study. Researchers have widely explored the V<sub>2</sub>O<sub>5</sub> especially in alkali metal ion batteries [10]. Taking the inherent relationship between the microstructure and macroscopic properties in mind, the distinctive physicochemical properties can be synchronized and controlled via the approach of controllable synthesis of micro-/nanostructured materials. V<sub>2</sub>O<sub>5</sub> nanosheets with various nanostructures such as nanosheets [11], nanoflowers [9], nanobelts [9], nanowires [8], nanoarrays, nanorods, nanobelts, nanonails, nanobridges, nanoprisms, nanotubes, nanobelts, nanorings, nanowhiskers, nanocombs, nanohelixes, nanosprings, nanopropeller, nanobows, nanocages, nanodisk, nanopoints, nanozigzag, nanostrings [9–11], and nanopores [8] have been fabricated. Moreover, the surface energy and surface defects of the active material are believed to contribute to the superior electrochemical performances has been developed and showed unique performances towards these specialized application. Peng et al. [11] reported V<sub>2</sub>O<sub>5</sub> nanosheets with large area had been prepared via a freeze-drying process and following annealing treatment. In addition, the phase structure and morphology of  $V_2O_5$  attained at different annealing temperatures was also systemically investigated. Xu et al. [12] reported the synthesis of V<sub>2</sub>O<sub>5</sub> nanosheets by freeze drying method which uses hydrogen peroxide, freeze drying; post annealing and finally nanosheet can be obtained. The annealing temperature exhibited considerable influence on the microstructure of  $V_2O_5$  nanosheets.  $V_2O_5$  nanosheets obtained at annealing at different temperatures of 400, 450, 500 and 550°C exhibited comparatively in larger size, smaller thickness and smoother surface. Figure 1 outlines the synthesis of V<sub>2</sub>O<sub>5</sub> nanosheets as reported by Peng et al. [11].

**Figure 2** shows the SEM images of  $V_2O_5$  heat treatment at different temperature points reported by Xu et al. [12]. For  $V_2O_5$  precursors in **Figure 2a**, layered particles are exhibited all over scattered the observed zoom. **Figure 2b** shows  $V_2O_5$  annealed at 350°C with nanosheet microstructure with the transverse dimension greater than 10 µm and the thickness of less than 20 nm. As the heat treatment temperature increased to 400°C as shown in **Figure 2c**, the transverse dimension increased while the surface morphology became smoother. The thickness of  $V_2O_5$  nanosheet increased Mini Review: Recent Green Advances on the Preparation of V<sub>2</sub>O<sub>5</sub>, ZnO, and NiO Nanosheets DOI: http://dx.doi.org/10.5772/intechopen.88765

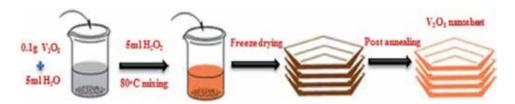
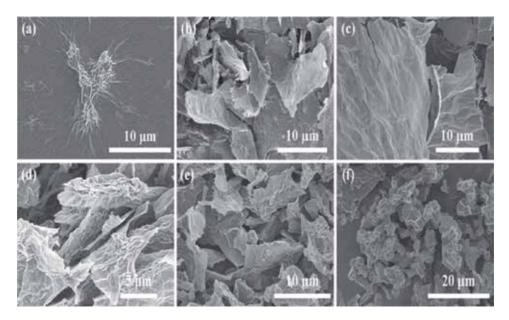


Figure 1.

Synthesis of V<sub>2</sub>O<sub>5</sub> nanosheets by freeze drying method [11].



#### Figure 2.

SEM images of  $V_2O_5$  nanosheet obtained at different temperature points: (a)  $V_2O_5$  precursor, (b) 350°C, (c) 400°C, (d) 450°C, (e) 500°C, and (f) 550°C [11, 12].

by increasing the heat treatment temperature to 450°C (in **Figure 2d**) and some nanosheets gradually crumpled and agglomerated as the heat treatment temperature increased to 500°C (**Figure 2e**). The surface morphology of  $V_2O_5$  heat treated at 550°C (**Figure 2f**) shows a mixture of agglomerated nanosheets and some regular polyhedral structures. The trend in the change of the morphological structures of  $V_2O_5$  revealed that the heat treatment temperature possessed significant influence on the microstructure of  $V_2O_5$ . Finally, the  $V_2O_5$  nanosheet heat treated at 400°C exhibited the optimal morphology with the largest size of transverse dimension and the thinnest thickness; hence 400°C is the optimal temperature for the fabrication of  $V_2O_5$  nanosheet.

Liang et al. [13] reported the synthesis of vanadium nanosheets that the uniform  $V_2O_5$  nanosheets were obtained by calcining the solvothermally prepared  $VO_2$  nanosheets in air at 350°C for 2 h with a heating ramp of 1°C min<sup>-1</sup>. Other scholars such as Cheng [14] also reported the synthesis of self-assembled  $V_2O_5$  nanosheets/ reduced graphene oxide (RGO) hierarchical nanocomposite nanosheet also using solvothermal method. In this nanocomposite, the  $V_2O_5$  nanosheets assembling on the RGO constitutes a 3-D hierarchical nanostructure with high specific surface area and good electronic/ionic conducting path as shown in **Figure 3** [14].

The SEM images shown in **Figure 4** were obtained to study the morphology and the structure of the as-prepared  $V_2O_5$  nanosheets/RGO hierarchical nanostructures [14]. As shown in **Figure 4a**, large 2-D free-standing nanosheets are observed. Similarly, it can be found from close examination from **Figure 4b** that the  $V_2O_5$  nanosheets/

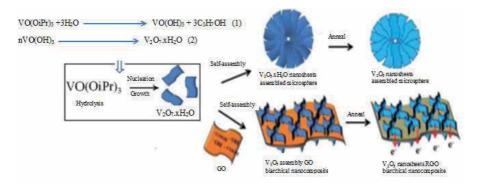


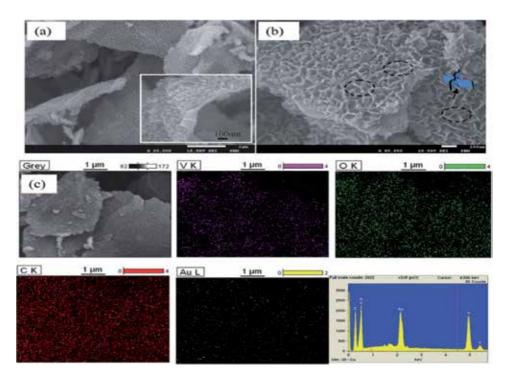
Figure 3.

Schematic illustration of the formation of 3-D V<sub>2</sub>O<sub>5</sub> nanosheets/RGO hierarchical nanocomposite [14].

RGO nanocomposite is made up of multiple 2-D nanosheets on the surface of graphenenanosheets (GNS) [14]. Hence, without the addition of graphite oxide (GO), it is found that only 1-D lower-like V2O5 spheres consisting of many nanosheets are formed under the similar conditions. The TEM images in **Figure 5** shows that the  $V_2O_5$ microspheres are composed of closely assembled nanosheets. Hence, by using GNS as the support, the formation of such a 3-D structure implies the effective growth of  $V_2O_5$ nanosheets on the GNS. The structure can be further unraveled by element mapping images of carbon, vanadium and oxygen in the V2O5 nanosheets/RGO composite. It can be seen from **Figure 4c** that the carbon, vanadium and oxygen distributions are relatively uniform; carbon is also well dispersed all over the composites, suggesting the homogeneous dispersion of  $V_2O_5$  on the GNS. TEM images in Figure 5a and b further show that the thin V<sub>2</sub>O<sub>5</sub> nanosheets are uniformly distributed on the graphene sheets over a large area in the nanocomposite. The HR-TEM image in Figure 5c taken on an individual V<sub>2</sub>O<sub>5</sub> nanosheet clearly shows crystal lattices with a d-spacing of 0.44 nm, corresponding to (001) planes of a crystalline orthorhombic phase of  $V_2O_5$ . The selected Figure 5a and b shows SEM images of V<sub>2</sub>O<sub>5</sub> nanosheets/RGO hierarchical nanocomposite at different magnifications, respectively. The insert in Figure 4a shows a profile of a single nanocomposite sheet; **Figure 4c** shows SEM image of  $V_2O_5$ nanosheets/RGO hierarchical nanocomposite with corresponding EDS maps of V, O and C elements (the Au is from sputter coating) [14].

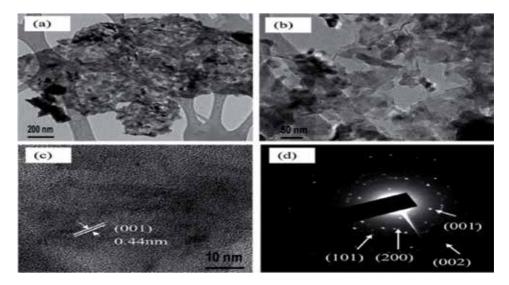
**Figure 6** presents field emission scanning electron microscopy (FE-SEM) and transmission electron microscopy (TEM) images of the  $V_2O_5$  nanosheets/CNTs nanocomposite as reported by Wang et al. [14] using the freeze drying process. It is observed that  $V_2O_5$  nanosheets and CNTs construct a uniform and homogeneous macro-morphology **Figure 6(a)**.

The carbon nanotubes (CNTs) act as "supporting-steel-like" architectures and the  $V_2O_5$  nanosheets are anchored on the CNTs. They combine to form a highly porous structure as shown in **Figure 6b**. The TEM images in **Figure 6d** and **e** confirms that the  $V_2O_5$  nanosheets and CNTs form a 3D interpenetrating of network structure. It is usually recognized that most nanosheets are easily overlapped and get bunched up to form bigger bulk due to the Ostwald ripening process, leading to the decrease of actually active surface and capacity loss for electrode materials [15]. In a study reported by Chen et al. [16],  $V_2O_5$  nanosheets are anchored on the surface of CNTs without an overlap phenomenon. As the addition ratio of CNTs increases from 0 to 20 wt%, the morphology of the  $V_2O_5$  nanosheets/CNTs nanocomposite becomes much more homogenous and the size of the  $V_2O_5$  nanosheets becomes much smaller. The mechanism behind the formation of the 1D and 2D nanostructures can be explained in such a way that the functional groups on the CNT Mini Review: Recent Green Advances on the Preparation of V<sub>2</sub>O<sub>5</sub>, ZnO, and NiO Nanosheets DOI: http://dx.doi.org/10.5772/intechopen.88765



# Figure 4.

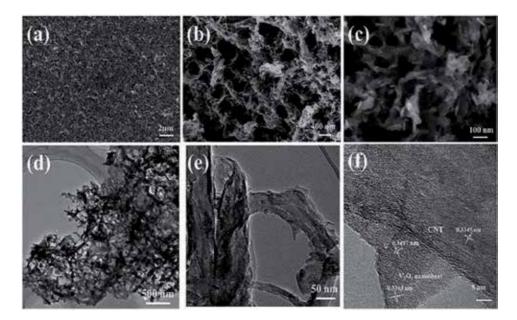
(a and b) SEM images of  $V_2O_5$  nanosheets/RGO hierarchical nanocomposite at different magnifications. The inset in (a) shows a profile of a single nanocomposite sheet; (c) SEM image of  $V_2O_5$  nanosheets/RGO hierarchical nanocomposite with corresponding EDS maps of V, O and C elements (the Au is from sputter coating) [14].



#### Figure 5.

(a and b) TEM images of  $V_2O_5$  nanosheets/RGO nanocomposite at different magnifications; (c) HR-TEM image of  $V_2O_5$  nanosheets/RGO nanocomposite; and (d) selected area electron diffraction (SAED) pattern [14].

surface act as the reaction centers. When the CNTs added into the vanadium oxide precursor solution, the vanadium oxytriisopropoxides bonded to the surface of the functional groups of CNT involved the electrostatic interaction bonding. During the freeze drying process, the hydrates in the  $V_2O_5$  sol are frozen and removed [16].



#### Figure 6.

The morphology observation of the  $V_2O_5$  nanosheets/CNTs nanocomposite. (a), (b) low- and (c) highmagnification FESEM images; (d), (e) TEM and (f) HRTEM images [14].

# 3. Nickel oxide nanosheets preparation and characterization by SEM and TEM

Nickel (II) oxide (NiO) and nickel (II) composites in meticulously have attracted substantial interest because of a broad range of applications, namely magnetic materials [17], photovoltaic [18] Li ion batteries [19], catalysis [20], gas sensors [21], p-type transparent conducting films, infrared detectors, storage oxygen materials, fuels cells, supercapacitors, ferromagnetic oxides, gas sensors and luminescence materials, photochromic materials, [22], electrochromic windows [23], biomedicine, desalination, waste water treatment, energy related fields, catalytic reduction, adsorption, photocatalytic reduction, degradation, magnetic material, reinforcing agents in composites [24, 25]. Different methods have been reported for the synthesis of NiO, such as sol–gel [26], microemulsion [27], hydrothermal [28], co-precipitation, precipitation [29], sonochemical [15], microwave [30], metal–organic chemical vapor deposition (MOCVD), sputtering method [30], pulsed laser deposition (PLD), infrared irradiation, thermal decomposition, thermal evaporation and condensation [29, 30].

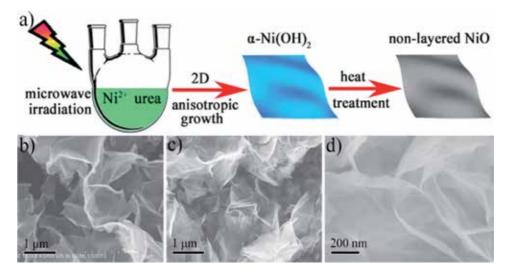
Nickel oxide is a predominantly interesting oxide because of its chemical and magnetic properties. There are various potential attractive applications of NiO in a variety of fields, such as absorbents, catalysis, battery cathodes, gas sensors, electrochromic films, magnetic materials, active optical fibers and fuel cell electrodes [31, 32]. The best know method for the fabrication of NiO nanosheets is through thermal decomposition of either nickel salts or nickel hydroxides. During this process the organic or halides on nickels burned which results in inhomogeneity of morphology and crystallite size of nickel oxide. Many efforts have been exerted to prepare NiO possessing controlled these inhomogeneity of morphology and crystallite size [33–36]. Although morphologically controlled synthesis of NiO nanocatalyst is becoming very much significant for catalytic reactions. These materials showed good electrochemical performance because of their special structure [37–41]. The fundamental process usually depends on the liquid-phase growth

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of ultrathin lamellar nickel hydroxide precursor under microwave irradiation as reported by Chen et al. [16]. Using urea (NH<sub>3</sub>), during this stage, the reactions experience a homogeneous alkalinization of nickel (II) nitrate. This is followed by the hydrolysis of sodium hydroxide (NaOH) using inductive effect provided by microwave irradiation at low-temperature condition. The setup of the microwave reactor with a three-necked flask experiment is illustrated in **Figure 7a**. The optimal thermodynamic and kinetic factors are important parameters to control for the growth of ultrathin intermediate [41, 42]. The formation of nanosheets is dominated by a self-assembly and oriented attachment mechanism. The swift microwave heating allows the best saturation of reactant species for 2D anisotropic, which causes a quick formation of ultrafine nanocrystals and then spontaneous self-assembling facilitated by natural driving force of lamellar nickel hydroxide. The  $\alpha$ -Ni(OH)<sub>2</sub> nanosheets can be totally decomposed in to NiO when annealed at 300°C (**Figure 7b-d**).

It is well noted that water molecule is a crucial reaction parameter in the fabrication of NiO nanosheet [42] (**Table 1**). In the presence of light amount of water molecules in the reactor, NiO samples are able to gain self-supporting mechanism and also exhibit a large area sheet-like morphology. However, when the amount of water decreased in the reactor, the product aggregated and became a flower-like quasi-spherical 3D hierarchical structure as shown in **Figure 8a**. It was however, observed that, they do regain their sheet-like building blocks as the water molecules removed (**Figure 8b**). In the total absence of water, the NiO surface morphology turned into spherical aggregates (**Figure 8c**) causing the disappearance of nanosheets arrangement.

Baghbanzadeh et al. [42] is in agreement with the above statements as they reported that the current methodology demonstrates that directional hydrophobic attraction plays essential role in determining morphologies of final products. There are two factors that influence the formation of nanosheet during microwave irradiation to assist liquid-phase growth procedure. The first factor is the layered-structural nature and the second factor is the hydrophobicity. As mentioned above, the 2D anisotropic growth of nanosheets need a large driving force, thus it is possible for them to grow into nanolayer to form layered crystals. This is achieved due to the intrinsic driving force provided by lamellar Ni(OH)<sub>2</sub>



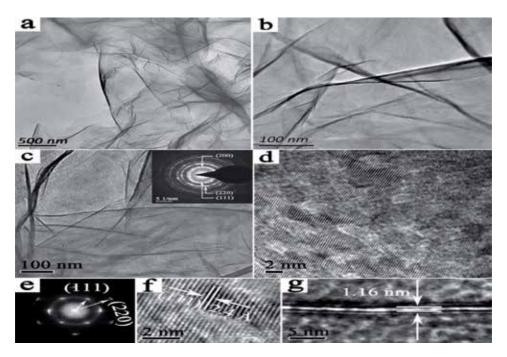
#### Figure 7.

(a) Schematic illustrating synthesis of nanosheets; FESEM images of (b) a-Ni(OH)<sub>2</sub> and (c), (d) NiO nanosheets [41, 42].

S. No.	Nanostructures	Particle size	Methods/conditions	Figure/ Reference
1.	$V_2O_5$ nanosheets	10–20 µm	Freeze drying 80°C, mixing	1–2/[1]
2.	V <sub>2</sub> O <sub>5</sub> nanosheets RGO hierarchal nanocomposite	1 µm	a. Hydrothermal b. Condensation c. Nucleation calcination 350°C 2 h	3/[14]
3.	NiO nanolayered	200 nm 1 μm 20 μm	a. Microwave irradiation b. A-Ni(OH) <sub>2</sub> 2D anisotropic growth c. Heat treatment	7/[41, 42] 5/[14]
4.	NiO flower flake architecture	2 μm, 1 μm, 500 nm	SDS assisted self-nucleation assembly growth 6, 9, 12 h	10/[45]
5.	Needle-like NiO nanosheets	2 μm, 10 μm, 1 μm	a. Complexation b. Aggregation c. Fabrication	12/[46]
6.	ZnO nanosheets	200 μm, 3 μm, 500 nm	Preheating by hydrothermal method 0–24 h	14/[48] 15/[48]

#### Table 1.

Nanostructures of different fabrication techniques.



## Figure 8.

(a) Low and (b) high magnification FESEM images of a-Ni(OH)<sub>2</sub> nanosheets; (c) TEM image (the inset showing SAED pattern), (d) a planar HRTEM image, (e), (f) the corresponding FFT pattern and enlarged HRTEM image recorded from (d), and (g) a vertical HRTEM image of NiO nanosheets [41, 42].

which is enough for the 2D anisotropic growth under microwave irradiation. From this, one can tell that layered-structure is a necessary requirement for the formation of 2D morphology. Mini Review: Recent Green Advances on the Preparation of V<sub>2</sub>O<sub>5</sub>, ZnO, and NiO Nanosheets DOI: http://dx.doi.org/10.5772/intechopen.88765

As mentioned above, hydrophobicity is also one of the factors that influence the formation of nanosheet. The hydrophobicity is necessary to bring about the directional hydrophobic attraction between nanocrystals and water molecules, and it forms two phases that interface where the excessive surface energy can be accommodated [42]. There must be a balance of anisotropic hydrophobic attraction and electrostatic interaction for the spontaneous attraction of nanocrystals in order for nanosheets to be formed [43, 44]. This interaction is important to prevent their potential of shrinking and aggregating, hence allow the epitaxial orientation of the crystals. This means that the presence of the hydrophobicity terminate their stacking and packing, leading to ultrathin 2D structure rather than 3D graphite-like layered framework.

Weng et al. [45] reported the synthesis of NiO nanoflowers by hydrothermal process. **Figure 9** shows the SEM images of as-synthesized NiO. **Figure 9a** and **b** illustrates the novel hierarchical flower-like structure of the sample, which has a high similarity with the natural peony flower (inset). In **Figure 9c**, the enlarged patterns evidently exhibit that the formation of these flake-flower architectures is attributed to the partial overlapping of numerous irregular-shape ultrathin nanosheets with a thickness of approximately 10–20 nm, which are closely packed and form a multilayered structure [45].

Weng et al. [45] further reported the growth mechanism of SDS-assisted self-assembly and transformation mechanism for the synthesis of NiO flake-flower architectures. This was projected on the basis of the experimental observations and analysis reported by Zhang et al. [44] by preparation method using hydrothermal process whereby nickel chloride hexahydrate and urea served as nickel source and precipitant, respectively. The reactions with the formation proceeding are shown in Eqs. [44]:

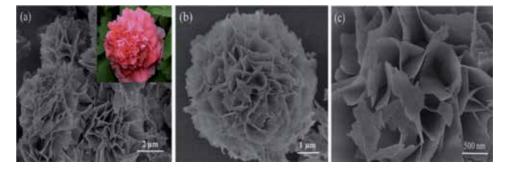
$$CO(NH_2)_2 + 3H_2O \rightarrow 2NH_3H_2O + CO_2$$
(1)

$$\mathrm{NH}_{3}\mathrm{H}_{2}\mathrm{O} \rightarrow \mathrm{NH}^{4+} + \mathrm{OH}^{-}$$

$$\tag{2}$$

$$CO_2 + 2OH^- \rightarrow CO^{2-}_3 + H_2O \tag{3}$$

$$3Ni^{2+} + 4OH^{-} + CO_2^{3-} + 4H_2O \rightarrow Ni_3(CO_3) (OH)_4 \cdot 4H_2O$$
 (4)



**Figure 9.** (*a*)–(*c*) SEM images of the final hierarchical NiO flake-flower architectures [45].

$$Ni_{3}(CO_{3})(OH)_{4} \cdot 4H_{2}O \rightarrow 3NiO + CO_{2} + 6H_{2}O$$
(5)

In the initial stage, the urea in aqueous solution began to hydrolyze and release ammonia,  $OH^-$  anions as well as  $CO_2^{3^-}$  anions according to Eqs. (1)–(3). The Ni<sup>2+</sup>

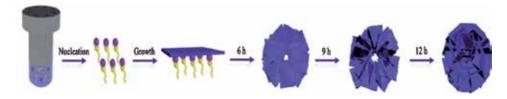
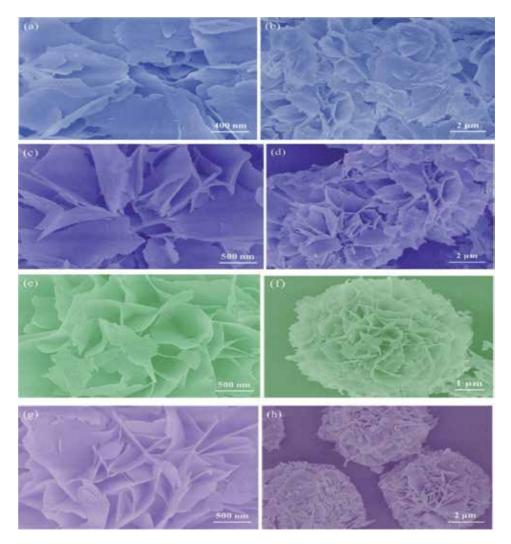


Figure 10.

Plausible SDS-assisted self-assembly and transformation mechanism for the synthesis of NiO flake-flower architectures [45].



### Figure 11.

(a) and (b) SEM images of NiO samples obtained at  $160^{\circ}C$  for 6 h. (c) and (d) SEM images of NiO samples obtained at  $160^{\circ}C$  for 9 h. (e)–(f) SEM images of NiO samples obtained at  $160^{\circ}C$  for 12 h. (g) and (h) SEM images of NiO samples obtained at  $160^{\circ}C$  for 12 h. (g) and (h) SEM images of NiO samples obtained at  $160^{\circ}C$  for 15 h [45].

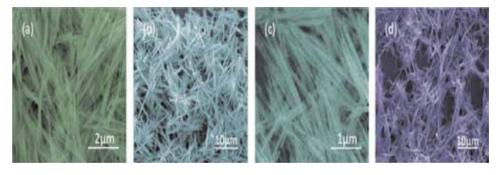
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species then reacted with  $OH^{-}$  and  $CO_{2}^{3-}$  ions to produce nickel carbonate as shown in Eq. (4). By increasing the temperature and the pH value of the solution in Eq. (5), tiny single crystals nucleated steadily due to the thermodynamic and dynamic effects [16]. With time, these tiny homogeneously nucleated crystals started to aggregate to form nanosheets through spontaneous self-organization of neighboring particles aiming to have an identical crystal orientation at the planar interface, process known as oriented attachment [31]. During oriented attachment, SDS, which is an ionic surfactant, temporarily, acted also both as a structure-directing agent as well as a capping agent in the development of aggregation and enhancing absorption on the surface of the tiny crystals, respectively, in order to reduce the superficial area and their energy as illustrated in Figure 10 [45]. However, longchain alkyl groups from SDS produced external steric repulsion against the van der Waals attractive force so that the particles do not aggregate excessively [33, 34], which contributed to the ultra-thin nanosheets. Figure 11 shows the SEM images of NiO nanosheets produced at the same heat treat temperature but at different annealing time.

Wen et al. [46] reported the synthesis of needle shaped NiO nanosheets by hydrothermal process as presented in **Figure 12**. The surface structures of both precursor (NiC<sub>2</sub>O<sub>4</sub>.2H<sub>2</sub>O, (EG)) and final products (NiO) were characterized by FE-SEM observations. **Figure 13** shows the needle-like and flower-like structures of NiC<sub>2</sub>O<sub>4</sub>.2H<sub>2</sub>O produced by varying amount of sodium oxalate [46]. The needle-like NiC<sub>2</sub>O<sub>4</sub>.2H<sub>2</sub>O structures in **Figure 13a** were synthesized by using 0.061 g Sodium oxalate. By decreasing the amount of sodium oxalate to 0.022 g, the nanoflowers of NiC<sub>2</sub>O<sub>4</sub>.H<sub>2</sub>O were generated as shown in **Figure 2b** [46].



Figure 12. Synthesis of needle-like NiO nanosheets [46].



#### Figure 13.

SEM images of the NiC<sub>2</sub>O<sub>4</sub>.2H<sub>2</sub>O and NiO: (a) and (c): needle-like architectures; (b) and (d): needle-flower architectures [46, 47].

# 4. Zinc oxide nanosheets preparation and morphology study by SEM and TEM

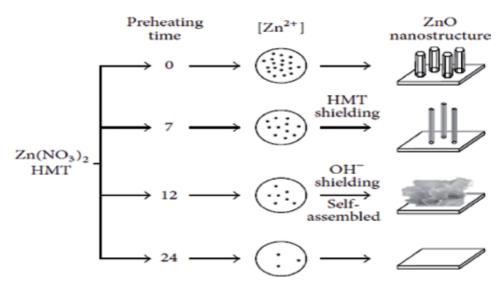
Wang et al. reported [48] the synthesis of ZnO nanostructures using a surfactant-free hydrothermal method. A schematic growth diagram of the ZnO nanostructures fabricated by preheating hydrothermal method is shown in **Figure 14**.

The morphology of the as-grown flower-like ZnO architectures were then investigated by field-emission scan electron microscopy (FE-SEM) and the results are shown in **Figure 15**.

The SEM image shown in **Figure 15(a)** demonstrates that the sample obtained after preheating for 12 h have high density flower-like ZnO architectures uniformly grow and extremely disperse in the substrates without any aggregation, with specifying high yield and good uniformity accomplished with this fabrication condition [48]. The middle magnification FE-SEM image in **Figure 15(b)** confirms that individual flowers has a diameter of about 40–50 $\mu$ m and consists of hundreds of thin curved nanosheets, which are spoke wise, projected from a common central zone. As presented in **Figures 15(c)** and (d), high magnification FE-SEM image reveals that these ZnO nanosheets produced with the shape of flower-like architectures. The white squares in **Figure 15(e)** represent the low density ZnO nanorods which can be seen on the space without flower-like ZnO. The shape of ZnO nanorods were found to be hexagonal prism with a pyramidal top and smooth side surface and the majority of the ZnO nanorods are perpendicular to the ZnO supportive substrate. This was proved by increasing the magnification of the SEM image as shown in **Figure 15(f)**.

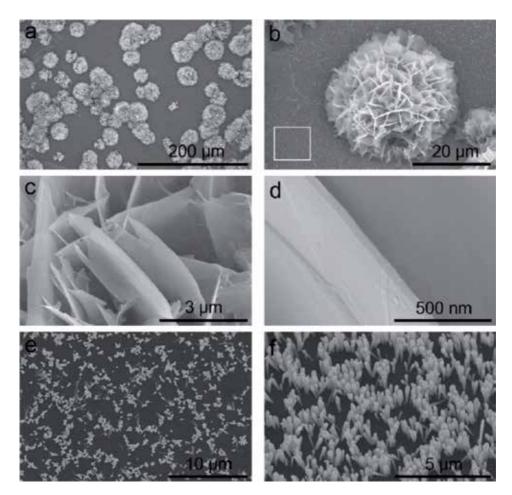
Wang et al. [48] also reported on the shapes of ZnO architectures removed from their supportive substrates using TEM images as shown in **Figure 16**.

The TEM images proved that the fabricated ZnO nanorods are made up of projected thin nanosheets as represented in **Figure 15a** [46, 47]. These ZnO nanosheets were found to be thin and have flat surfaces as shown in **Figure 15b**. Two sets of well resolved parallel lattice fringes are observed in high resolution TEM in **Figure 15c** [47]. The interplanar spacing is corresponding to that of {0002}





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#### Figure 15.

FESEM images of flower-like ZnO architectures grown on ZnO thin film coated glass substrates. (a) Low magnification, (b) middle magnification, (c) and (d) high magnification of FESEM images of ZnO flowers, and (e) and (f) middle magnification of FESEM images from the space without ZnO flower, as indicated by the white square in (b) [48].

and {01–10} planes of ZnO crystals. **Figure 15d** is its SAED pattern and exhibits visible bright spots identical to all the crystal planes of the wurtzite ZnO, indicating a single crystalline with a good crystal quality. Based on HRTEM and SAED results, Wang et al. [49] suggested that the single crystal wurtzite ZnO nanosheet grows along [0001] and [01–10] crystallographic directions within the (2–1–10) plane. Hence, the flower-like ZnO growth process is summarized in **Figure 14**. Wang et al. [49] reported on study,  $Zn^{2+}$  and  $OH^-$  are provided by hydration of  $Zn(NO_3)_2$  and HMT respectively. Therefore, the key chemical reactions can be formulated as shown in Eqs. (6)–(9):

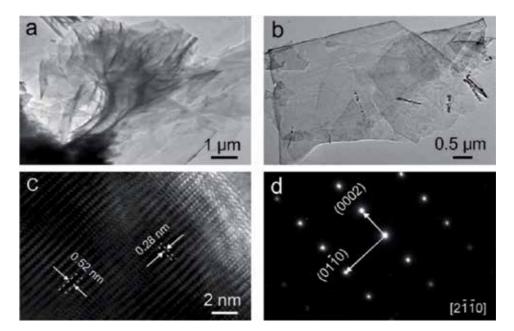
$$(CH_2)_6N_4 + H_2O + Heat \rightarrow 4NH_{3(g)} + 6HCHO_{(g)}$$
(6)

$$\mathrm{NH}_3 + \mathrm{H}_2\mathrm{O} \to \mathrm{NH}_4^+ + \mathrm{OH}^- \tag{7}$$

$$Zn_{2+} + 2OH^{-} \rightarrow Zn(OH)_{2(s)}$$
(8)

$$Zn(OH)_2 \rightarrow ZnO_{(s)} + H_2O$$
(9)

Wang et al. [49] have reported that in order to produce flower-like crystals of ZnO nanosheet also known as ZnO nanoroses, sodium citrate must be added in the reaction to create uniformity in the synthesis. Usually, cathodic electrodeposition is employed for the growth on polycrystalline ZnO thin films of different morphological orientation range from 1D (nanorods), 2D (nanoplates) to 3D crystals. However, Illy et al. [50] reported that the 2D sheet only found to occur when 1D sheets are allowed to combine under specific electrochemical conditions. **Figure 17** represents star-like and flower-like ZnO crystals. There is a big



### Figure 16.

TEM images of flower-like ZnO architectures. Typical TEM images of (a) an individual ZnO flower and (b) a piece of ZnO nanosheet. (c) HRTEM image and (d) SAED image of a piece of ZnO nanosheet [48].



**Figure 17.** SEM images of the ZnO star-like crystals [50].

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variation regarding the shape and morphology of the ZnO crystals shown. The nature and number of the reactants involved, the secondary products, concentration as well as complex ions in the solution are the main factors that contribute to the kinetics of the crystal growth [50]. With regard to concentration, Illy et al. [50] demonstrated that in order to produce the ZnO stars-like crystals, the concentration of  $(CH_2)_6N_4$  must be in a 1 order of magnitude higher than  $Zn(NO_3)_2$ ·6H<sub>2</sub>O. In terms of secondary products as an important factor, it was found that the production of an excess of oxygen containing species in solution increased competition for the interaction with a limited number of Zinc ions. One would expect then a reduction in the size of the ZnO rods compared to those hydrothermally formed from an equimolar reactant solution. Hence, these methods of synthesizing different shapes of nanomaterials exhibit quite remarkable properties.

## 5. Conclusion

This review highlighted the fabrication and characterization of various shapes of metal oxide nanosheets which are characterized by SEM and TEM instruments. Over the past decade, there has been enormous development of research on nanosheets, in the area of metal oxides. This offers basically new capabilities to architect a broad array of novel materials in the area of metal oxides and structures on a molecular scale. This chapter summarizes different ways to create smaller, cheaper, lighter and faster devices using vanadium, nickel, and zinc oxides. Structurally controlled synthesis at large of these nanomaterials can be attained morphologically nanomaterials would have the same importance for as controlling the helical angle of carbon nanotubes which determines it applications. These materials have remarkable applications in the all the branches of science, engineering and medicine in semiconductor, electronics, biomedicine, catalysis, batteries waste water treatment, sensors, drug delivery and curing dreadful diseases and many more, which has brought about the new, developing and exciting research field called nanoscience/nanotechnology which is driving of the new millennium.

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## **Conflict of interest**

The authors of this chapter declare no conflict of interest.

Advances in Condensed-Matter and Materials Physics - Rudimentary Research to Topical...

# **Author details**

Daniel Likius<sup>1\*</sup>, Ateeq Rahman<sup>1\*</sup>, Elise Shilongo<sup>2</sup> and Veikko Uahengo<sup>1</sup>

1 Department of Chemistry and Biochemistry, Faculty of Science, University of Namibia, Windhoek, Namibia

2 Department of Physics, Faculty of Science, University of Namibia, Windhoek, Namibia

\*Address all correspondence to: daniels@unam.na and arahman@unam.na

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## Chapter 7

# Applications of Graphene Modified by Self-Assembled Monolayers

Gulsum Ersu, Yenal Gokpek, Mustafa Can, Ceylan Zafer and Serafettin Demic

## Abstract

Self-assembled monolayers (SAMs) are well-oriented molecular structures that are formed by the adsorption of an active site of a surfactant onto a substrate's surface. Aromatic SAMs were used to modify anode/hole transport layer interface in order to achieve preferable barrier alignment and charge carrier injection from anode to an organic-based thin film material. Other functions of SAMs include current blocking layers or moisture penetration blocking layers, dipolar surface layers for enhanced charge injection, and modification of work function of a material such as graphene acting as a spacer to physically separate and electrically decouple it from the substrate. Additionally, SAM modification of graphene leads to its electronic passivation at layers' edges, elimination of defects, and enhanced adhesion and stability. The surface modification with molecules capable of forming SAM is a fast, simple, low-cost, and effective technique for the development of novel materials especially for the production of electronic devices. The ability to modify its properties by SAM technique has opened up a wide range of applications in electronic and optoelectronic devices.

**Keywords:** self-assembled monolayer, graphene, surface modification, interface modification, optoelectronic devices

## 1. Introduction

The development of more efficient, multifunctional, and miniaturized electronic devices requires a continuous research in the area of suitable materials to meet the demand of the modern society. Self-assembled monolayers (SAMs), which are arranged spontaneously on surfaces of the substrate due to the chemical or physical interactions of molecules with a substrate, have gained considerable attention in the past decade. SAMs opened a way toward the miniaturization in microelectronics as well as tailoring the properties of surfaces such as graphene [1–6].

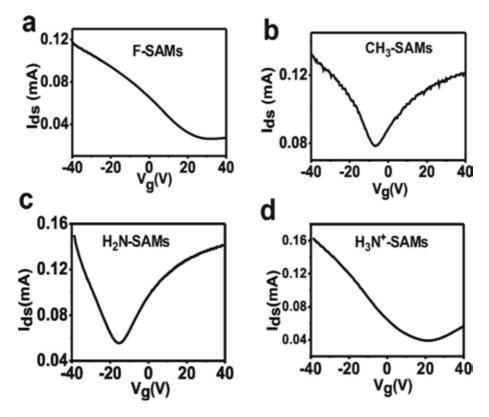
This review focuses on researches committed over the past decade about the modification of graphene via SAM technique. In Section 2, a brief overview of the modification methods of graphene with SAMs was given. In Section 3, the applications of graphene modified by SAMs are summarized and discussed.

## 2. Modification of graphene with self-assembled monolayers

Graphene is a good candidate material for many applications due to its unique optical, mechanical, and electronic properties [7–10]. Pristine graphene is a zero band gap material, chemically inert, and also insoluble in many organic and inorganic solvents [11–13]. Therefore, it cannot be used in many applications. In order to achieve commercial viability and provide to the specific needs of device applications, it is necessary to control the electrical properties of graphene without damaging its intrinsic properties. To fully utilize its potential, the surface and electronic structures of graphene have been modified via functionalization (post-synthesis) or doping (during in situ synthesis) methods [14–16]. Substitutional doping of graphene occurs during the synthesis by covalently bonding the chemical groups and thereby transforms carbon hybridization from  $sp^2$  to  $sp^3$  [17–19]. On the other hand, functionalization of graphene is a physical process involving the addition of functional species onto graphene sheets to manipulate van der Waals interactions occurring effectively among the graphene sheets. In the substitution process, electrons are exchanged between dopant molecules bonded onto the graphene surface and graphene. Surface charge transfer depends on the relative energy of the highest occupied molecular orbital (HOMO) or lowest unoccupied molecular orbital (LUMO) of the dopant with respect to the Fermi level of graphene [16, 20–23]. Many different chemical substances have been studied for the functionalization of graphene, and SAM technique is one of them. An ultrathin layer, SAM, can be uniformly formed on the surface by the attachment of the SAM-forming molecule through its functional group as a result of a covalent bond. This technique provides a suitable and flexible way to modify the surface properties of the substrate materials to some extent or completely depending on the molecular structure of acting as SAM-forming molecule. Recent reports have also shown that SAMs can significantly change the properties of graphene without sacrificing the intrinsic graphene performance. In order to modify the electronic properties of graphene by SAM technique, the usage of either electron donating or withdrawing terminal groups has been reported by Yan et al. [24]. As shown in **Figure 1**, the threshold voltage ( $V_{th}$ ) which corresponds to the neutrality point in graphene field-effect transistor (FET) devices shifted to positive values after the decoration of SiO<sub>2</sub> substrates by using fluorinated molecules (F-SAMs), indicating p-type doping of the graphene layer. For the graphene FET device made by CH<sub>3</sub>-SAMs and H<sub>2</sub>N-SAMs, the negative V<sub>th</sub> shift was observed, indicating p-type FET behaviors. This clearly indicates modification of the electronic properties of graphene which becomes available by suitably adapting the SAM techniques.

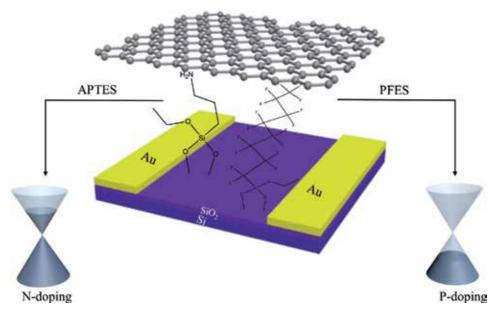
SAMs have been widely used to eliminate the Schottky barrier at the materials' interface by modifying the interface between graphene and its support substrate which is creating p-n junctions in graphene [25–27]. Sojoudi et al. used 3-aminopropyltriethoxysilane (APTES) and perfluorooctyltriethoxysilane (PFES) for the modification of the interface between transferred CVD-graphene films and its supporting dielectric [28]. Thus, n-type and p-type graphene was created by treating APTES and PFES, respectively. As shown in **Figure 2**, APTES and PFES are patterned on the same dielectric, thus creating a graphene p-n junction. They demonstrated that substrate functionalizing with these SAMs resulted in p-n junctions with controlled position and height.

Recent studies have shown that graphene functionalization has been enhanced significantly by electrochemical control [29–32]. Fermi level of graphene can be shifted and also increased its reactivity toward aggressive chemicals by application of electrochemical potential. The groups of Treossi and Palermo used electrochemical approach,



#### Figure 1.

 $I_{d,l}/V_{g}$  characteristics of graphene-based FET devices fabricated on (a) 1H,1H,2H,2H-perfluorooctyltriethoxysilane (F-SAMs), (b) butyltriethoxysilane (CH<sub>3</sub>-SAMs), (c) 3-aminopropyltriethoxysilane (H<sub>2</sub>N-SAMs), and (d) protonated form produced from the H<sub>2</sub>N (H<sub>3</sub>N<sup>+</sup>-SAMs) (this figure is reprinted from Ref. [24]).



**Figure 2.** Schematic representation of graphene *p*-*n* junction fabrication.

a fast and simple method, to functionalize graphene [33]. The electrochemical potential allowed good control over the morphology of the 4-docosyloxy-benzenediazonium tetrafluoroborate (DBT) suspended layer, which does not react randomly on the substrate, and also transformed the physisorption into a covalent chemisorption.

## 3. Applications of graphene/SAM structure

Graphene has well-known electrical properties, which may be utilized in various applications such as biosensors, environmental sensors, electronic and optical devices, etc. Modification with SAM can result in the change of properties at the interface, such as friction coefficient. The monolayer can also be utilized as a physical spacer, in order to enhance the sensing properties of the layer underneath. Apart from these applications, SAMs can be used in order to synthesize graphene, both by electrostatical assembly of graphene flakes onto the surface and by providing the carbon atoms that is required to assemble graphene from their own molecular structure.

### 3.1 Biosensor

The enhancement effect of SAM is widely used in the field of biosensor and biomedical. Shi et al. formed a SAM from 4-aminothiophenol (4-ATP) solution on gold substrate and placed the prepared substrate in graphene oxide (GO) solution vertically. Coupling reagents ethylene dichloride and N-hydroxysuccinimide (EDC and NHS, respectively) were added to promote the reactions between  $-NH_2$  groups of SAM molecules and -COOH groups of GO. After the device fabrication, cyclic voltammetry (CV) and electrochemical impedance spectroscopy (EIS) measurements were carried out, and ultrasensitive electrochemical Hg ion sensing properties were shown [34]. Sun et al. prepared GO and fluorescent SAMs with thrombin aptamer (TBA) fixed onto the outermost layer and used CdTe quantum dots as a fluorescence probe, which allow sensing biomolecules by interfacial energy transfer from CdTe in SAMs to GO. The measured fluorescence spectra showed that the increase of the intensity was related to the concentration of the target molecule (**Figure 3**) and the linear correlation was obtained by using GO which was necessary for defining the device as a sensor [35].

Thakur et al. prepared a graphene-based FET sensor using  $\alpha$ -ethyl-tryptamine (AET) to add functionality to the electrodes. This approach enables the electrostatical adsorption of functional groups that are present in GO monolayers, such as carboxylic acid and epoxide, by the amine end of AET. The selectivity and response time showed great results, being able to detect a single *E. coli* cell from a vast amount of sample (**Figure 4**). With the incorporation of suitable probing molecules, this approach could be a useful tool to detect other bacteria as well [36]. For related bacteria sensing applications, Chang et al. reported that 2-aminoethanethiol molecules were self-assembled onto Au electrodes by immersion, and then thermally reduced monolayer of GO was deposited on the electrodes due to electrostatic interactions. After some treatments, the device was incubated in the PBS containing anti-*E. coli* O157 antibodies and introduced as a high-performance FET chemical sensor and biosensor [37].

As a selectivity study, Khan et al. suggested an ITO-based, APTES-modified sensor that contained electrochemically reduced GO. Positively charged amino groups ( $NH_3^+$ ) within APTES have interacted with the negatively charged carboxyl and hydroxyl groups within GO. This electrostatic interaction has allowed deposit of GO onto ITO/APTES electrode. It was observed that the electronic transport is improved with the modification of the ITO surface with SAM, and the addition of

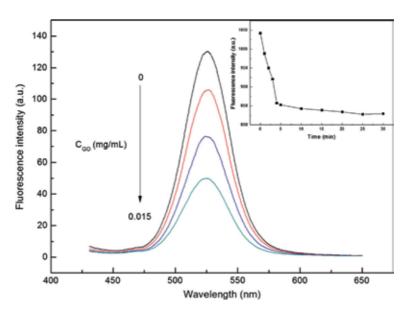
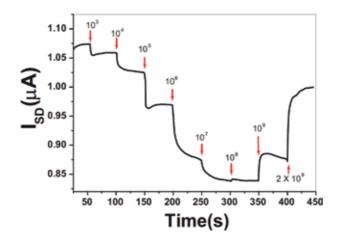


Figure 3.

Fluorescence spectra of sensor at different concentration of tDNA, inset: plot of fluorescence intensity ratio related to concentration with and without GO (figure image reprinted from Ref. [35]).



#### Figure 4.

*Real-time detection* ( $V_{ds} = 0.1 V$ ) of *E. coli* (*CFU/mL*) *in water with the anti-E. coli/AuNPs/Al*<sub>2</sub>O<sub>3</sub>/*rGO biosensor (figure image reprinted from Ref.* [36]).

GO onto the ITO/SAM surface increased the conductivity. Therefore, the resulting device had the property of sensing the oxidation peak of tyramine due to selective behavior of electrode toward electrooxidation. The sensor had also stability and selectivity tests, which it stayed stable for 3 weeks (with the loss of <5% activity) and as selective for human urine, commercial milk, and beer sample. Final conclusions ended up with that the device had sensing capabilities for dopamine and ascorbic acid as well, and it is ready for commercial applications [38].

Feng et al. studied a new type of electrochemical aptasensor for highly sensitive detection of adenosine triphosphate (ATP) and adenosine deaminase (ADA) activity. For modification, 6-mercaptohexanol (MCH) was used. Fabricated sensor could sense different molecules with varying concentrations and had amplified electrochemical signals, due to the facilitation of electron transfer of the functionalized graphene (**Figure 5**) [39]. Yeh et al. demonstrated graphene field-effect transistors (G-FETs) for

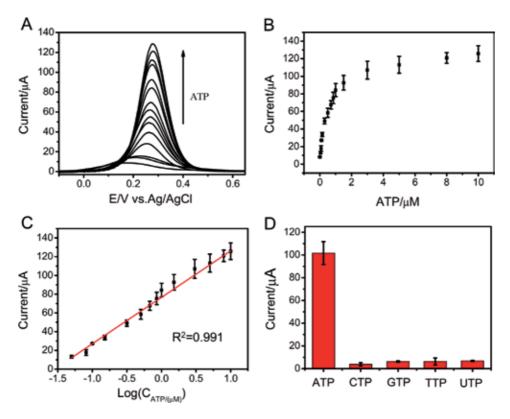


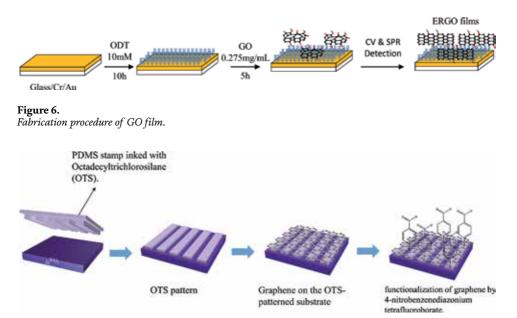
Figure 5.

( $\vec{A}$ ) Differential pulse voltammetry (DPV) responses, (B) current intensities with different ADA active units, (C) a linear relationship between DPV peaks and ADA active units, and (D) specificity of the assay for ADA activity (figure image reprinted from Ref. [39]).

high-mobility applications that were both rigid and flexible. First, graphene was synthesized by CVD method and then transferred onto silicon substrates. The graphenecoated silicone samples were soaked into the solution of hexamethyldisilazane (HMDS) used as SAM-forming molecule for 17 h in a partially covered beaker. The samples were turned into G-FET devices using e-beam lithography and functionalized. As a result, they showed that modification of substrates for graphene electronic devices through patterned SAM arrays of HDMS can enhance the electrical properties of G-FETs by limiting and screening the interactions between graphene and hydrophilic polar groups attached. The HMDS-modified G-FET devices they built could detect cancer biomarker CSPG4 in serum samples at a concentration of as low as 0.01 fM, which is five orders of magnitude more sensitive than a conventional colorimetric assay [40].

Chiu et al. modified a gold electrode using 1-octadecanethiol (ODT) as SAMforming molecule and then immersed it into GO aqueous solution. After the completion of the coating process, the GO film could be turned into electrochemically reduced GO (ERGO) films. The resulting film showed sensing properties, and the process variables can control the residual oxygen functionalities and conductivity in GO sheets in order to provide tools for sensitive immunoassay detection (**Figure 6**) [41]. Bhardwaj et al. prepared a biological sensor that contained covalently bonded GO array with a layer of SAM formed by 4-aminothiophenol on Au electrodes. After functionalizing the surface with lipase enzyme, the sensor could bind with tributyrin and found to be linearly correlated with concentration between certain limits [42].

In a study of binding mechanism, Wang et al. reported that included CVD-grown graphene, hexagonal boron nitride (hBN), and OTS as SAM-forming molecules. They also used a stamp-like micropatterning process in order to give SAM layer a

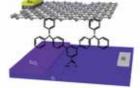


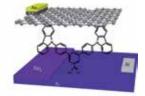
#### Figure 7.

Illustration of reactivity imprint lithography. PDMS stamp inked with OTS-SAM was used to pattern  $SiO_2$  substrate. Graphene is transferred onto the patterned substrate and reacted with 4-nitrobenzenediazonium tetrafluoroborate.









Si/SiO2/CAR/Graphene

Figure 8. The structure of devices.

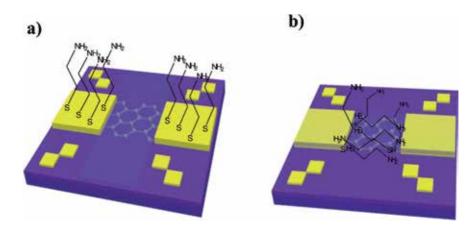
pattern before the coating of the graphene, which affected the binding mechanism of target molecules (**Figure 7**) [43].

Si/SiO\_/TPA/Graphene

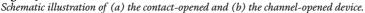
#### 3.2 Device

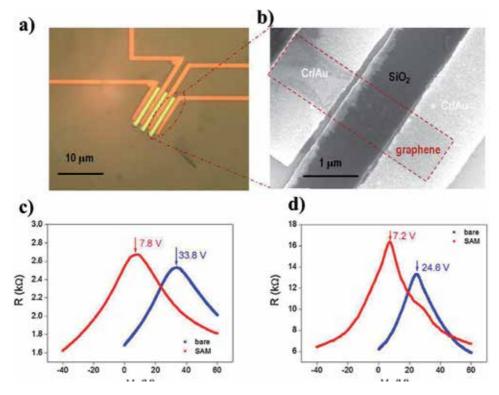
One of the several properties of SAM layers is to alter the working conditions of the bare device. Aydin et al. investigated the properties of a diode that contained graphene, 4"bis(diphenylamino)-1, 1':3"-terphenyl-5' carboxylic acids (TPA), and 4,4-di-9H-carbazol-9-yl-1,1':3'1'-terphenyl-5' carboxylic acid (CAR) aromatic SAMs (**Figure 8**). The decrease in the Schottky barrier height and series resistance by forming a suitable interface between Si and graphene is also noted. The graphene forms  $\pi$ - $\pi$  interaction with aromatic SAMs as well. The theoretical calculations of the study also confirmed that CAR molecules showed better results than TPA, due to the more compatible energy levels [44].

Kim et al. studied the electrical transport characteristics of graphene transistors functionalized with a SAM of cationic molecules. They used 1-aminoethanethiol as SAM molecule onto mechanically exfoliated graphene, and the device is completed after the electrical contact electrodes were fabricated by e-beam lithography (**Figure 9**).



#### Figure 9.





#### Figure 10.

(a) Optical microscopy (b) SEM images of the contact-opened graphene device. The effects of SAM modification on (c) contact-opened and (d) channel-opened graphene transistor (figure image reprinted from Ref. [45]).

Finally they found that work-function engineering with SAMs results in a larger doping effect than the simple adsorption of amine-containing molecules onto the graphene channels (**Figure 10**) [45]. Jung et al. fabricated graphene hybrid film consisted of graphene/APTES/polyethylene terephthalate (PET) for enhancement of the conductivity. Basically, a CVD-grown graphene film is transferred onto an APTES layer on PET substrate. This process enhanced the conductivity of graphene effectively. As a result of the study, the carrier density of graphene was improved from  $9.3 \times 10^{12}$  to  $1.16 \times 10^{13}$ / cm<sup>2</sup> with transmittances of 82% and 86%, depending on the process parameters [46].

Gan et al. studied a new method for controlling H- and J-stacking in selfassembly. They used the property of GO and reduced graphene oxide (RGO) in order to control the self-assembly of perylene (Py). This new method suggested new materials for photosensitive applications in optoelectronics and liquid-junction solar cells [47]. Wieghold et al. demonstrated optoelectronic function in almost monolayer molecular architecture. The active layer consisted of a self-assembled terrylene diimide (TDI) derivative dye that formed a bicomponent supramolecular network with melamine. They found photocurrents of 0.5 nA and open-circuit voltages of 270 mV employing 19 mW/cm<sup>2</sup> irradiation intensities at 710 nm. They also estimated an incident photon to current efficiency of 0.6% at 710 nm with a contact area of  $9.9 \times 10^2$  mm<sup>2</sup>, meaning the opening up to the intriguing possibilities in bottom-up optoelectronic device fabrication with molecular resolution [48].

Kang et al. presented a new efficient and stable RGO doping method by employing two different types of alkylsilane compounds to produce p-type or n-type doping of RGO: (tridecafluoro-1,1,2,2,-tetrahydrooctyl) trichlorosilane (FTS) and APTES, respectively (**Figure 11**). The tunable electrical property of the SAM-functionalized RGO was utilized in developing source/drain (S/D) electrodes in bottom contact OFETs. The OFET device performance was improved significantly upon the use of FTS-RGO S/D electrodes [49]. Park et al. devised a method to optimize the performance of OFETs by controlling the work functions of graphene electrodes by functionalizing the surface of SiO<sub>2</sub> substrates with N,N'-ditridecyl-3,4,9,10-perylenetetracarboxylic

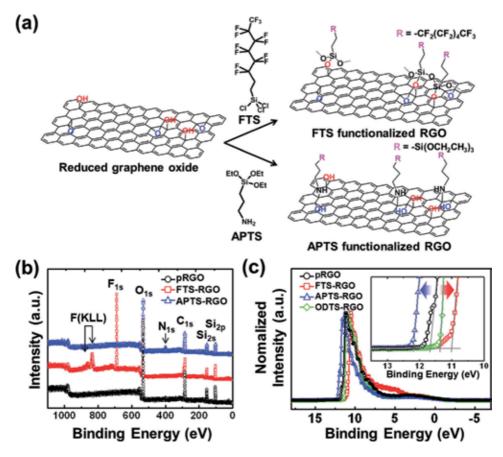
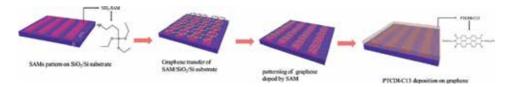


Figure 11.

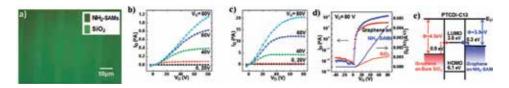
(a) Representation of SAM functionalization of RGO with FTS and APTES, (b) XPS and (c) UPS spectra of SAM-functionalized RGOs. The inset figure in (c) shows the secondary electron emission region (figure image reprinted from Ref. [49]).

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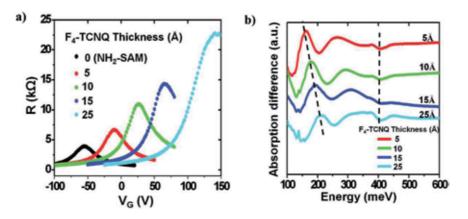
#### Figure 12.

Schematic illustration of PTCDI-C13 FET device process with patterned graphene onto SAM-modified SiO<sub>2</sub> substrate.



#### Figure 13.

(a) Optical microscopy images of samples. I-V measurements of (b) graphene S/D electrode containing n-type PTCDI-C13 FETs on pure SiO<sub>2</sub> and (c) on NH<sub>2</sub>-SAMs, (d) transfer characteristics of electrodes on different SAM-modified SiO<sub>2</sub>. (e) Band diagram structures of samples (figure image reprinted from Ref. [27]).



#### Figure 14.

(a) Current-voltage transfer characteristics of bilayer graphene FETs on a  $NH_2$ -SAM-modified SiO<sub>2</sub>/Si substrates with various thicknesses of the F4-TCNQ layers, (b) absorption spectra of graphene on  $NH_2$ -SAM-modified SiO<sub>2</sub>/Si substrates after applying different thickness of F4-TCNQ layers (figure image reprinted from Ref. [50]).

diimide (PTCDI-C13) as SAM molecules (**Figure 12**). In order to facilitate the electron injection, the work function of graphene is lowered to 3.9 eV in NH<sub>2</sub>-SAM-modified SiO<sub>2</sub>. The method of performance optimization of graphene-based OFETs which utilizes work-function engineering by functionalizing the substrate with SAMs is described and shows ~10 times enhancements in properties regarding the charge carrier mobility and the on-off ratio of OFETs (**Figure 13**) [27]. The same group also used APTES as SAM molecule and 2,3,5,6-tetrafluoro-7,7,8,8-tetracyanoquinodimethane (F4-TCNQ) as doping agent in order to modify the properties of graphene and examined the thickness of the F4-TCNQ related to the electrical properties of bilayer graphene FETs on NH<sub>2</sub>-SAM-modified SiO<sub>2</sub>/Si substrates. A single-gate bilayer graphene FET with high-current on/off current ratios is successfully fabricated, and tunable bandgap was demonstrated. (**Figure 14**) [50].

Gan et al. discovered a weak organic acid, 3,4,9,10-perylene tetracarboxylic acid (PTCA), and utilized to synthesize a supramolecular nanocomplex containing PTCA-graphene that showed wide voltage window and ultrahigh specific capacitance [51].

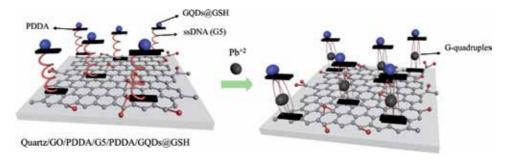


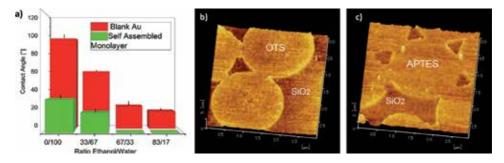
Figure 15.

Schematic diagram of the Pb<sup>2+</sup> adding into quartz/GO/PDDA/G5/PDDA/GQDs@GSH SAMs.

In terms of environmental sensor, Sun et al. developed a sensor for the detection of Pb<sup>2+</sup> ions by constructing quartz/GO/PDDA/G5/PDDA/GQDs@GSH system which included GO, glutathione-functionalized graphene quantum dots (GQDs@GSH), poly(diallydimethylammonium) chloride (PDDA), and G5 (G-rich DNA) (**Figure 15**). The group showed that the detection concentration of the sensor for Pb<sup>2+</sup> ions is as low as 2.2 nM [52].

## 3.3 Interface modifier

Pfaffeneder-Kmen et al. used 4-mercaptophenol as SAM molecule in order to produce homogeneous GO coatings. This process allowed the modification of the surface for contact angle to be low enough in order to achieve complete wetting that causes GO suspension to adhere onto the Au surface (Figure 16a) [53]. Larisika et al. used APTES as SAM-forming layer on SiO<sub>2</sub> substrates in order to enhance the adsorption of GO before the dip-coating process. The resulting sensor had potential as a highperformance and low-voltage operating graphene device [54]. Kamiya et al. investigated protein adsorption to graphene films which modificates the surface of substrates with two different SAMs in aqueous environment, octadecyltrichlorosilane (OTS) and APTES. They employed latex bead projection method for patterning SAMs and observed that the protein adsorption behavior on the graphene flakes is attached to partially SAM-modified SiO<sub>2</sub>/Si substrates in aqueous environment (Figure 16b–c). It was also found that a high-density of agglomerated avidin molecule clusters was formed in the OTS-supported graphene areas, whereas a low-density of large clusters was formed in the SiO<sub>2</sub> and APTES-supported ones. For the high-performance graphene biosensors with small nonspecific adsorption of protein molecules, the suggested technique can control protein adsorption phenomena on graphene surfaces [55].



#### Figure 16.

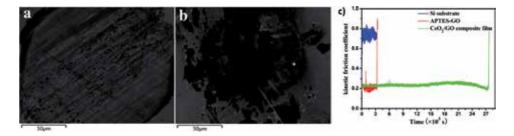
(a) Contact angle vs. water/ethanol ratio with and without mercaptophenol SAM (figure image reprinted from Ref. [53]). AFM images of (b) an OTS-modified and (c) an APTES-modified SiO<sub>2</sub> substrate (figure image reprinted from Ref. [55]).

Ermakova et al. used the zinc complex of 5,10,15,20-tetra(4-pyridyl)-21H,23Hporphine (ZnTPyP) as an organic promoter for the interfacial adsorption of GO. The ZnTPyP/GO/ZnAc<sub>2</sub> bilayer was transferred as whole onto silicon slide by vertical LB method. As conclusion, they informed the stabilizing effect of GO which both anchored the assembled organic layer on the surface. By this result, the final multilayer structures showed large-area uniformity, especially for applications in catalysis, sensors, optoelectronics, etc. [56].

Hui et al. utilized a SAM molecule, 11-mercapto-1-undecanol (11-MU), for the blocking of Au surface, discovering the effect of the electrochemical kinetics of external-sphere redox mediators. For this purpose, metal electrodes were buried in the subsurface of continuous double-layer graphene electrodes. Modified Au tip exhibited a substantial decrease in its electron transfer kinetics [57].

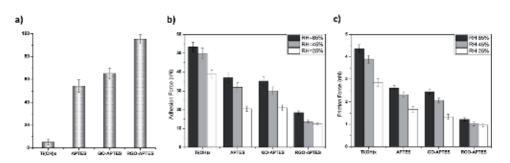
In terms of mechanical modification, Bai et al. used APTES-SAM molecules between Si substrate and ceria/GO composite films in order to alter the mechanical properties of the final film. The friction coefficient was reduced drastically, and the anti-wear lifetime was longer than the GO films (**Figure 17**) [58]. Li et al. investigated and compared three different structures: titanium substrate, APTES-SAM, and GO-APTES nanolayer. The modifications changed the wettability, adhesion, and friction forces of the final structures (**Figure 18**) [59].

Li et al. used APTES as an intermediate coupling agent for chemisorption of RGO sheets on titanium alloy substrate. The results showed that the prepared films contain chemisorptive bonds on the substrate. Tribological results indicated that the prepared APTES-RGO film decreased the friction coefficient while improving antifriction properties of titanium alloy under dry friction (**Figure 19a**) [60]. Ou et al. utilized two different SAM layers including APTES and OTS in order to study lubrication coating properties. First, an APTES-SAM with amine (—NH<sub>2</sub>) outer



#### Figure 17.

SEM images of the wear scars on the steel balls sliding against (a) APTES-GO and (b)  $CeO_2/GO$  composite film. (c) Variation of kinetic friction coefficient with time for different samples under an applied load of 2 N and a constant speed of 10 mm/s (1 Hz) (figure image reprinted from Ref. [58]).

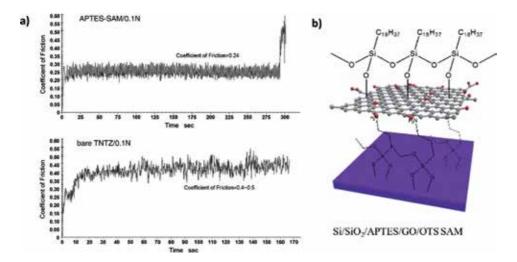


#### Figure 18.

(a) Water contact angle results of Ti substrate and prepared films; (b) adhesion force and (c) friction force with a normal load of 70 nN at ambient conditions at different relative humidity (figure image reprinted from Ref. [59]).

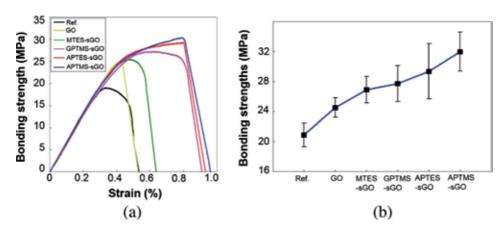
groups was covalently anchored onto the Si wafer. GO sheets were chemo-grafted onto the APTES-SAM surface. Finally, an OTS outer layer was assembled onto the GO surface (**Figure 19b**). In order to increase the hydrophobicity of the film, an outer layer of OTS-SAM is introduced, which reduced the friction and boosted the anti-wear life [61].

Lee et al. used four different SAMs, APTES, (3-aminopropyl)trimethoxysilane (APTMS), (3-glycidyloxypropyl)trimethoxysilane (GPTMS), and triethoxymethylsilane (MTES), in order to modify GO and silane-functionalized GO (sGO). The samples were prepared using epoxy and tested mechanically. The results showed that sGO, especially those containing amine functional groups, can strengthen the interfacial bonding between the carbon fibers and epoxy adhesive (**Figure 20**) [62]. Liu et al. used negatively charged poly(sodium 4-styrenesulfonate) (PSS)-mediated graphene sheets (PSS-GS) and the positively charged polyethyleneimine (PEI) repeatedly layer by layer, in order to obtain a multilayered film. Both the layer thickness and layer numbers were



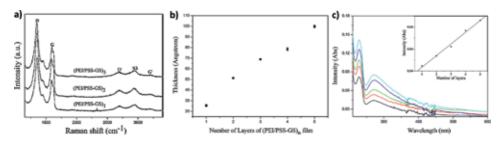
#### Figure 19.

(a) Tribology results of varied materials on TNTZ surface in contact with  $Si_3N_4$  balls under dry friction, (top) APTES-SAMs, 0.1 N applied load; (bottom) bare TNTZ, 0.1 N (figure image reprinted from Ref. [60]). (b) Schematic illustration of APTES-GO-OTS film structure on a Si wafer.



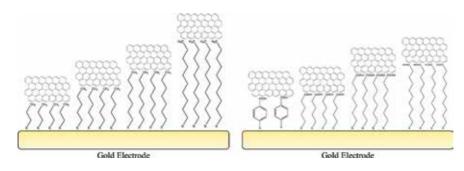
#### Figure 20.

(a) Bonding strength-strain relationships with the addition of GO or the sGOs in the carbon fiber/epoxy composite, (b) average bonding strength of the sample (figure image reprinted from Ref. [62]).



#### Figure 21.

(a) Raman spectra of sample films; (b) graph showing the correlation between the layer numbers of sample and ellipsometric thicknesses; (c) UV-vis spectroscopy results of samples that are assembled on a quartz slide via LBL method. Inset shows the correlation between the absorbance value at 270 nm and the layer number (n) (figure image reprinted from Ref. [63]).



#### Figure 22.

Schematic representation of CRGOs' self-assembly process on to the gold electrode.

changed in order to determine the relation. Their good tribological properties under the given testing conditions suggested that the use as a low-friction and anti-wear coating layer is possible (**Figure 21**) [63].

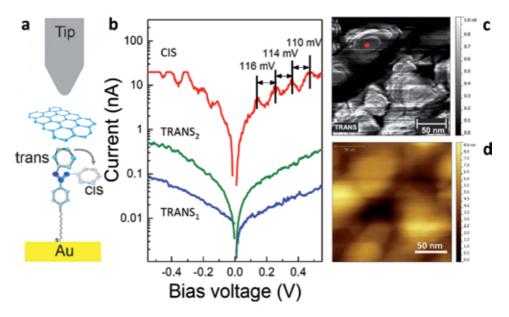
## 3.4 Spacer

Kong et al. reported the influence of chemically reduced graphene oxide sheets (CRGOs) on the electrochemical performance through methyl or carboxylic acid-terminated SAMs (**Figure 22**). Modified gold electrode and immobilization of the CRGOs on a SAM-treated surface showed effective enhancement of the heterogeneous electron transfer (ET) of the SAM due to the tunneling effect. They also reported that the kinetics of electron transfer activity between the CRGOs/SAM/ Au electrode and redox species in the solution was attributed to charge transfer being confined to CRGOs with different interactions with —CH<sub>3</sub> and —COOH terminated thiols, which can influence the electron transfer efficiency and the rate of charge transfer due to different electron transfer pathways [64].

Margapoti et al. reported the experimental studies of resonance oscillation in the current density of a SAM-graphene hybrid system. They used Au surface functionalized with a mixture of 4-(1-mercapto-6-hexyloxy) azobenzene as SAM treatment and 6-mercapto-1-hexanol as spacer molecules. A reversible change in conductivity was observed after transforming the molecular configuration from *trans* to *cis* (**Figure 23**) [65].

## 3.5 Graphene synthesis by SAM

It is also quite possible to synthesize high-quality graphene by using SAM technique as assembling surfaces. Xie et al. reported a simple and environmentally



#### Figure 23.

(a) Measurement configurations and schematic representation of graphene/mSAM/Au hybrid with the azobenzene molecule in trans- and cis-configurations. (b) Typical I-V characteristics in trans-configuration before illumination (blue line) and in cis-configurations, which is controlled via UV-light (red line) and trans-configuration (green line) following white light exposure. (c) Topographical image and (d) current topography with the mSAM in the trans-configuration (figure image reprinted from Ref. [65]).

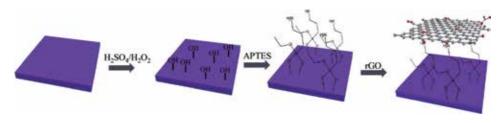
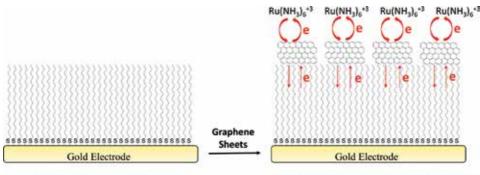


Figure 24. Schematic representation for self-assembly of CRGO monolayer on APTES/Si/SiO<sub>2</sub> surface.

friendly approach for synthesizing a composite of graphene/gold nanoparticles (3DG/Au NPs) in one step. The selected molecule for SAM treatment is 4-amino-thiophenol. They immersed the SAM-coated glass substrate into the GO-HAuCL<sub>4</sub> solution, and the resulting sample showed catalytic reduction properties [66].

Yin et al. successfully bonded monolayer of CRGO nanosheets on Si substrates chemically and investigated their possible applications in Raman scattering (**Figure 24**). The assembly of large-scale and uniform graphene sheet was performed by the electrostatic absorption between the —NH<sub>2</sub> groups of APTES that was coated onto the Si surface and residual groups on RGO. They also concluded that the mildly RGO substrate has the optimum graphene-enhanced Raman scattering (GERS) performance among all the CRGO substrates. The  $\pi$ - $\pi$ stacking and the residual polarized oxygen groups on CRGO surface were mainly responsible for the excellent GERS effect of mildly RGO substrate [67].

Jing et al. reported a facile approach to the direct synthesis of graphene sheets based on the SAM technique. They used a thiophene-terminated silane molecule, triethoxy-(6-(thiophen-3-yloxy)-hexyl)silane (TEHS), as carbon source, and by heating the cross-linked polythiophene SAM up to 1000°C under high vacuum, single-layered or few-layered graphene sheets were successfully prepared on the



C18H37SH on gold electrode

Graphene sheets onto the SAM/Au electrode

#### Figure 25.

Illustration of the fabrication of a graphene-/SAM-modified gold electrode and electron transfer of the mechanism on the graphene-modified electrode.

dielectric silicon oxide substrate [68]. Xie et al. investigated the electrochemical behaviors of graphene sheets attached to a SAM (n-octadecyl mercaptan) on a gold electrode (**Figure 25**). Their studies revealed that the heterogeneous electron transfer blocked by the SAM layer can be restored by graphene sheets, and the graphene-/SAM-modified Au electrode had a smaller interfacial capacitance, as compared with that of a bare one [69].

Three innovative methods are introduced by Nayak et al. for functionalizing bioinert ceramic. These methods include immobilizing rGO onto the surface using appropriate SAMs. Among these methods, activated —COOH groups of rGO and  $-NH_2$  functionalized zirconia shows the most effective immobilization. They also concluded that further immobilization makes it possible to customize the surface properties for the desired application and could be easily performed on graphene-modified ceramics [70].

## 4. Conclusions

Following Geim and Novoselov study about graphene, it has been the most exciting and promising material discovered in the last few years. Due to its outstanding properties, it has enormous potential to develop many applications ranging from nanoelectronics to nanobiotechnology [71, 72]. However, tuning the physical and chemical properties of graphene, which possess high sheet resistance and zero bandgap, is crucial to the realization of graphene-based technologies. Furthermore, adsorption of graphene onto a solid surface is important for the device applications since it provides good charge transfer. Functionalization of the surface with SAMs is useful for controlling the electronic properties of the graphene layer and improving adsorption, paving the way to develop commercial applications.

In recent years, the interaction between SAMs with different chemical properties and graphene has been investigated by many research groups. For instance, SAMs with thiol group is most widely studied for electronic applications due to having delocalized  $\pi$ -electrons. These SAMs can also modify electrodes for electrochemical sensor applications. For example, SAM-decorated Au probes can electrostatically adsorb graphene derivatives, both functionalizing the sensor and improving the sensing ability. These researches demonstrate that SAMs are a utility for improving the performance of experimental devices. It is considered widely that overcoming the difficulties in the production of large-area graphene sheets may allow developing commercial applications. In this chapter, we have demonstrated the functionalization, modification, and synthesis of graphene by SAMs and reviewed different applications. This chapter also demonstrates how to utilize the SAM-modified graphene and that SAM modification can improve the possibility of its usage in many applications.

# **Conflict of interest**

The authors declare no conflict of interest for this publication.

# Author details

Gulsum Ersu<sup>1</sup>, Yenal Gokpek<sup>1</sup>, Mustafa Can<sup>2</sup>, Ceylan Zafer<sup>3</sup> and Serafettin Demic<sup>1\*</sup>

1 Department of Material Science and Engineering, Faculty of Engineering and Architecture, Izmir Katip Celebi University, Izmir, Turkey

2 Department of Engineering Sciences, Faculty of Engineering and Architecture, Izmir Katip Celebi University, Izmir, Turkey

3 Ege University, Institute of Solar Energy, İzmir, Turkey

\*Address all correspondence to: serafettin.demic@ikc.edu.tr

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# **Chapter 8**

# Indenter Shape Dependent Dislocation Actives and Stress Distributions of Single Crystal Nickel during Nanoindentation: A Molecular Dynamics Simulation

Wen-Ping Wu, Yun-Li Li and Zhennan Zhang

# Abstract

The influences of indenter shape on dislocation actives and stress distributions during nanoindentation were studied by using molecular dynamics (MD) simulation. The load-displacement curves, indentation-induced stress fields, and dislocation activities were analyzed by using rectangular, spherical, and Berkovich indenters on single crystal nickel. For the rectangular and spherical indenters, the load-displacement curves have a linear dependence, but the elastic stage produced by the spherical indenter does not last longer than that produced by the rectangular indenter. For a Berkovich indenter, there is almost no linear elastic regime, and an amorphous region appears directly below the indenter tip, which is related to the extremely singular stress field around the indenter tip. In three indenters cases, the prismatic dislocation loops are observed on the {111} planes, and there is a sudden increase in stress near the indenter for the Berkovich indenter. The stress distributions are smooth with no sudden irregularities at low-indentation depths; and the stress increases and a sudden irregularity appears with the increasing indentation depths for the rectangular and spherical indenters. Moreover, the rectangular indenter has the most complex dislocation activities and the spherical indenter is next, while very few dislocations occur in the Berkovich indenter case.

**Keywords:** molecular dynamics simulation, nanoindentation, indenter shape, dislocation, stress distribution

# 1. Introduction

Nanoindentation is one of the most popular experiments to investigate the behavior of materials at the nanometer scale [1, 2]. Nanoindentation-probed materials' properties are usually different from their macroscopic counterparts and present different deformation mechanisms [3]. The atomistic models can give important qualitative information for the understanding of experimentally observed complex phenomena; especially, they have the indisputable advantage of analyzing the main physical process and micro-mechanisms (dislocation

nucleation and evolution) [4-9]. Many studies have adopted atomistic simulations to probe and understand detailed deformation process and the possible impact factors involved in nanoindentation. For example, Chan et al. [10] studied the size effects of indenter nanohardness using atomistic simulations, and found that nanohardness was inversely proportional to the indenter radius. Imran et al. [11] studied the influence from the indenter velocity and size of the indenter using molecular dynamics (MD) simulations in Ni single crystals. Noreyan et al. [12] carried out MD simulations of nanoindentation of  $\beta$ -SiC to investigate the dependence of the critical depth and pressure for the elastic-to-plastic transition on indentation velocity, tip size, and workpiece temperature. Yaghoobi et al. [13] and Kim et al. [14] conducted MD simulations of nanoindentation on nickel single crystal and nickel bicrystal and discussed the effects of boundary conditions and grain boundary, respectively. Fu et al. [15] and Yuan et al. [16] investigated the effects of twin boundary on hardness, elastic modulus, and dislocation movements during nanoindentation by MD simulations. Fang et al. [17] carried out MD to find that both Young's modulus and hardness become smaller as temperature increases, and elastic recovery is smaller at higher temperatures during nanoindentation. Wu et al. [18] performed MD simulation to investigate the effects of the temperature, loading and unloading velocities, holding time, and composition of Ni-Al alloys on the nanoimprinting lithography process. Hansson [19], Tsuru et al. [20], and Remington's et al. [21] studies indicated that the crystallographic orientation strongly influenced the hardness, load for pop-in formation, and mechanisms of plastic deformation using nanoindentation simulated by MD. Zhao et al. [22], Chamani et al. [23], and Chocyk et al. [24] also used MD simulation to study nanoindentation behaviors and microstructure features in metallic multilayers, and the effect of layer thickness on nanoindentation hardness was discussed. Furthermore, few studies also found that the geometry shape of indenter have a strong influence on the dislocation nucleation [25, 26], hardness [26, 27], and Young's modulus [27]. Generally, in the MD simulation of nanoindentation, the material properties response is influenced by some factors including specimen thickness, crystal orientation, grain size and boundaries, atomic potentials, boundary conditions, temperature, shape and size of indenter, and loading/ unloading rate of indentation, etc.

Although the atomic simulation of nanoindentation process and the influence of different factors have been considered comprehensively, most of them mainly consider the dislocation nucleation and deformation mechanisms of specimen, whereas seldom consider the evolutions of and microstructure and stress field of specimen caused by indenter tip geometry. Especially, the internal relationship between the microstructural evolution and the distribution of stress field during nanoindentation has not been analyzed. Since the microstructure features and its evolutions in a localized region are closely related to the stress field in this region, the mechanical properties are strongly dependent on the microstructure evolution and relation with the local stress field, which can be a great help for further understanding of the physical mechanisms during nanoindentation.

The objective of this contribution is to examine how the development of dislocation microstructures, stress distributions, and load-displacement curves are affected by complex stress sites from different shapes of indenters, to determine the relationships between dislocation microstructures and stress distributions during nanoindentation. Moreover, the effect of shapes of indenters on dislocation nucleation, and dislocation movements, stress distribution characteristics during nanoindentation of single crystal nickel are studied in detail. Indenter Shape Dependent Dislocation Actives and Stress Distributions of Single Crystal Nickel... DOI: http://dx.doi.org/10.5772/intechopen.89111

# 2. Simulation procedure and stress calculation

In this work, an open source code LAMMPS [28] is used to carry out MD simulations and investigate the influences of indenter geometry on dislocation movements and stress distributions for a Ni single crystal nanoindentation. Three indenters with different geometries are employed: spherical, rectangular, and Berkovich indenters. The geometries of the models with three different shapes of indenters are shown in **Figure 1**. Both models are in the cubic orientation (i.e., *X*-[100], *Y*-[010], and *Z*-[001]), and the size of box  $(X \times Y \times Z)$  is 200 Å × 200 Å × 50 Å). A free boundary condition was applied on the top surface of z direction, while the last two layers (7.04 Å) at the bottom of z direction were frozen down, resembling a hard substrate. Periodic boundary conditions (PBC) were applied in the x and y directions, and the sizes of x and y directions, which are perpendicular to the z direction (indentation direction) were chosen to be large enough to avoid spurious effects of the PBC. In the present MD simulations, the embedded-atom-method (EAM) potential provided by Mishin et al. [29] was used, which has previously been successfully applied to simulate FCC single crystal nickel [30, 31]. Atoms in the indenter were kept fixed (indenter was assumed to be an infinitely rigid body), at the start of the simulation, all the models with different indenters are relaxed with the conjugate gradient method to reach a minimum energy state, and then the indenters are inserted into the free top surface of z direction at an average indentation speed of v = 0.25 m/s to a maximum penetration of 15 Å by using a displacement control, and this maximum depth is 30% of the specimen in z direction. When the indenter reaches the maximum depth, the indenter returns to the original position by unloading, hence the indentation process is completed. In addition, to reduce temporal local stress fluctuations, the systems are allowed to relax 4 ps after every increment of the indenters. Meanwhile, considering the time scale limitation of the MD simulation on a nanoindentation procedure, a very low temperature of 1 K is chosen to carry out all nanoindentation simulations, where the indentation rate does not play a significant role as long as it is less than the speed of sound [32]. In the present study, the atomic configurations and their evolutions are analyzed by common neighbor analysis (CNA) proposed by Honeycutt and Andersen [33], because CNA can provide an effective filtering method to classify

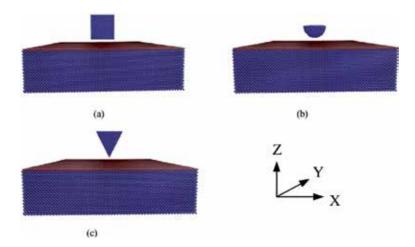


Figure 1.

The geometries of the models with three different shapes of indenters: (a) rectangular indenter, (b) spherical indenter, and (c) Berkovich indenter.

atoms and characterize the local structural environment in crystalline systems. Finally, the atomic configurations and their evolutions are observed by the visualization tools, AtomEye [34], which provides details of the microstructural evolution of nanoindentation.

To investigate the variation and distribution characteristics of atomic stress fields during nanoindentation, the atomistic stress definition is employed in this work. The stress tensor for an atom is calculated as a time averaged value over a number of time steps after relaxation of an indentation step, for atom  $\alpha$  of the atomic stress tensor is defined as [35, 36]:

$$\sigma_{ij}^{\alpha} = -\frac{1}{V^{\alpha}} \left( M^{\alpha} v_i^{\alpha} v_j^{\alpha} + \sum_{\beta} F_i^{\alpha\beta} r_j^{\alpha\beta} \right)$$
(1)

where  $V^{\alpha}$  is the volume of atom  $\alpha$ ,  $M^{\alpha}$  is atomic mass,  $v_i$  and  $v_j$  are the atom velocity components, and  $F_i^{\alpha\beta}$  and  $r_j^{\alpha\beta}$  is the force and distance between atoms  $\alpha$  and  $\beta$ , respectively.

# 3. Simulation results and discussion

#### 3.1 Effect of indenter shapes on load: Displacement curves

In order to compare the load-displacement curves of three different indenters, we gave three indenters penetrating into the same maximum indentation depth of 1.5 nm; the load-displacement curves for three different indenters are shown in **Figure 2**. As the indenters are -1 nm away from the contact surface of the specimen surface at the initial stage, the load-displacement is close to a straight line, and the load P is zero for three different shapes of indenter before the separation is approximately -0.5 nm. When the distance between the indenter and the contact surface of the specimen is about  $-0.5\sim0$  nm, the load values are negative because of the repulsive force of the interaction between atoms, and the repulsive force is larger at the larger contact surface. The rectangular indenter has a larger contact surface than the spherical and Berkovich indenters, the repulsive force is biggest

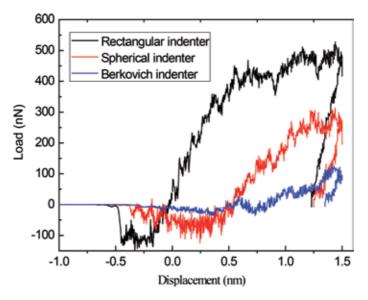


Figure 2. Load-displacement curves for different shape indenters.

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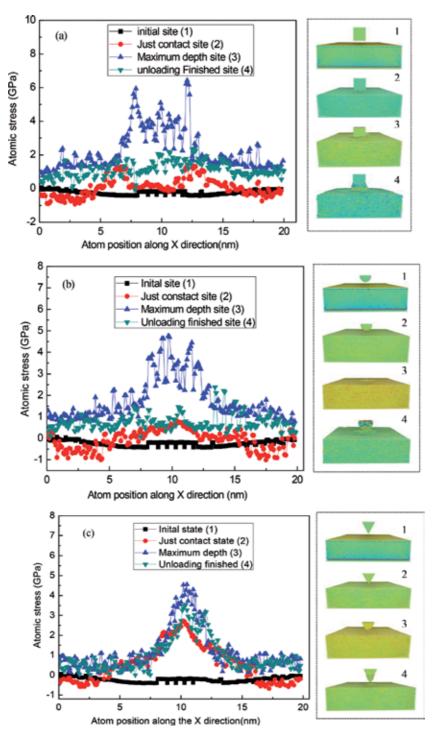
for the rectangular indenter and smallest for the Berkovich indenter (see **Figure 2**). After the indenter contact the surface of the specimen, the load gradually increases with the increase of the penetration depth, the load-displacement curve has a linear dependence, which means that at this stage, the indentation is performed in the linear elastic regime.

For a rectangular indenter, when the load-displacement curve reaches the maximum load, the load keeps fluctuating around a constant value during the further displacement of the indenter, because of the constant cross section of the rectangular indenter; its further penetration into the crystal does not affect significantly the force acting on the indenter. The fluctuations are caused by the relaxation of stresses in the system, such as dislocations migration from the deformed sites. For the spherical indenter, similar to the rectangular indenter case, a quasi-elastic behavior is observed between inflection points; the force acting on the indenter gradually increases with the increase of the penetration depths, but does not last as long in increasing load periods. For a Berkovich indenter, the force acting on the indenter slowly increases with the increase of the penetration depths, the load drop events tend to be small or not noticeable.

Comparison with these three different indenters, the load-displacement curves show different peak loads, elastic-plastic behavior, and load drop events, which are related to a series of transitions of the dislocation structures under the indentation site. To explain this phenomenon, we analyze the local stress distribution and microstructure evolution features of specimen under the indentation site during nanoindentation.

# 3.2 Effect of indenter shapes on stress distributions

Figure 3 shows atomic stress as a function of atom position along the X direction for different shape indenters during nanoindentation. Here, four different nanoindentation sites are chosen to analyze the atomic stress distributions under the action of different indenters. For rectangular indenter, when indenter does not contact specimen surface [initial site (1) in Figure 3a], the atomic stress values are approximately zero along the X direction for three different shape indenters. When the indenter just contacts specimen surface [just contact site (2) in **Figure 3a**], near the contact point, the stress value is positive and relatively high. Whereas the specimen surface at a distance from the contact point, the stress value is negative because the atomic interaction force is repulsive. As the indenter gradually penetrates into the specimen, the stress increases and a sudden irregularity appears. When indenter reaches the maximum indentation depth site (3), the stress value at this site is the highest, and a sudden increase occurs at the indenter site. When the indenter is fully unloaded to the initial site (4) in Figure 3a, comparison with the maximum indentation depth, the stress value decreases, but it is still high, which indicates that there are still dislocations in the unloaded specimens and cannot be restored completely. For spherical and Berkovich indenters, a similar trend is found with initially smooth stress distributions, becoming irregular at larger indentation depths. By comparing the stress distributions for three different shape indenters, we found that different indenters have similar stress distribution characteristics at different indentation depth sites, but the stress values are different. The rectangular indenter have the highest stress value (about 6.8 GPa), the spherical indenter is next (about 5.0 GPa), which also has a high stress value (nearly 5.0 GPa) for the Berkovich indenter at the same maximum indentation depth of 1.5 nm. Although the load is the smallest for the Berkovich indenter from the load-displacement curves in Figure 2, the contact area of the indenter is also the smallest, resulting in the stress value that is still high near the indenter. It is noteworthy that for the Berkovich indenter, except for the



#### Figure 3.

Atomic stress as function of atom position along the X direction at four different nanoindentation sites for different shape indenters: (a) rectangular indenter, (b) spherical indenter, and (c) Berkovich indenter. The 1, 2, 3, and 4 inserted in figure indicate the indenter at four different nanoindentation sites: (1) initial site (indenter does not contact Ni single crystal specimen), (2) just contact site, (3) maximum depth site, and (4) unloading finished site.

high stress (nearly 5.0 GPa) near the indenter, the other parts of the specimen are very low, which is also the reason for the stress concentration of the sharp indenter. From **Figure 3**, we can see that a sudden increase in stress near the indenter for the

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Berkovich indenter, while for the rectangular and spherical indenters, the stress distributions at low indentation depths are smooth with no sudden irregularities, indicating a fully elastic response. At larger indentation depths, the stress distribution gets more and more irregular with locally very high stresses. The stress irregular distribution and the formation of pop-in are closely related to dislocation activities during nanoindentation.

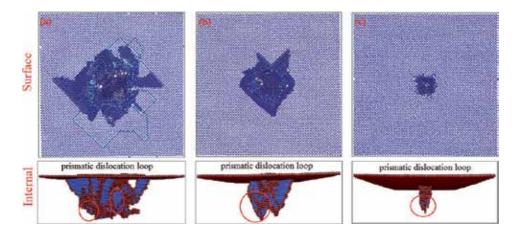
# 3.3 Effect of indenter shapes on surface and internal microstructures of specimen

To understand the microstructure evolution of the specimen during nanoindentation process, the surface and internal microstructure characteristics of specimen for different shape indenters are presented at the maximum indentation depth site and unloading finished site, as shown in **Figures 4** and **5**, respectively.

Due to the maximum stress and irregular distribution occurring at the maximum indentation depth site, and the dislocation activity is also the most complex at this site, From **Figure 4**, at the same maximum indentation depth of 1.5 nm, we can clearly see that the dislocation structure is the most complex for the rectangular indenter case, and the next for the spherical indenter case, whereas there are only few dislocations for the Berkovich indenter cases. Compared to the dislocation activities of rectangular and spherical indenter cases, an amorphous region directly below the indenter tip is observed in the Berkovich indenter case, which we think that the extremely singular stress field around the indenter tip contributes to this uncommon observation.

When the unloading is finished, the indenter returns to its initial site, the stress cannot be completely restored and there are still a lot of dislocations on the surface of the specimen for the rectangular and spherical indenters cases, and these dislocations move slowly toward the surface and boundary of the specimen during unloading, forming the surface microstructure of the specimen as shown in **Figure 5a,b**, while in the Berkovich indenter case, there are almost no dislocations on the surface of specimen at unloading finished site (see **Figure 5c**).

Furthermore, for all three indenters cases at the same maximum indentation depth, the prismatic dislocation loops are mainly observed to nucleate on the {111} planes, as seen the red cycles in **Figures 4** and **5**, this observation in accordance with the predictions of dislocation theory in a face-centered cubic metal. In the rectangular indenter case, dislocation activities are found to be complex; a



#### Figure 4.

The surface and internal microstructure features of specimens at maximum depth site for different shape indenters: (a) rectangular indenter, (b) spherical indenter, and (c) Berkovich indenter.

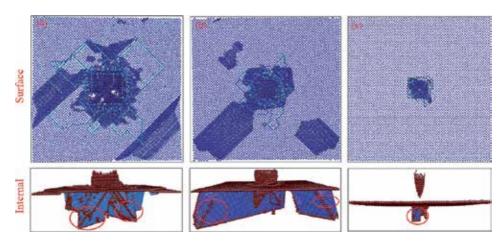


Figure 5.

The surface and internal microstructure features of specimen at unloading finished site for different shape indenters: (a) rectangular indenter, (b) spherical indenter, and (c) Berkovich indenter.

prismatic loop originating inside the specimen is observed and glided upward to the indenting surface. In the spherical indenter case, dislocation activities are still relatively complex, a prismatic dislocation loop originating from the surface of specimen is observed and glided downward to the boundary of specimen. In the Berkovich indenter case, dislocation activities are relatively scarce and the defect structure does not change significantly.

# 4. Conclusions

MD simulations are performed to investigate the influences of indenter geometry on the dislocation activities and stress distributions during nanoindentation on nickel single crystal. The stress field and dislocation activities induced by the change of indenter shape are analyzed. The major findings are as follows:

- 1. Load-displacement curves show different peak loads, elastic-plastic behavior, and load drop events in all three cases. For the rectangular and spherical indenters, the load-displacement curves have a linear dependence, which means a linear elastic regime in indentation process, but the elastic stage produced by the spherical indenter does not last long than that produced by the rectangular indenter. For a Berkovich indenter, there is almost no linear elastic regime, the load drop events tend to be small or not noticeable.
- 2. For the rectangular and spherical indenters, the stress distributions at low indentation depths are smooth with no sudden irregularities, indicating a fully elastic response. At larger indentation depths, the stress distribution becomes more and more irregular with locally very high stresses. For the Berkovich indenter, a sudden increase in stress near the indenter, and the other parts of the specimen is very low, which is the reason for the stress concentration of the sharp indenter. These irregular stress distributions and the formations of pop-in occurred are closely related to dislocation activities during nanoindentation.
- 3. In all three cases, prismatic dislocation loops are observed to nucleate on the {111} planes, which is in agreement with the predictions of dislocation theory

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in a face-centered cubic metal. The dislocation activities are the most complex for the rectangular indenter case, and the next for the spherical indenter case, whereas very few dislocations and an amorphous region directly below the indenter tip are observed in the Berkovich indenter case, which is related to the extremely singular stress field around the indenter tip. According to these results, we can conclude that the shapes of indenters have different and significant influences on dislocation activities and stress distributions during nanoindentation.

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# **Author details**

Wen-Ping Wu<sup>1,2\*</sup>, Yun-Li Li<sup>1,2</sup> and Zhennan Zhang<sup>1,2</sup>

1 Department of Engineering Mechanics, School of Civil Engineering, Wuhan University, Wuhan, China

2 State Key Laboratory of Water Resources and Hydropower Engineering Science, Wuhan University, Wuhan, China

\*Address all correspondence to: wpwu@whu.edu.cn

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# **Chapter 9**

# G-Jitter Effects on Chaotic Convection in a Rotating Fluid Layer

Palle Kiran

# Abstract

The effect of gravity modulation and rotation on chaotic convection is investigated. A system of differential equation like Lorenz model has been obtained using the Galerkin-truncated Fourier series approximation. The nonlinear nature of the problem, i.e., chaotic convection, is investigated in a rotating fluid layer in the presence of g-jitter. The NDSolve Mathematica 2017 is employed to obtain the numerical solutions of Lorenz system of equations. It is found that there is a proportional relation between Taylor number and the scaled Rayleigh number R in the presence of modulation. This means that chaotic convection can be delayed (for increasing value of R) or advanced with suitable adjustments of Taylor number and amplitude and frequency of gravity modulation. Further, heat transfer results are obtained in terms of finite amplitude. Finally, we conclude that the transition from steady convection to chaos depends on the values of Taylor number and g-jitter parameter.

**Keywords:** g-jitter effect, nonlinear theory, rotation, chaos, truncated Fourier series

# 1. Introduction

The study of chaotic convection is of great interest due to its applications in thermal and mechanical engineering and in many other industry applications. It was introduced by Lorenz [1] to illustrate the study of atmospheric three-space model arising from Rayleigh-Benard convection. Some of the applications are production of crystals, oil reservoir modeling, and catalytic packed bed filtration. He developed a simplified mathematical model for atmospheric convection given below:

$$x' = Pr(y - x), \tag{1}$$

$$y' = x(R - z) - y, \tag{2}$$

$$z' = xy - \beta z. \tag{3}$$

This model is a system of three ordinary differential equations known as the Lorenz equations. These equations are related to the properties of a twodimensional Rayleigh-Benard convection. In particular, the system describes the rate of change of three quantities convection, temperature variation vertically with respect to time. These equations are related to the properties of two-dimensional flow model warmed uniformly from below and cooled from above. In particular, the system describes the rate of change of three quantities of time, x is proportional to the rate of convection, y is the horizontal temperature variation, and z is the vertical temperature variation. The constants Pr, R and  $\beta$  are the system parameters proportional to the Prandtl number, Rayleigh number, and certain physical dimensions of the media. If R < 1 then there is only one equilibrium point at the origin which is represented as no convection point. Further, all orbits converge to the origin, which is a global attractor. When R = 1, then a pitchfork bifurcation occurs, and for  $R_1$ , two additional critical points arise and are known as convection points, and there the system loses its stability. In addition to this model, I would like to add the concept of modulation either to suppress or to enhance nonlinearity. The literature shows that there are different types available; some of them are temperature modulation (Venezian [2]), gravity (Gresho and Sani [3] and Bhadauria and Kiran [4, 5]), rotation (Donnelly [6], Kiran and Bhadauria [7]), and magnetic field modulation (Bhadauria and Kiran [8, 9]). Their studies are mostly on thermal convection either considering fluid or porous medium. Their ultimate idea behind the research is to find external regulation to the system to control instability and measure the heat mass transfer in the system. But what happens when we consider the external configuration to system Eq. (1). The external configurations are like thermal, gravity, rotation, and magnetic field modulation. In this direction, no data are reported so far. With this, I would like to extend the work of Lorenz along with modulation.

The studies on chaos with respect to the different types of parameters like Rayleigh number and Prandtl number are mostly investigated by the following studies. The transition from steady convection to chaos occurs by a subcritical Hopf bifurcation producing a solitary cycle which may be associated with a homoclinic explosion for low Prandtl number is investigated by Vadasz and Olek [10]. The work of Vadasz [11] suggests an explanation for the appearance of this solitary limit cycle via local analytical results. The effect of magnetic field on chaotic convection in fluid layer is investigated by Mahmud and Hasim [12]. They found that transition from chaotic convection to steady convection occurs by a subcritical Hopf bifurcation producing a homoclinic explosion which may limit the cycle as Hartman number increases. For the moderate values of Prandtl number, the route to chaos occurs by a period of doubling sequence of bifurcations given by Vadasz and Olek [13]. Feki [14] proposed a new simple adaptive controller to control chaotic systems. The constructed linear structure of controller may be used for chaos control as well as for chaotic system synchronization. Yau and Chen [15] found that the Lorenz model could be stabilized, even in the existence of system external distraction. For non-Newtonian fluid case, Sheu et al. [16] have shown that stress relaxation tends to accelerate onset chaos. A weak nonlinear solution to the problem is assumed by Vadasz [17], and it can produce an accurate analytical expression for the transition point as long as the condition of validity and consequent accuracy of the latter solution is fulfilled. Narayana et al. [18] investigated heat mass transfer using truncated Fourier series method. They have also discussed chaotic convection under the effect of binary viscoelastic fluids. The studies related to gravity modulation are given by Kiran et al. [19–25]. These studies show that the gravity modulation can be used to control heat and mass transfer in the system in terms of frequency and amplitude of modulation.

The above paragraph demonstrated the earlier work on chaotic convection with different configurations and models to control chaos. Recently Vadasz et al. [26] and Kiran et al. [27] have investigated the effect of vertical vibrations and temperature modulation on chaos in a porous media. Their results show that periodic solutions and chaotic solutions alternate as the value of the scaled Rayleigh number changes in the presence of forced vibrations. The root to chaos is also affected by three types of thermal modulations. G-Jitter Effects on Chaotic Convection in a Rotating Fluid Layer DOI: http://dx.doi.org/10.5772/intechopen.90846

The effect of rotation on chaos is investigated by Gupta et al. [28] without any modulation. They found that rotation has delay in chaos and controls nonlinearity. It is also concluded that there are suitable ranges over Ta and R to reduce chaos in the system. Based on the above studies in this chapter, I would like to investigate the study of chaotic convection in the presence of rotation and gravity modulation.

# 2. Mathematical model

An infinitely extended horizontal rotating fluid layer about its vertical z-axis is considered. The layer is gravity modulated and the lower plate held at temperature  $T_0$  while the upper plate at  $T_0 + \Delta T$ . Here  $\Delta T$  is the temperature difference in the medium. The mathematical equation of the flow model is given by

$$\nabla .q=0, \tag{4}$$

$$\frac{\partial \overline{q}}{\partial t} + 2\Omega * \overline{q} = -\frac{1}{\rho_0} \nabla p + \frac{\rho}{\rho_0} \overline{g} + \nu \Delta^2 \overline{q}, \tag{5}$$

$$\frac{\partial T}{\partial t} + (\overline{q} \cdot \nabla)T = k_T \nabla^2 T, \tag{6}$$

$$\rho = \rho_0 [1 - \alpha_T (T - T_0)].$$
(7)

The thermal boundary conditions are given by

$$T = T_0 + \Delta T$$
 at  $z = 0$  and  $T = T_0$  at  $z = d$ , (8)

where  $\overline{q}$  -> is the velocity of the fluid,  $\Omega$  -> is the vorticity vector, p -> is the fluid pressure,  $\rho$  -> is the density,  $\nu$  -> is the kinematic viscosity,  $K_T$  -> is the thermal diffusivity ratio, and  $\alpha_t$  -> is the thermal expansion coefficient. We consider in our problem the externally imposed gravitational field (given by Gresho and Sani [3]):

$$\vec{g} = g_0 \left[ 1 + \delta_g \sin\left(\omega_g t\right) \right] \vec{k},\tag{9}$$

where  $\delta_g$ ,  $\omega_g$  are the amplitude and frequency of gravity modulation.

# 2.1 Basic state

The basic state of the fluid is quiescent and is given by

$$q_{b} = (0, 0, 0), p = p_{b}(z), T = T_{b}(z).$$
 (10)

Using the basic state Eq. (10) in the Eqs. (4)–(6), we get the following relations

$$\frac{\partial \overline{q}_{b}}{\partial t} + 2\Omega * \overline{q}_{b} = -\frac{1}{\rho_{0}} \nabla p_{b} + \frac{\rho_{b}}{\rho_{0}} \overline{g} + \nu \Delta^{2} \overline{q}_{b}, \qquad (11)$$

$$o = -\frac{1}{\rho_0} \nabla p_b + \frac{\rho_b}{\rho_0} \overline{g},\tag{12}$$

$$\nabla p_b = \rho_b \overline{g},\tag{13}$$

$$\frac{\partial p_b}{\partial z} = \rho_b \overline{g},\tag{14}$$

and from Eq. (6)

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$$\frac{\partial T_b}{\partial t} + \left(\overline{q}_b \cdot \nabla\right) T = k_T \nabla^2 T_b, \tag{15}$$

$$k_T \nabla^2 T_b = 0, \tag{16}$$

$$T_b = T_0 + \Delta T \left( 1 - \frac{z}{d} \right). \tag{17}$$

#### 2.2 Perturbed state

On the basic state, we superpose perturbations in the form

$$q = q_b + q', \rho = \rho_b(z) + \rho', p = p_b(z) + p', T = T_b(z) + T'$$
(18)

where the primes denote perturbed quantities. Now substituting Eq. (18) into Eqs. (4)–(7) and using the basic state solutions, we obtain the equations governing the perturbations in the form

$$\nabla . \overline{q}' = , 0 \tag{19}$$

$$\frac{\partial (T_b + T')}{\partial t} + \left( \left( q_b + q' \right) \Delta \right) (T_b + T') = K_T \nabla^2 (T_b + T'), \tag{20}$$

$$\frac{\partial T'}{\partial t} + (q' \cdot \nabla)(T_b + T') = K_T \nabla^2(T'), \tag{21}$$

$$\frac{\partial T'}{\partial t} + \left(u'\frac{\partial}{\partial x} + w'\frac{\partial}{\partial z}\right)(T_b + T') = K_T \nabla^2(T'), \tag{22}$$

simplifying the above equation, then we get

$$\frac{\partial T'}{\partial t} - \frac{\partial \psi}{\partial x} \frac{\partial T_b}{\partial z} + \frac{\partial (\psi, T')}{\partial (x, z)} = K_T \nabla^2(T').$$
(23)

Similarly we can derive the same for momentum equation of the following form

$$\frac{\partial \overline{q}'}{\partial t} + 2\Omega * \overline{q}' = -\frac{1}{\rho_0} \nabla p' + \frac{\rho'}{\rho_0} \overline{g} + \nu \Delta^2 \overline{q}'.$$
(24)

We consider only two-dimensional disturbances and define the stream functions  $\psi$  and  $\overline{q}$  by

$$(u',w') = \left(-\frac{\partial\psi}{\partial z},\frac{\partial\psi}{\partial x}\right), \overline{g} = (0,0,-g),$$
(25)

which satisfy the continuity Eq. (19). While introducing the stream function  $\psi$  and non-dimensionalizing with the following nondimensional parameters  $(x',y',z') = d(x^*, y^*, z^*)$ ,  $t' = \frac{d^2}{K_T}t^*$ ,  $T' = (\Delta T)T^*$ , and  $p' = \frac{\mu K_T}{d^2}p^*$ , then the resulting Eq. (19) becomes

$$\frac{\partial T'}{\partial t} - \frac{\partial \psi}{\partial x} \frac{\partial T_b}{\partial z} + \frac{\partial (\psi, T')}{\partial (x, z)} = K_T \nabla^2 (T'),$$

after simplifying the above equation, we get

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$$\left(\frac{\partial}{\partial t} - \nabla^2\right)T = \frac{\partial\psi}{\partial x} - \frac{\partial(\psi, T)}{\partial(x, z)}.$$
(26)

Similarly while eliminating the pressure term and using the dimensionless quantities, from the momentum equation (24), we get the following:

$$\left[\left(\frac{1}{Pr}\frac{\partial}{\partial t}-\nabla^2\right)^2\nabla^2+T_a\frac{\partial^2}{\partial z^2}\right]\frac{\partial\psi}{\partial x}=Ra\left(1+\delta_g\sin\left(\omega_g t\right)\right)\frac{\partial^2}{\partial x^2}\left(\frac{1}{Pr}\frac{\partial}{\partial t}-\nabla^2\right)T,\quad(27)$$

where  $\Pr = \frac{\nu}{K_T}$  is the Prandtl number,  $T_a = \frac{4d^4\Omega^2}{\nu^2}$  is the Taylor number, and  $Ra = \frac{a(\Delta T)d^3g_0}{\nu K_T}$  is the Rayleigh number. The assumed boundaries are stress free and isothermal; therefore, the boundary conditions are given by

$$w = \frac{\partial^2 w}{\partial z^2} = T = 0 \quad at \quad z = 0 \quad and \quad z = 1.$$
 (28)

The set of partial differential Eqs. (26) and (27) forms a nonlinear coupled system of equations involving stream function and temperature as a function of two variables in x and z. We solve these equations by using the Galerkin method and using Fourier series representation.

#### 3. Truncated Galerkin expansion

To obtain the solution of nonlinear coupled system of partial differential equations (26) and (27), we represent the stream function and temperature in the form

$$\psi = A_1 \sin\left(ax\right) \sin\left(\pi z\right),\tag{29}$$

$$T = B_1 \cos(ax) \sin(\pi z) + B_2 \sin(2\pi z) \tag{30}$$

The above are the Galerkin expansion of stream function and temperature. Now substituting these equations in Eqs. (26) and (27) and applying the orthogonal conditions to Eqs. (30) and (31) and finally integrating over the domain  $[0,1] \times [0,1]$  yield a set of equations:

$$\frac{\partial B_1}{\partial t}\cos ax\sin \pi z + \frac{\partial B_2}{\partial t}\sin 2\pi z + k^2 B_1\cos ax\sin \pi z + 4B_2\pi^2\sin 2\pi z \qquad (31)$$

$$= A_1 a \cos ax \sin \pi z - A_1 B_1 a \pi \cos \pi z \sin \pi z \tag{32}$$

$$-2A_1B_2a\pi\cos 2\pi z\cos ax\sin \pi z. \tag{33}$$

Now multiply with  $\cos ax \sin \pi z$  on both sides, and apply integration from 0 to 1 with respect to x and 0 to  $\frac{2\pi}{a}$ :

$$\frac{\partial B_1}{\partial t} \int_0^1 \int_0^{\frac{2\pi}{a}} \cos^2 ax \sin^2 \pi z dx dz + \frac{\partial B_2}{\partial t} \int_0^1 \int_0^{\frac{2\pi}{a}} \cos ax \sin \pi z \sin 2\pi z dx dz$$
(34)

$$+k^{2}B_{1}\int_{0}^{1}\int_{0}^{\frac{2\pi}{a}}\cos^{2}ax\sin^{2}\pi zdxdz$$
(35)

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$$+4B_2\pi^2 \int_0^1 \int_0^{\frac{2\pi}{a}} \sin 2\pi z \cos ax \sin \pi z dx dz$$
(36)

$$=A_{1}a \int_{0}^{1} \int_{0}^{\frac{2\pi}{a}} \cos^{2}ax \sin^{2}\pi z dx dz$$
(37)

$$-A_1 B_1 a \pi \int_0^1 \int_0^{\frac{2\pi}{a}} \cos ax \cos \pi z \sin^2 \pi z dx dz$$
(38)

$$-2A_1B_2a\pi \int_0^1 \int_0^{\frac{2\pi}{a}} \cos 2\pi z \cos^2 ax \sin^2 \pi z dx dz.$$
(39)

$$\frac{\partial B_1}{\partial t}\frac{\pi}{2a} + k^2 B_1 \frac{\pi}{2a} = A_1 a \frac{\pi}{2a} - 2A_1 B_2 a \pi \left(-\frac{\pi}{2a}\right), \tag{40}$$

$$\frac{\partial B_1}{\partial t} = A_1 a + A_1 B_2 a \pi - k^2 B_1. \tag{41}$$

Now we consider  $\tau = k^2 t \Rightarrow t = \frac{\tau}{k^2}$ .

$$\frac{\partial B_1}{\partial \tau} = \frac{A_1 a}{k^2} + \frac{a\pi}{k^2} A_1 B_2 - B_1.$$
(42)

Now let us consider Eq. (30) and multiply with  $sin 2\pi z$  on both sides of the equation and apply integration from 0 to 1 with respect to x and 0 to  $\frac{2\pi}{a}$ :

$$\frac{\partial B_1}{\partial t} \int_0^1 \int_0^{\frac{2\pi}{a}} \cos ax \sin \pi z \sin 2\pi z dx dz + \frac{\partial B_2}{\partial t} \int_0^1 \int_0^{\frac{2\pi}{a}} \sin^2 2\pi z dx dz$$
(43)

$$+k^{2}B_{1}\int_{0}^{1}\int_{0}^{\frac{2\pi}{a}}\cos ax\sin \pi z\sin 2\pi z dxdz$$
 (44)

$$+4B_2\pi^2 \int_0^1 \int_0^{\frac{2\pi}{a}} \sin^2 2\pi z dx dz$$
 (45)

$$= A_1 a \int_0^1 \int_0^{\frac{2\pi}{a}} \cos ax \sin \pi z \sin 2\pi z dx dz$$
 (46)

$$-\int_{0}^{1}\int_{0}^{\frac{2\pi}{a}} -\int_{0}^{1}\int_{0}^{\frac{2\pi}{a}} A_{1}B_{1}a\pi \cos \pi z \sin \pi z \sin 2\pi z dx dz$$
(47)

$$-\int_{0}^{1}\int_{0}^{\frac{2\pi}{a}} 2A_{1}B_{2}a\pi \cos 2\pi z \cos ax \sin \pi z \sin 2\pi z dx dz,$$
 (48)

then by simplifying the above equation, we get

$$\frac{\partial B_2}{\partial \tau} = -\frac{4\pi^2}{k^2} B_2 - \frac{a\pi}{2k^2} A_1 B_1.$$
(49)

Similarly from Eq. (50)

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$$\frac{\partial^2 A_1}{\partial \tau^2} = -2Pr\frac{\partial A_1}{\partial \tau} + \frac{a}{K^6} \left( a^2 Ra \left( 1 + \delta_g \sin \left( \omega_g t \right) \right) - \pi^2 T_a Pr - k^6 Pr \right) A_1 + \frac{\pi a^2 Pr Ra}{k^6} A_1 B_2 + \frac{a Ra Pr (Pr - 1)}{k^4} B_1,$$
(50)

where  $k^2 = \pi^2 + a^2$  is the total wavenumber and  $\tau = k^2 t$  is the rescaled time. Introducing the following dimensionless quantities

$$R = \frac{a^2 R a}{K^6}, T = \frac{\pi^2 T_a}{k^6} \text{ and } \gamma = -\frac{4\pi^2}{k^2}, \sigma = Pr,$$
 (51)

and rescale the amplitudes in the form of

$$X = \frac{\pi a}{k^2 \sqrt{2}} A_1, Y = \frac{\pi R}{\sqrt{2}} B_1$$
 and  $Z = -\pi R B_2.$  (52)

To provide the following set of equations, we consider the following equations  $\gamma = -\frac{4\pi^2}{k^2}, \frac{1}{k^2} = -\frac{\gamma}{4\pi^2}$ 

$$\frac{\partial B_1}{\partial \tau} == \frac{\gamma a}{4\pi^2} A_1 - \frac{\gamma a \pi}{4\pi^2} A_1 B_2 - B_1, \tag{53}$$

$$\frac{\partial}{\partial \tau} \left( \frac{Y\sqrt{2}}{\pi R} \right) = \frac{\gamma a R}{4\pi^2} \left( \frac{Xk^2 \sqrt{2}}{\pi a R} \right) - \frac{\gamma a}{4\pi} \left( \frac{Xk^2 \sqrt{2}}{\pi a} \right) \left( -\frac{z}{\pi R} \right) - \frac{Y\sqrt{2}}{\pi R}, \tag{54}$$

and then simplifying the above equation, we get

$$Y' = RX - XZ - Y, (55)$$

now from the Eq. (50)

$$\frac{\partial B_2}{\partial \tau} = \gamma B_2 - \frac{1}{2} \left( -\frac{\gamma}{4\pi^2} \right) \pi a A_1 B_1, \tag{56}$$

$$\frac{\partial}{\partial \tau} \left( \frac{Z}{\pi R} \right) = \gamma \left( \frac{z}{\pi R} \right) - \frac{1}{2} \left( -\frac{\gamma}{4\pi^2} \right) \pi a \left( \frac{Xk^2 \sqrt{2}}{\pi R} \right) \left( \frac{Y\sqrt{2}}{\pi R} \right), \tag{57}$$

$$Z' = \gamma Z + XY. \tag{58}$$

Similarly from Eq. (28),

$$X' = W, \tag{59}$$

$$W' = -2\sigma w + \sigma \left( R \left( 1 + \delta_g \sin \left( \omega_g t \right) \right) - \sigma (T+1) \right) X - \sigma X Z + \sigma (\sigma - 1) Y, \quad (60)$$

where the symbol (/) denotes the time derivative  $\frac{d()}{d\tau}$ . Eqs. (56), (59), and (61) are like the Lorenz equations (Lorenz (13), sparrow (14)), although with different coefficients. The final nonlinear differential equations are given by

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$$X' = W, \tag{61}$$

$$Y' = RX - XZ - Y, (62)$$

$$Z' = \gamma Z + XY, \tag{63}$$

$$W' = -2\sigma W + \sigma \big( R \big( 1 + \delta_g \sin \big( \omega_g \tau \big) \big) - \sigma (T+1) \big) X - \sigma X Z + \sigma (\sigma - 1) Y.$$
 (64)

### 4. Stability analyses

To understand the stability of the system, we determine the fixed points of the system and will try to find the nature of these fixed points through eigen equation. The nonlinear dynamics of Lorenz-like system (62)–(65) has been analyzed and solved for  $\sigma = 10$ ,  $\gamma = -\frac{8}{3}$  corresponding to convection. The basic properties of the system to obtain the eigen function are described next.

#### 4.1 Dissipation

The system of Eqs. (62)–(65) is dissipative since

$$\nabla V = \frac{\partial X'}{\partial X} + \frac{\partial Y'}{\partial Y} + \frac{\partial Z'}{\partial Z} + \frac{\partial W'}{\partial W} = -(2\sigma + 1 - \gamma) < 0.$$
(65)

If the set of initial solutions is the region of V(0), then after some time t, the endpoints of the trajectories will decrease to a volume:

$$V(t) = V(0) \exp \left[ -(2\sigma + 1 - \gamma)t \right].$$
(66)

The above expression shows that the volume decreases exponentially with time.

#### 4.2 Equilibrium points

System (62)–(65) has the general form, and the equilibrium (fixed or stationary) points are given by:

$$X' = W, \tag{67}$$

$$W = 0. \tag{68}$$

From Eq. (83) we got

$$X = \frac{Y}{R - Z},\tag{69}$$

and similarly we also got the following from Eq. (64):

$$Z = \frac{-Y^2}{\gamma(R-Z)},\tag{70}$$

and similarly we also got the following from Eq. (65) for the momentum case:

$$R = T + 1, \tag{71}$$

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then we get a relation

$$X_{2,3} = \pm \frac{\sqrt{(T+1-R)\gamma}}{\sqrt{T+1}}$$
(72)

the remaining  $Y_{2,3}, Z_{2,3}$  will be accessed. The fixed points of rescaled system for modulated case are  $(X_1, Y_1, Z_1) = (0, 0, 0)$  corresponding to the motionless solution and  $(X_{2,3}, Y_{2,3}, Z_{2,3}) = \left[\pm \sqrt{\frac{Z}{c}}, \pm c \sqrt{\frac{Z}{c}}, \frac{(RI_1-c)}{(R-1)^2}\right]$  corresponding to the convection solution. The critical value of R, where the motionless solution loses their stability and the convection solution takes over, is obtained as  $R_{cr} = \frac{c}{I_1}$ , which corresponds to  $Ra = 4\pi^2 \frac{c}{I_1}$  where  $c = \left(1 + C\frac{\pi^2}{\gamma}\right)$  and  $I_1 = \int_0^1 \sin^2(\pi z) f_2 dz$ . This pair of equilibrium points is stable only if  $R < \sqrt{\frac{Z}{c}}$ ; beyond this condition the other periodic, quasiperiodic, or chaotic solutions take over at  $R > \sqrt{\frac{Z}{c}}$ . The corresponding stability of the fixed points associated with the motionless solution  $(X_1, Y_1, Z_1) = (0, 0, 0)$  is controlled by the zeros of the following characteristic polynomial:

# 5. Stability of equilibrium points

The Jacobian matrix of Eqs. (62)–(65) is as follows:

$$J = DF_{(X,Y,Z,W)} = \begin{bmatrix} 0 & 0 & 0 & 0 \\ R - Z & -1 & -X & 0 \\ Y & X & \gamma & 0 \\ \sigma[R - \sigma(T+1) - Z] & \sigma(\sigma - 1) & -\sigma X & -2\sigma \end{bmatrix}$$

The characteristic values of the above Jacobian matrix, obtained by solving the zeros of the characteristic polynomial, provide the stability conditions. If all the eigenvalues are negative, then the fixed point is stable (or in the case of complex eigenvalues, they have negative real parts) and unstable, when at least one eigenvalue is positive (or in the case of complex eigenvalues, it has positive real part):

$$DF_{(0,0,0,0)} = egin{bmatrix} 0 & 0 & 0 & 0 \ R & -1 & 0 & 0 \ 0 & 0 & \gamma & 0 \ \sigma[R-\sigma(T+1)] & \sigma(\sigma-1) & 0 & -2\sigma \end{bmatrix}$$

The characteristic equation for the above system at origin is given by  $|A - \lambda I| = 0$  which implies the following

$$\gamma = \lambda, \lambda^3 + (2\sigma + 1)\lambda^2 + \left[(2 - R)\sigma + \sigma^2(T + 1)\right]\lambda + \sigma^2(T - R + 1) = 0$$

The first eigenvalue  $\gamma$  is always negative as  $\gamma = \frac{-8}{3}$ , but the other three eigenvalues are given by equation

$$\lambda^{3} + (2\sigma + 1)\lambda^{2} + [(2 - R)\sigma + \sigma^{2}(T + 1)]\lambda + \sigma^{2}(T - R + 1) = 0.$$

The stability of the fixed points corresponding to the convection solution  $(X_{2,3}, Y_{2,3}, Z_{2,3})$  is controlled by the following equation for the eigenvalues  $\lambda_i$ , = 1, 2, 3, 4:

$$\lambda^{4} + \lambda^{3}(2\sigma + 1 - \gamma) + \lambda^{2}(2\sigma - \gamma - 2\gamma\sigma\gamma - \sigma T + \sigma^{2}T - \sigma + \sigma^{2} + X^{2}) + \lambda(X^{2}\sigma(T + 1))$$
(73)

$$-\sigma\gamma + T\sigma\gamma - \sigma^2\gamma T - \sigma^2\gamma) + 2X^2\sigma^2(T+1) = 0,$$
(74)

$$\lambda^4 + \lambda^3 (2\sigma + 1 - \gamma) + \lambda^2 + \left[\frac{-\gamma R}{T+1} + 2\sigma(1-\gamma) + \sigma(\sigma-1)(T+1)\right]\lambda^2$$
(75)

$$+\left[\frac{-2\sigma\gamma R}{T+1}+\sigma\gamma(2-\sigma)(T+1)-R\right]\lambda+2\sigma^2Y(T+1-R)=0,$$
(76)

$$\frac{\sigma \gamma^2 (T+3)(1-\gamma-\sigma-\sigma T)}{(T+1)^2} R^2 - \sigma \gamma \left[ (2\sigma+1-\gamma)\{\gamma(2-\sigma) + \frac{2\sigma(1-\gamma)(T+3)}{T+1} \right] (77)$$

$$+\sigma(T+3)(\sigma-1) - 2\sigma(2\sigma+1-\gamma)\} - 2\sigma\gamma(T+3)(2-\sigma)]R,$$
(78)

$$+\sigma^{2}\gamma(T+1)(2-\sigma)[(2\sigma+1-\gamma)2(1-\gamma)+(1-\sigma)(T+1)-\gamma(T+1)(2-\sigma)]=0$$
(79)

The loss of stability of the convection fixed points for  $\sigma = 10$ ,  $\gamma = -\frac{8}{3}$  using Eq. (80) is evaluated to be  $R_{c2} = 25.75590$  for system parameters T = 0,  $R_{c2}$  for T = 0.1,  $R_{c2} = 25.75590$  for T = 0.2,  $R_{c2} = 29.344020$  for T = 0.45, and  $R_{c2} = 32.775550$  for T = 0.6.

### 5.1 Nusselt number

According to our problem, the horizontally averaged Nusselt number for an oscillatory mode of convection is given by

$$Nu(\tau) = \frac{conduction + convection}{conduction}.$$
(80)

$$=\frac{\left[\frac{a}{2\pi}\int_{0}^{\frac{2\pi}{d_{c}}}\left(\frac{\partial T_{b}}{\partial z}+\frac{\partial T_{2}}{\partial z}\right)dx\right]_{z=0}}{\left[\frac{a_{c}}{2\pi}\int_{0}^{\frac{2\pi}{a_{c}}}\left(\frac{\partial T_{b}}{\partial z}\right)dx\right]_{z=0}}.$$
(81)

$$=1+\frac{\left[\frac{a}{2\pi}\int_{0}^{2\pi}\left(\frac{\partial T_{2}}{\partial x}\right)dx\right]_{z=0}}{\left[\frac{a_{c}}{2\pi}\int_{0}^{2\pi}\left(\frac{\partial T_{b}}{\partial z}\right)dx\right]_{z=0}}.$$
(82)

In the absence of the fluid motions, the Nusselt number is equal to 1. And simplifying the above equation, we will get the expressions for heat transfer coefficient:

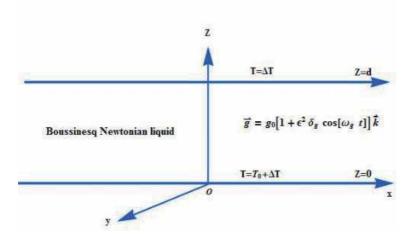
$$Nu = 1 - 2\pi B_2(\tau).$$
 (83)

# 6. Result and discussion

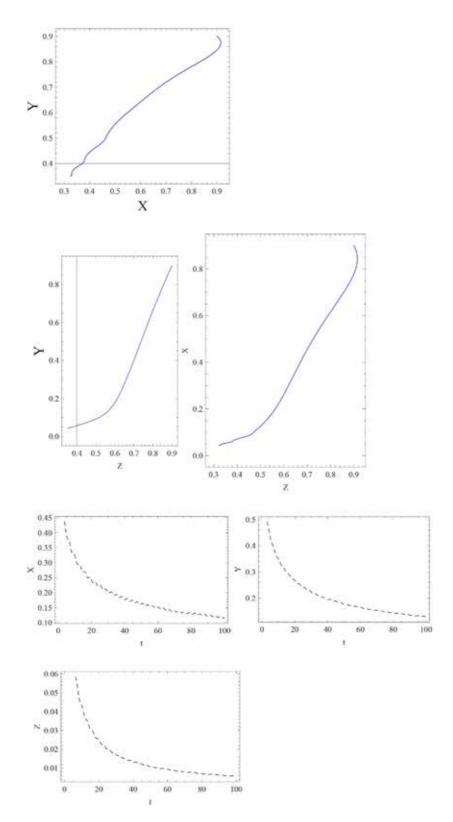
In this section we present some numerical simulation of the system of Eqs. (62)– (65) for the time domain  $0 \le \tau \le 40$ . The computational calculations are obtained by using Mathematica 17, fixing the values  $\sigma = 10$ ,  $\gamma = -8/3$ , and taking in the initial conditions X(0) = Y(0) = 0.8, Z(0) = 0.9. In the case of T = 0, it is found that at  $R_{c^1} = 1$ , obtained from Eq. (80), the motionless solution loses stability, and the convection solution occurs. Also the eigenvalues from Eq. (80) become equal and complex conjugate when R varies from 24.73684209 to 34.90344691 given by Gupta et al. [28]. The evolution of trajectories over a time domain in the state space for increasing the values of scaled Rayleigh number and modulation terms is given in the figures. The projections of trajectories onto Y-X, Z-Y, Z-Y, and W-Z planes are also drawn (Figure 1). In Figure 2, we observe that the trajectory moves to the steady convection points on a straight line for a Rayleigh number (R = 1:1) just above motionless solutions. It is clear from Figure 3a that the trajectories of the solutions approach the fixed points at R = 12, which means the motionless solution is moving around the fixed points. As the value of R changes around R = 25.75590, there is a sudden change and transition to chaotic solution (in **Figure 3b**).

In the case of gravity modulation in **Figure 4**, just keeping the values  $\delta_g = 0.05$ ,  $\omega_g = 10$  in connection with **Figure 3**, the motionless solution loses stability, and convection solution takes over. Even at the subcritical value of R = 25.75590, transition to chaotic behavior solution occurs, but one can develop fully chaotic nature with suitably adjusting the modulation parameter values  $\delta_g = 0.05$ ,  $\omega_g = 10$ .

To see the effect of rotation on chaotic convection for the value of T = 0.45, we get  $R_{c^1} = 1.45$  from Eq. (80), which concludes that the motionless solution loses stability at this stage and the convection solution takes over. The other second and third eigenvalues become equal and complex conjugate at R = 31.44507647. In this state the convection points lose their stability and move onto the chaotic solution. The corresponding projections of trajectories and evolution of trajectories are presented in **Figure 5a** and **b**, planes Y-X, Z-X, Z-Y, and W-Z. At the subcritical value of R = 31.44507647, transition to chaotic behavior solution occurs. Observing **Figure 5b** it is clearly evident that in the presence of modulation  $\sigma = 20$ ,  $\delta_e = 0.2$ ,

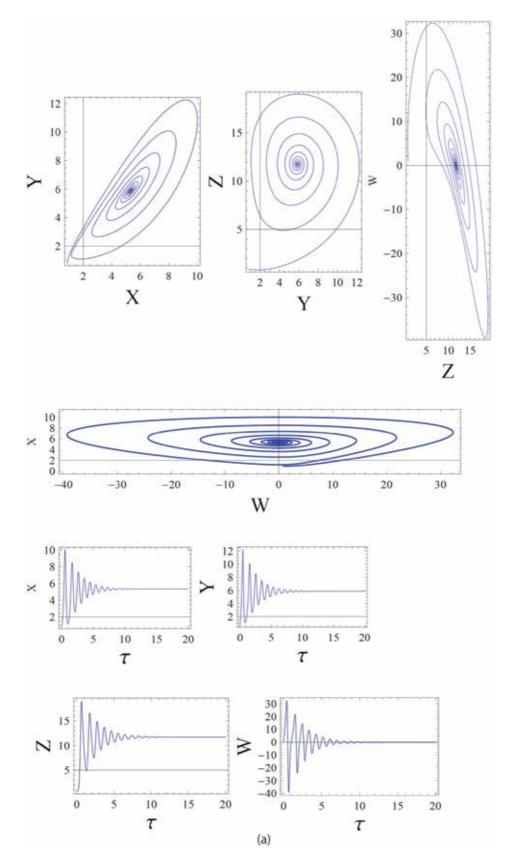


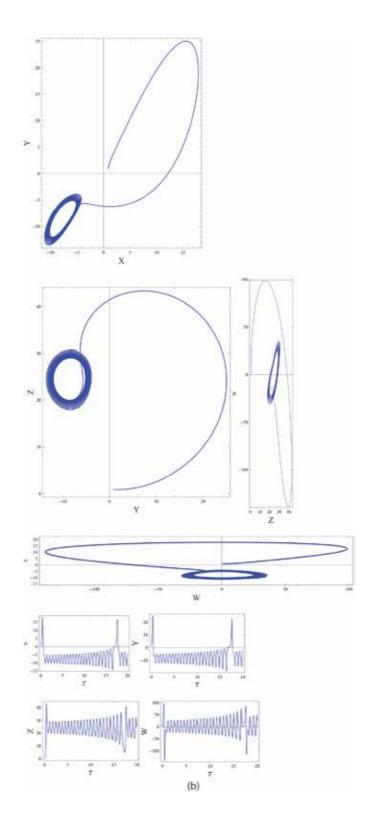
**Figure 1.** *Physical configuration of the problem.* 



#### Figure 2.

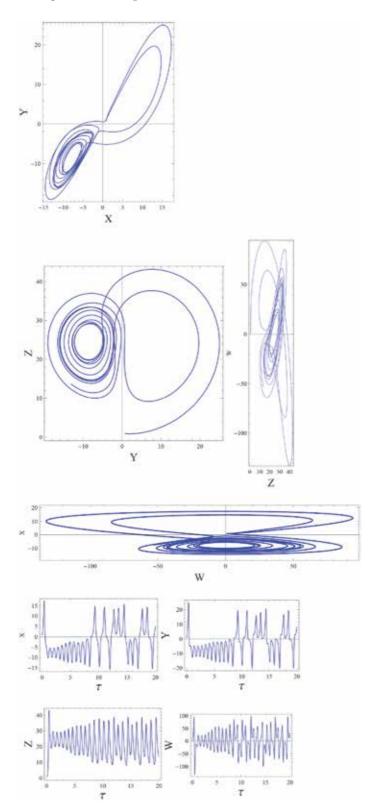
Phase portraits for the evolution of trajectories over time in the state space for increasing the value of rescaled Rayleigh number (R). The graphs represent the projection of the solution data points onto Y-X, Z-X, Z-Y, and W-Z planes for  $\gamma = -8/3$ ;  $\sigma = 10$ , T = 0.1,  $R = 1.1 \omega_g = 0$ ,  $\delta_g = 0.0$ .



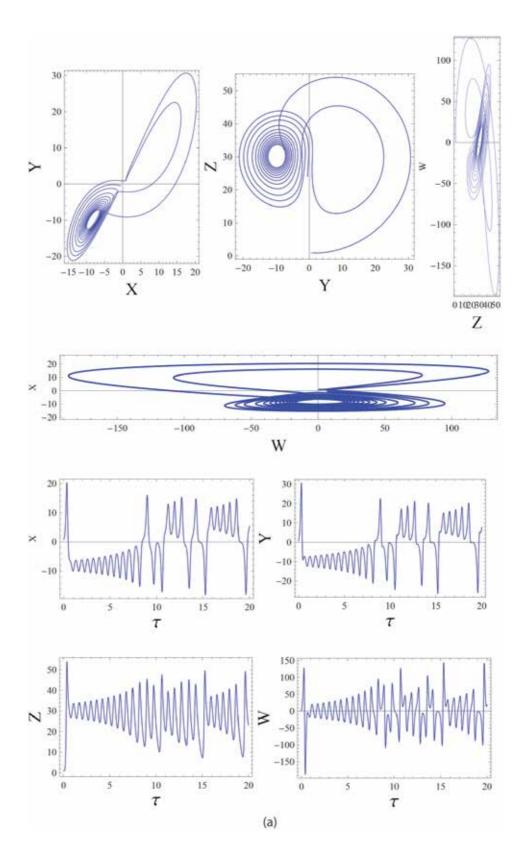


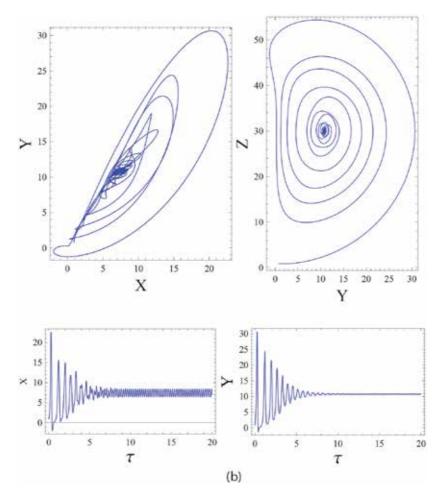
**Figure 3.** (*a*) Phase portraits for the evolution of trajectories over time in the state space Y-X, Z-X, Z-Y, and W-Z planes for  $\gamma = -8/3$ ,  $\sigma = 10$ , T = 0.1, R = 12,  $\omega_g = 2$ ,  $\delta_g = 0.0$ . (*b*) Phase portraits for the evolution of trajectories over time in the state space Y-X, Z-X, Z-Y, and W-Z planes for  $\gamma = -8/3$ ,  $\sigma = 10$ , T = 0.1, R = 25.75590,  $\omega_g = 2$ ,  $\delta_g = 0.0$ .

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**Figure 4.** Phase portraits for the evolution of trajectories over time in the state space modulation. The graphs represent the projection of the solution data points onto Y-X, Z-X, Z-Y, and W-Z planes for  $\gamma = -8/3$ ;  $\sigma = 10$ , T = 0.1, R = 1.1,  $\omega_g = 10$ ,  $\delta_g = 0.05$ .



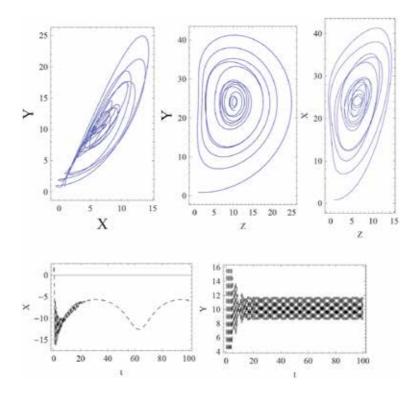


#### Figure 5.

(a) Phase portraits for the evolution of trajectories over time in the state space Y-X, Z-X, Z-Y, and W-Z planes for  $\gamma = -8/3$ ,  $\sigma = 10$ , T = 0.2, R = 31.44507647,  $\omega_g = 2$ ,  $\delta_g = 0.0$ . (b) Phase portraits for the evolution of trajectories over time in the state space Y-X and Z-Y planes for  $\gamma = -8/3$ ,  $\sigma = 20$ , T = 0.2, R = 31.44507647,  $\omega_g = 25$ ,  $\delta_g = 0.2$ .

 $\omega_g = 20$ , the trajectories are manifolds around the fixed points. Which are the interesting results to see that the system is unstable mode with rotation and buoyancy. But with gravity modulation, the system becomes stable mode.

For the value of T = 0.6, we obtain the motionless solution (where the system loss stability) given in **Figure 5b**. The values of the second and third eigenvalues become equal and complex conjugate when the value of R = 24.73684209; at this point the convection points lose their stability, and chaotic solution must occur. But due to the presence of modulation, the trend is reversed given in **Figure 6**. Observing that in the presence of modulation  $\delta_g = 0.1$ ,  $\omega_g = 2$ , the system will come to stable mode for large values of R. The effect of frequency of modulation for the values  $\omega_g = 2$  and  $\omega_g = 20$  on chaos is presented in **Figure 7a** and **b**. It is clear that low-frequency-modulated fluid layer is in stable mode and high-frequencymodulated fluid layer in unstable mode. The reader may have look on the studies of [29–33] for the results corresponding to the modulation effect on chaotic convection.



#### Figure 6.

Phase portraits for the evolution of trajectories over time in the state space Y-X and Z-Y planes for  $\gamma = -8/3$ ,  $\sigma = 20, T = 0.6, R = 24.73684209, \omega_g = 10, \delta_g = 0.1$ .

Finally we also derived the heat transfer coefficient  $(Nu(\tau))$  given by Eq. (83) and verified the rate of transfer of heat under the effect of gravity modulation. It is clear from **Figure 8** that heat transfer in the system is high for low-frequency modulation and for  $\delta_g$  values varies from 0.1 to 0.5. The results corresponding to the gravity modulation may be observed with the studies of [19–26].

# 7. Conclusions

In this chapter, we have studied chaotic convection in the presence of rotation and gravity modulation in a rotating fluid layer. It is found that chaotic behavior can be controlled not only by Rayleigh or Taylor numbers but by gravity modulation. The following conclusions are made from the previous analysis:

- 1. The gravity modulation is to delay the chaotic convection.
- 2. Taking the suitable ranges of  $\omega_g$ ,  $\delta_g$ , and *R*, the nonlinearity is controlled.
- 3. The chaos in the system are controlled by gravity modulation either from stable to unstable or unstable to stable depending on the suitable adjustment of the parameter values.
- 4. The results corresponding to g-jitter may be compared with Vadasz et al. [27], Kiran [31] and Bhadauria and Kiran [33].
- 5. It is found that heat transfer is enhanced by amplitude of modulation and reduced by frequency of modulation.

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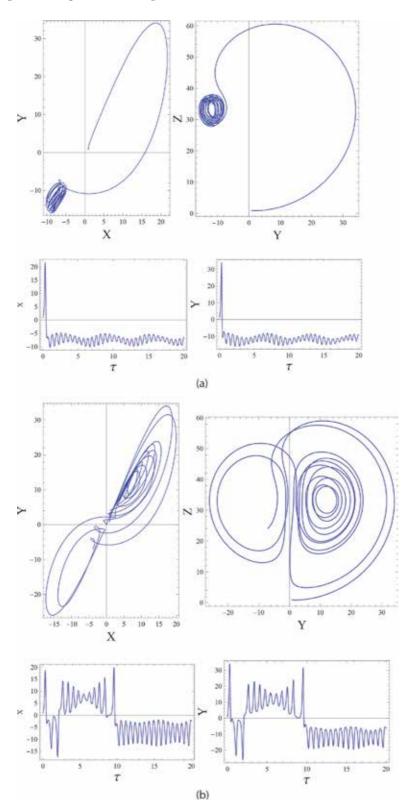
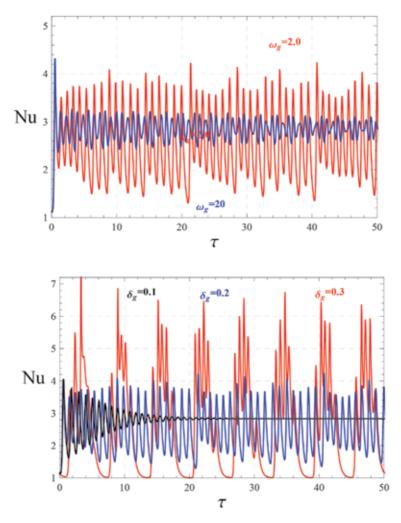


Figure 7.

(a) For  $\gamma = -8/3$ ,  $\sigma = 20$ , T = 0.2, R = 34.90344691,  $\omega_g = 2$ ,  $\delta_g = 0.1$ . (b) Phase portraits for the evolution of trajectories over time in the state space Y-X and Z-Y planes for  $\gamma = -8/3$ ,  $\sigma = 20$ , T = 0.2, R = 34.90344691,  $\omega_g = 20$ ,  $\delta_g = 0.1$ .



**Figure 8.** Effect of  $\omega_g$  and  $\delta_g$  on Nu.

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# **Conflict of interest**

The authors declare no conflict of interest.

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# **Author details**

Palle Kiran Department of Mathematics, Chaitanya Bharathi Institute of Technology, Hyderabad, Telangana, India

\*Address all correspondence to: pallkiran\_maths@cbit.ac.in

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# Chapter 10

# A Compact Source of Terahertz Radiation Based on an Open Corrugated Waveguide

Ljudmila Shchurova and Vladimir Namiot

# Abstract

We show that it is possible to produce terahertz wave generation in an open waveguide, which includes a multilayer dielectric plate. The plate consists of two dielectric layers with a corrugated interface. Near the interface, there is a thin semiconductor layer (quantum well), which is an electron-conducting channel. The generation and amplification of terahertz waves occur due to the efficient energy exchange between electrons, drifting in the quantum well, and the electromagnetic wave of the waveguide. We calculate the inhomogeneous electric fields induced near the corrugated dielectric interface by electric field of fundamental mode in the open waveguide. We formulate hydrodynamic equations and obtain analytical solutions for density waves of electrons interacting with the inhomogeneous electric field of the corrugation. According to numerical estimates, for a structure with a plate of quartz and sapphire layers and silicon-conducting channel, it is possible to generate electromagnetic waves with an output power of 25 mW at a frequency of 1 THz.

**Keywords:** terahertz source, corrugated waveguide, open waveguide, drifting electrons, interaction of electrons with a wave

# 1. Introduction

For past few decades terahertz radiation, which occupies the bandwidth from approximately 0.3–10 THz, have received a great deal of attention. Devices exploiting this waveband are set to become increasingly important in a very diverse range of applications, including medicine and biology [1, 2]. Nevertheless, despite significant progress in the study of terahertz sources in recent years (see, for example, [3, 4] and references therein), this range is mastered much less than its neighboring frequency ranges: the optical range, in which optoelectronic devices are used, and the microwave range, in which electro-vacuum microwave devices are mainly used.

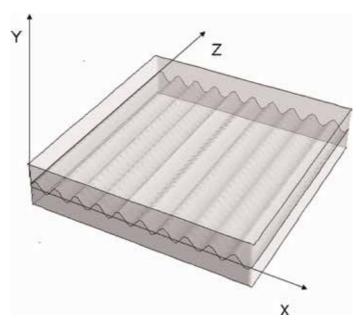
Currently, the key problem lies in the creation of a sufficiently intense, and at the same time compact, terahertz source that can be adapted for a variety of applications.

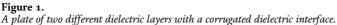
Here we consider a scheme of a compact terahertz generator, which uses some methods and ideas that have been successfully applied in vacuum microwave generators. In the schemes of terahertz generator discussed here, as in microwave generators (such as backward wave and traveling wave tubes), electrons interact with the waveguide wave and transfer their energy to this wave. However, a straight-forward adaptation of microwave generator circuit for terahertz generators causes serious difficulties. It is known that the most efficient energy transfer between electrons and an electromagnetic wave occurs when the electron velocity is close to the phase velocity of the wave. However, since the electron velocity is much less than the speed of the electromagnetic wave in a vacuum (light speed), slow-wave structures are used to reduce the wave velocity. The characteristic dimensions of such slow-wave structures should be comparable with the length of the amplified electromagnetic wave. There is a strong absorption of electromagnetic radiation in slow-wave structures with small characteristic dimensions, which are necessary for slowing down terahertz waves. This significantly affects the generation conditions. It is extremely difficult both to slow the wave and to avoid losses in this frequency range.

Here, we offer another phase-matching method. In the proposed terahertz generator, a speed of the electromagnetic wave, which propagate along a waveguide, is close to the speed of light in vacuum, but electrons are still able to effectively transfer their energy to the wave. Such a situation may occur in corrugated waveguides, in which the corrugated dielectric surface is located in the region of a high electric field of an electromagnetic wave, and electrons move over this corrugated surface. The electromagnetic wave causes the polarization of the dielectric in the zone of the corrugated dielectric interface. The characteristic scale that determines the induced electric field is determined by the corrugation period. Since the corrugated interface has a periodic structure, the induced electric field near the interface can be regarded as the sum of an infinite set of harmonics. By selecting the size of the period, we can ensure that electrons, moving at a small distance above the corrugation, would effectively interact with the first harmonic of the induced electric field and would give its energy to the wave.

Here we consider a scheme of an open corrugated waveguide, which includes a thin multilayer dielectric plate (**Figure 1**). The plate consists of two different dielectric layers with a dielectric interface corrugated periodically in the transverse direction of the waveguide (in the direction perpendicular to the direction of wave propagation). The electric field of the transverse electromagnetic wave (TE wave) induces near the corrugation an electric field that is non-uniform in the transverse direction of the waveguide.

There is a quasi-two-dimensional conducting channel (quantum well) in one of the dielectric layers. In the quantum well located near the corrugation, electrons drift in the transverse direction of the waveguide, and interact with the transverse electric field of the induced surface electromagnetic wave. Phase matching ( $v_e \approx v_f$ ) can be achieved by selecting the applied voltage (which determines the electron drift velocity  $v_e$ ) and the corrugation period L (which defines wave number  $k_c = 2\pi/L$  and the phase velocity of the surface wave  $v_f = \omega/k_c$ , where  $\omega$  is the frequency of the waves). The phase velocity of electromagnetic waves with a frequency of  $\sim 10^{12} \ s^{-1}$  is a value of the order of  $\sim 10^6 - 10^7 \ cm/s$  for the corrugation period of  $L \sim 0.1-1 \ \mu m$  (structures with such parameters are achievable at the present technological level). The drift velocity of electrons in a conducting channel can have a value of the order of  $\sim 10^6 - 10^7 \ cm/s$ . Thus, the corrugation period and the parameters of the electronic system can be selected so as to satisfy the conditions of the most effective interaction of the carriers with the electromagnetic wave. As a result of the interaction, the amplitude of the electric field of the





transverse electromagnetic wave increases, while the amplified electromagnetic wave itself propagates along the waveguide at a speed close to the speed of light in vacuum ( $c > v_f$ ).

We propose a generator circuit of an open waveguide, which includes a thin multilayer dielectric plate. In such waveguide, the field of an electromagnetic wave is focused in a region that includes both the plate itself and some region near the plate. Ohmic losses of electromagnetic waves are only into the dielectric plate, while wave energy is concentrated mainly outside the plate. So, in open waveguides, it is possible to reduce the energy loss of an electromagnetic wave (and, thus, to improve the generation conditions).

In our works [5, 6], a similar synchronization scheme was proposed for a open corrugated waveguide, in which electrons move ballistically in vacuum above a corrugated plate surface and interact with the non-uniform electric field induced near the corrugation. Such electro-vacuum terahertz generators can have an output power of the order of watts, and efficiency up to 80% [5].

However, in such schemes it is necessary to stabilize the electron beam position above the plate, avoiding the bombardment of the plate by electrons. In [5], we proposed a method for stabilizing the electron beam, but this greatly complicated the scheme of the terahertz generator.

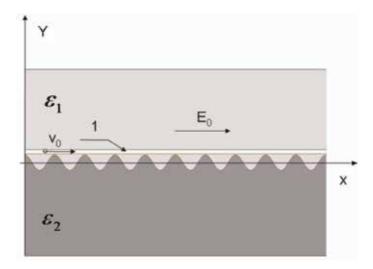
In the scheme considered here, the position of the electrons is already stabilized, since the electrons drift in the quantum well, and the conducting channel can be located close to the corrugated dielectric interface. Such a terahertz generator is compact and, moreover, quite simple to produce. However, the parameters of such a generator are low compared with the parameters of the generator described in [5]. In the terahertz generator scheme considered here, electrons drift in a semiconductor quantum well and experience a large number of collisions. As a result, there are significant losses in Joule heat in such a waveguide. According to our estimates, in such a scheme, it is possible to generate terahertz waves with an output power of tens and hundreds of milliwatts and efficiency of the order of 1%. A brief description of the terahertz generator, based on the interaction of electrons in a quantum well with an electromagnetic wave of a corrugated waveguide, was previously presented in our works [7, 8].

In the second section of this chapter, we present calculations of the induced inhomogeneous electric field of the wave near the corrugated dielectric interface. In the third section, we use a hydrodynamic approach to describe a system of charged carriers, which drift in a quantum well and interact with the inhomogeneous electric field of the wave in the zone of the corrugation. We define the parameters of the system under which the amplification of the electromagnetic field is the most effective. In the fourth section, we give a brief conclusion.

# 2. Wave electric fields in an open waveguide with a plate consisting of two dielectric layers with a corrugated interface

The generator circuit considered here is an open waveguide, which includes a thin dielectric plate consisting of two dielectric layers with a dielectric interface, periodically corrugated in the transverse direction of the waveguide. An electron conducting channel is included in one of the dielectric layers of the plate close to the corrugated dielectric interface (**Figure 2**), and the electrons drift in the conducting channel in the transverse direction of the waveguide (in the direction perpendicular to the direction of wave propagation).

We assume that the conducting channel is sufficiently thin (its thickness is much smaller than the corrugation amplitude). In this case, the problem of calculating of electric fields in the waveguide, and the problem of calculating of interactions of electrons with electromagnetic waves can be solved separately. In this section, we solve the problem of calculating of electric fields without electrons. In the next section, we introduce electrons, which interact with wave electric fields, into the picture.



#### Figure 2.

Plate profile of an open waveguide. The plate consists of two dielectric layers with permittivities  $\varepsilon_1$  (light gray) and  $\varepsilon_2$  (dark gray) having a periodically corrugated dielectric interface. Electrons drift with a mean velocity  $v_0$  in a semiconductor layer 1.  $E_0$  is an electric field of a principal wave of the waveguide (TE-wave).

Electromagnetic waves, including waves in the terahertz frequency range, can propagate in the proposed open waveguide. The waveguide contains a dielectric plate of thickness 2*a* consisting of two dielectric layers with different permittivities  $\varepsilon_1$  and  $\varepsilon_2$  ( $\varepsilon_1 < \varepsilon_2$ ). For sufficiently thin plate,  $a < <c/\omega$ , and for not too large values of  $\varepsilon_1$  and  $\varepsilon_2$  ( $\varepsilon_i < 10$ ) the electromagnetic wave energy is mostly concentrated in the region outside the plate. In the waveguide, an electromagnetic wave propagates with the velocity close to the speed of light.

Let us consider the case of a TE wave, in which there is an antinode of the electric field in the center of the cross section of the plate (where the dielectric plate is) [7] (**Figure 1**).

For a thin plate ( $a < 2\pi c/\omega$ ) with a flat dielectric interface, the electric field of the TE wave is directed along the X-axis, and is given by

$$E_{TE}(r,t) = e_x E_x(y) \cdot \exp(ikz - i\omega t), \qquad (1)$$

The field  $E_x$  can be represented as:

$$E_x \approx E_{in} \cos(\chi y), \text{ if } |y| \le a, \text{ and}$$
  

$$E_x \approx E_{out} \exp(-s|y|), \text{ if } |y| \ge a$$
(2)

Here,  $e_x$  is a unit vector along the x-axis,  $E_{out} \approx E_{in} = E_0$ ,  $\chi$  and s are transverse components of the wave vector in a dielectric and vacuum, respectively. The values  $\chi$  and s are related by  $sa = \frac{1}{\varepsilon} \cdot \chi a \cdot tg \ (\chi a)$  and  $(\chi a)^2 + (sa)^2 = \frac{\omega^2 a^2}{c^2} (\varepsilon - 1)$ , where  $\varepsilon = \sqrt{\varepsilon_1 \cdot \varepsilon_2}$  is the average value of permittivity of the dielectric plate.

However, the electric field  $E_x$  of the TE-wave is uniform for a homogeneous dielectric plate, as well as multi-layer plates with a flat dielectric interface. In this case, the effective interaction between electron and the wave should be absent.

We propose a scheme of a waveguide with a thin multilayered dielectric plate, and the interface between two dielectric layers is a corrugated surface (**Figure 1**). The waveguide with this plate can also serve as a waveguide for the TE wave, and the wave propagation speed along the Z-axis is still being close to the speed of light. But in this case, in the vicinity of corrugated dielectric interface, an additional surface wave is induced in a field of the TE wave. The induced inhomogeneous electric field of the surface wave is comparable with the electric field of the volume electromagnetic wave only in a very narrow region near the dielectric interface. And the inhomogeneous electric field decreases exponentially (in Y-direction) with distance from the interface. The induced electric field is inhomogeneous in the Zdirection of the waveguide, and electrons also drift in X-direction in quasi-twodimensional conductance channel, located in the zone of the corrugation (**Figure 2**). Such electrons can interact with an inhomogeneous field of the wave.

Let the coordinates of the dielectric interface in the waveguide cross section vary according to a periodic law, for example, to the law  $y(x) = R \cos(k_c x)$ . Here  $k_c = 2\pi/L$ , and the corrugation amplitude *R* is significantly smaller than the plate thickness, R < 2a, and the corrugation period *L* is much less than the plate width.

We accept the condition

$$k_c >>k, \tag{3}$$

and, as will be clear from the following, it is worth considering the case  $k_c R \sim 1$ , in which the interaction of an electromagnetic wave with electrons (and the amplification of this wave) will be most effective. We assume that the conducting

channel is thin enough (h < < R, where h is the channel width), so that the electrons in the channel do not deform the electromagnetic fields in the dielectric.

In such waveguide, the electric field of the wave can be represented as  $E(r, t) = E_{TE}(r, t) + F(r, t)$ , where  $E_{TE}(r, t)$  is given by (1) and (2) [7]. The electric field F(r, t) of the wave, which is induced near the corrugation, is comparable with the TE wave field only in a very narrow region (with a width of about R) near the dielectric interface. And F(r, t) is significantly less than  $E_{TE}(r, t)$  outside this region.

Let us proceed to calculation of the electric field F(r, t). The field F(r, t) is caused by influence of the electric field  $E_{TE}(r, t)$  of the TE-wave on the dielectric interface. However, due to the smallness of the corrugation size is compared to the electromagnetic wavelength  $\lambda = 2\pi/\chi$  ( $\lambda >>R$ ,  $\lambda >>L$ ), the TE wave's electric field can be considered as a potential at distances typical for corrugation. Let us denote this field by  $E_0$ , where  $E_0 \cos(\chi y) \approx E_0$ . Since the corrugated dielectric interface is homogeneous along the Z-axis, the problem of calculating F(r, t) is effectively two-dimensional one [7].

The problem can be described by the scalar potential  $\phi^{(i)}$ , which satisfies to the Laplace equation. We denote the potential as  $\phi^{(1)}(x, y)$  inside the dielectric layer with the permittivity  $\varepsilon_1$ , and as  $\phi^{(2)}(x, y)$  inside the layer with the permittivity  $\varepsilon_2$  [7]. The functions  $\phi^{(1)}(x, y)$  and  $\phi^{(2)}(x, y)$  satisfy to the Laplace equation  $\Delta \phi^{(1)}(x, y) = 0$  and  $\Delta \phi^{(2)}(x, y) = 0$  within its domain. Then the boundary conditions take the form

$$\phi^{(1)}(x,y)|_{c} = \phi^{(2)}(x,y)|_{c}$$
(4)

$$\varepsilon_1 \frac{\partial \phi^{(1)}(x, y)}{\partial n} \bigg|_c = \varepsilon_2 \frac{\partial \phi^{(2)}(x, y)}{\partial n} \bigg|_c.$$
(5)

The conditions (4)–(5) represent the continuity of the tangential electric field and normal component of an electric induction vector in a point with coordinates (x, y) on the corrugation dielectric interface [7].

Since the corrugated dielectric interface is described by a periodic function of x, the electrostatic potential functions  $\phi^{(i)}(x, y)$  can be written as the sum of spatial harmonics:

$$\phi^{(i)}(x, y) = \sum_{m=0}^{\infty} B_m^{(i)} \cos(mk_c x) \exp(-mk_c |y|) + \sum_{m=0}^{\infty} A_m^{(i)} \sin(mk_c x) \exp(-mk_c |y|) + E_0 x$$
(6)

In our problem,  $y(x) = R \cos(k_c x)$  is a continuously differentiable function. In this case, expressions (6) represent a complete set of basis functions [9] for potentials  $\phi^{(i)}$  and for electric fields  $E^{(i)} = -\nabla \phi^{(i)}$ . The expansion coefficients  $A_m^{(i)}$  and  $B_m^{(i)}$  of the sum (6) are found from the boundary conditions (4)–(5) at the point  $(x, y) = (x, \cos k_c x)$  [7]. For the boundary described by  $y(x) = R \cos(k_c x)$ , this system is consistent, if the coefficients  $B_m^{(i)} = 0$ , and  $A_m^{(i)} \neq 0$ . Then for the calculation of coefficients  $A_m^{(i)}$  we have limited the harmonic expansion to the seventh term. According to our calculations, when  $\varepsilon_2/\varepsilon_1 \ge 3$ , taking into account the seven expansion terms is sufficient for calculating the coefficients, and the error will not exceed a few percent.

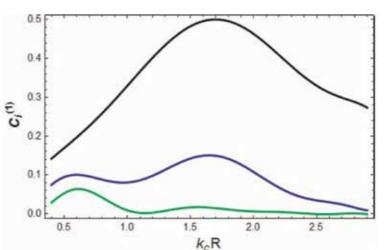
The resulting expression for the x-component  $E_x^{(1)}$  of the electric field  $E^{(1)} = -\nabla \phi^{(1)}$  induced in the upper layer near the corrugation (at  $y > R \cos(k_c x)$ ) can be represented as

$$E_x^{(1)}(x, y) = E_0 \sum_{m=1}^{\infty} C_m^{(1)} e^{imk_c x} e^{-mk_c |y|}$$
(7)

The coefficients  $C_m^{(1)}$ , which characterize the contribution of *m*th harmonic to the electric field induced above the corrugation, depend on the shape and size of corrugation and, moreover, on the parameters  $\varepsilon_1$  and  $\varepsilon_2$ . We carried out numerical analysis on an example of a structure with a plate of quartz ( $\varepsilon_1 = 4.5$ ) and sapphire ( $\varepsilon_2 = 9.3$ ). In the case, when the dielectric boundary is described by  $y(x) = R \quad \cos \quad (k_c x)$ , each of the coefficients  $C_m^{(1)}$  can be represented as a function of  $k_c R$ . **Figure 3** shows the calculated dependences  $C_1^{(1)}(k_c R)$ ,  $C_2^{(1)}(k_c R)$  and  $C_3^{(1)}(k_c R)$ . For  $k_c R \ge 1$ , the value of  $C_1^{(1)}$  is much greater than  $C_2^{(1)}$  and  $C_3^{(1)}$ . The coefficients  $C_m^{(1)}$ for m > 3 are much less than  $C_1^{(1)}$ ,  $C_2^{(1)}$  and  $C_3^{(1)}$ .

**Figure 4** shows the first harmonic of electric field  $E_x^{(1)}/E_0$  at y = R as a function of  $k_c x$  for different values of the corrugation amplitude ( $k_c R = 0.3$ , 1.2, 2). At y = R, the amplitude of  $E_x^{(1)}/E_0$  takes the maximum value for  $k_c R \approx 1.2$ . At the maximum we have  $E_x^{(1)}/E_0=0.15$  and  $C_1^{(1)} \approx 0.5$ . At the corrugation height  $R \approx 1.2 \cdot (k_c)^{-1}$  the amplitude of the first harmonic  $E_x^{(1)}$  of the electric field reaches its maximum value. The first harmonic electric field of the corrugation is smaller for both the higher and lower corrugation amplitude. Indeed, for lower corrugation heights ( $k_c R < < 1$ ), the induced electric field is small because of weak polarization of charges on the dielectric interface with weak corrugation. In the case of higher corrugation heights ( $k_c R > > 1$ ), the charge-induced field largely decays at  $y \approx R$ .

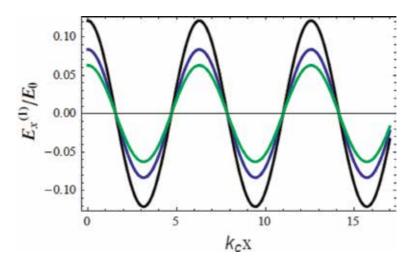
Thus, we have the expression for the x-component of the first harmonic electric field of a wave at y = R (in the region where the conducting channel is)



$$F_x^{(1)} = E_0 C_1^{(1)} \exp\left(-k_c R\right) \exp\left(ik_c x + ikz - i\omega t\right).$$
(8)

#### Figure 3.

Coefficients, characterizing a contribution of the first  $C_1^{(1)}$  (black line), second  $C_2^{(1)}$  (blue line) and third  $C_3^{(1)}$  (green line) harmonics to the induced electric near the corrugation, as a function  $k_c R$ ; R is a corrugation amplitude,  $k_c = 2\pi/L$ , L is a corrugation period.



#### Figure 4.

Calculated values of the first harmonic electric field at y = R as a function of normalized coordinate  $k_c x$  for different values of a corrugation amplitude:  $R = 0.3/k_c$  (blue line),  $R = 1.2/k_c$  (black line) and  $R = 2/k_c$  (green line).

The optimal corrugation amplitude *R* and period *L*, in which the first harmonic amplitude of the non-uniform electric field takes its maximum, are determined by  $k_c R \approx 1.2$  (where  $k_c = 2\pi/L$ ).

### 3. Electron interaction with electromagnetic wave

Let us now consider the problem of interaction of an electromagnetic wave with the electrons. In our study frame electrons drift in a quasi-two-dimensional conducting channel in the transverse direction (X direction) of the waveguide in a quasi-two-dimensional conducting channel (**Figure 2**). The conductive channel is located close to the corrugated dielectric interface, that is, in large inhomogeneous electric field region.

The most effective interaction between the first harmonic of a wave and electrons happens under the condition of synchronism, when phase velocity  $v_f = \omega/k_c$  of the wave is close to the electron drift velocity  $v_0$ . The corrugation period L and applied voltage are selected in such a way as to satisfy the condition  $v_0 \approx v_f$ . (More precisely, the electron drift velocity must slightly exceed the phase velocity of the electromagnetic wave [7].) Due to the change of the electron velocity in the electric field, the electron flow becomes velocity modulated. Electron velocity modulation process is accompanied an electron bunching, and electric field of the corrugation, release their energy to the electromagnetic wave. The slightly amplified electromagnetic wave which, in turn, amplifies the electromagnetic wave even more [5]. Thus, an oscillatory mode appears.

To describe the electrons interacting resonantly with the wave, a self-consistent system of equations is required. The system should take into account the change as electromagnetic wave fields, and electron velocity v(x,t) and density n(x,t). We assume that the electron density is quite low and the conducting channel is very thin, so that the screening of the corrugation electric field by electrons is negligible. TE-wave of the waveguide includes  $H_y$  and  $H_z$  components of the magnetic field. Since the electron collision frequency is much greater than the cyclotron frequency,

the influence of magnetic field on the electron motion is negligible. The form of a solution describing the electric field of the first harmonic wave is described by (8). Since the corrugated dielectric interface is homogeneous along the Z-axis we can take z = 0 without loss of generality. At the initial generation stage, while the linear approximation is correct, the amplitude of the electromagnetic increases with time by the exponential law with an increment  $\gamma$ . Then, taking into account (8), the contribution of the first harmonic to the wave's electric field at y = R can be presented as

$$F_x^{(1)}(x,t) = E_0 \cdot C_1^{(1)}(k_c R) \exp\left(-k_c R
ight) \cdot \, \exp\left(ik_c x - i\omega t
ight) \cdot \, \exp\left(\gamma t
ight)$$

We will consider only the effect of the electric field (directed along the X-axis) on the drifting electron in the quantum well located at  $y \approx R$ .

In the hydrodynamic approximation, functions v(x,t) and n(x,t) can be described by the motion equation

$$\frac{\partial v}{\partial t} + (v \cdot \nabla)v = \frac{e}{m} \left( E_{app} + F^{(1)} \right) - \frac{v}{\tau} - \frac{\nabla p}{m \cdot n}$$
(9)

and the equation of continuity

$$\frac{\partial n}{\partial t} + div(n \ v) = 0. \tag{10}$$

Here, *e* and *m* are the electron charge and the electron effective mass, respectively;  $E_{app}$  is the applied dc electric field,  $F^{(1)}$  is electric field of the wave in a waveguide,  $\tau^{-1}$  is the electron collision frequency. The last term on the right-hand side of Eq. (7) describes the effect of the pressure gradient ( $\nabla p$ ) in a non-uniform gas of carriers.

Let us assume that  $n(x,t) = n_0 + \delta n(x,t)$  and  $v(x,t) = v_0 + \delta v(x,t)$ , where  $n_0$  and  $v_0$  are the unperturbed concentration and velocity of the charge carriers. At  $\tau^{-1} > \omega$ , the left side of Eq. (9) can be neglected, then

$$\delta v = \mu F_1 - D \frac{1}{n_0} \frac{\partial \, \delta n}{\partial x},\tag{11}$$

where  $\mu$  is mobility and D is diffusion coefficient of the charge carrier system in the quantum well.

We solve the system of Eqs. (9) and (11) for the boundary conditions  $\delta n(0,t) = 0$  (that is, at the point of entry into the interaction space, the electron flow is uniform). In the linear approximation over  $\delta n(x,t)$  and  $\delta v(x,t)$ , solutions take the form (in the region outside the boundary x = 0).

$$\delta n \approx \frac{n_0 k_c \mu E_0 C_1^{(1)} \exp\left(-k_c R\right)}{\delta^2 + \left(\gamma + D \cdot k_c^2\right)^2} \left\{-\delta \cos\left(k_c x - \omega t\right) - \left(Dk_c^2 + \gamma\right) \sin\left(k_c x - \omega t\right)\right\} \exp\left(\gamma t\right),\tag{12}$$

$$\delta v \approx \frac{\mu E_0 C_1^{(1)} \exp\left(-k_c R\right)}{\delta^2 + \left(\gamma + D k_c^2\right)} \left\{ \left(D k_c^2 \gamma + \delta^2\right) \cos\left(k_c x - \omega t\right) + D k_c^2 \delta \sin\left(k_c x - \omega t\right) \right\} \exp\left(\gamma t\right).$$
(13)

Here, $\delta = k_c v_0 - \omega$ ,  $\delta < < \omega$ . The expressions (12)–(13) were obtained for condition  $\gamma < < Dk_c^2$ , which is satisfied for typical semiconductors with diffusion coefficient  $D > 1 \text{ cm}^2/\text{s}$ .

Amplification of electromagnetic waves is achieved due to the fact that drifting charge carriers transfer their energy to the radiation field. Represent the current of carriers, which interact resonantly with the wave, as the sum.

 $J(x, t) = J_n(x, t) + J_v(x, t)$ , where  $J_n(x, t) = e \cdot \delta n(x, t) \cdot v_0 \cdot L_z$  is the current of the electron density wave, and  $J_v(x, t) = e \cdot \delta v(x, t) \cdot n_0 \cdot L_z$  is the current due to velocity modulation of the electron stream,  $L_z$  is the length of the plate. (Usually,  $J_v$  is much smaller than  $J_n$ .) The electron current does work on the electromagnetic wave, and gives its energy to the electromagnetic wave. Let P denote the energy transferred by electrons to an electromagnetic wave per unit time and per unit area of the plate, and in addition per unit path of the electron flow averaged over the distance traveled. Using (12) and (13), we obtain:

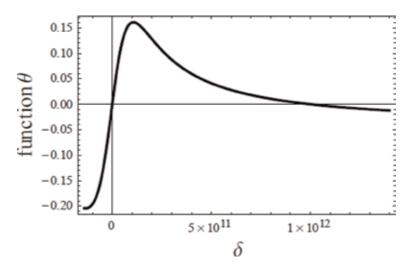
$$P \approx -(1/2) \cdot e \cdot n_0 \cdot \left(C^{(1)} E_0 e^{-k_c R}\right)^2 \mu \cdot \theta, \qquad (14)$$

where the function

$$heta=rac{\delta\cdot\left(k\cdot v_{0}+\delta
ight)}{\delta^{2}+\left(Dk_{c}^{2}
ight)^{2}}$$

characterizes the efficiency of energy transfer from the electron density waves to the electromagnetic wave. From  $\theta$  it follows that if the electron velocity  $v_0$  is strictly equal to  $\omega/k_c$  (this corresponds to  $\delta = 0$ ), the amplification of an electromagnetic wave is absent. Indeed, in the case of  $\delta = 0$ , electromagnetic wave energy, expended for electron acceleration, is equal to the energy that is returned to the wave by decelerating electrons. Thus, there is no amplification of an electromagnetic wave. In order for the wave amplification mode to occur, the electron velocity must be slightly higher than  $\omega/k_c$  ( $\delta > 0$ ).

**Figure 5** shows  $\theta$  as a function of  $\delta$ , where  $\delta = k_c v_0 - \omega$ . The region of values of  $\delta$ , in which the function  $\theta$  takes positive values (and P < 0), corresponds to the amplification of the electromagnetic wave. The electromagnetic wave attenuation occurs for negative values of  $\theta$  (P > 0). The maximum energy transfer from



#### Figure 5.

 $\theta$  as a function of  $\delta = k_c v_o - \omega$ . The function  $\theta$  characterizes the efficiency of energy transfer from electrons to the electromagnetic wave.

electrons to the wave (the maximum of the electromagnetic wave amplification) corresponds to the maximum of the function  $\theta$  which is attained at

$$\delta_g \approx Dk_c^2 \left(1 - \frac{Dk_c}{v_0}\right).$$

We carried out numerical estimates for the structure with *p*-Si conducting channel. The semiconductor p-Si has quite high values of the electrical breakdown field strength  $(3 \cdot 10^5 \text{ V/cm})$ , and high values of the saturation electron velocity  $(1.5 \cdot 10^7 \text{ cm/s})$  in high electric fields and relatively low electron mobility at room temperature [10]. The crystal heterostructures Si  $O_2/Si$  /Si  $O_2$  are mastered well enough by now [11].

For our estimates, we used the values of  $\mu = 10^2 \ cm^2 V^{-1} s^{-1}$  for room temperature mobility and  $v_0 = 5 \cdot 10^6 \ cm/s$  for the drift velocity in the applied field  $E_{app} \approx 5 \cdot 10^4 \ V/cm$ . Then, at the frequency  $\omega = 10^{12} \ s^{-1}$  and the wave number  $k_c = \omega/v_0 = 2 \cdot 10^5 \ cm^{-1}$  (which corresponds to the corrugation period  $L_c = 0.3 \ \mu$ ), we have  $D \cdot k_c^2 \approx 1.2 \cdot 10^{11} s^{-1}$ . The hole collision frequency is  $\tau^{-1} = 10^{14} \ s^{-1}$ , so condition  $\tau^{-1} > \omega$  is satisfied.

For amplification coefficient  $\gamma = 10^8 \ s^{-1} (\gamma < D \cdot k_c^2)$ , we have found the optimum mismatch  $\delta_g \approx 10^{11} \ s^{-1}$ , at which for the value of the energy transmitted from the electrons to the electromagnetic wave have its maximal in linear amplification regime.

The plate width  $L_x = 2\pi/\chi \approx 0.87$  mm is chosen to be equal to half the natural wavelength with the frequency $\omega = 10^{12} \text{ s}^{-1}$ . With the above parameters, a maximum value of the field  $E_{\text{max}}$  reaches value of  $10^4 \text{ V/cm}$  at which the exponential growth of electromagnetic field comes to set end, and the process goes to a quasistationary state. For our estimates, we used  $E_0 \approx 170 \text{ V/cm}$ , for which a linear regime of generation is certainly satisfied.

Negative energy flow of the electron density wave (represented by the expression (14)) is converted into a positive energy flow of the electromagnetic wave.

The change per unit time of the electromagnetic field energy of the open waveguide is determined by the sum  $W_v + W_d$  of the contributions of the field energy outside the plate (in vacuum)

$$W_v \approx rac{1}{4\pi} \cdot S \cdot \gamma \cdot e^{2\gamma t} \cdot E_0^2 rac{c^2}{\omega^2 a} rac{\varepsilon}{(\varepsilon-1)},$$

and the field energy concentrated inside the plate

$$W_d \approx \frac{1}{4\pi} \cdot S \cdot \gamma \cdot e^{2\gamma t} \cdot E_0^2 \cdot \left[ (\varepsilon + 1) \cdot \left( \frac{\cos a \chi \sin a \chi + a \chi}{\chi} \right) \right],$$

where  $S = L_x L_z$  is the area of the plate.

For a structure with a plate of quartz and sapphire with the thickness  $2a = 400 \ \mu$ , the wave vector takes the value of  $s \approx a\omega^2(\varepsilon - 1)/(\varepsilon c^2) = 1.8 \cdot cm^{-1}$  in vacuum and the value of  $\chi \approx (\varepsilon - 1)^{1/2}\omega/c = 72.3 \ cm^{-1}$  in dielectric. In this case, the ratio of the wave energy in the dielectric to the wave energy in vacuum is  $W_d/W_v \approx 10^{-3}$ .

To start the electromagnetic oscillations, the gain  $\gamma$  must be larger than the loss factor

$$\gamma_{loss} = \omega \cdot tg \ \beta \cdot \frac{W_d}{W_v + W_d},$$

which characterizes the attenuation of waves due to dielectric losses. Here,  $tg \beta$  is dielectric loss tangent, which depends on dielectric materials. For the structure of quartz and sapphire ( $tg \beta \sim 10^{-4}$ ) with thickness  $2 \cdot a = 400 \mu$ , and at frequency  $\omega = 10^{12} \text{ s}^{-1}$ , the value of the dielectric loss coefficient is  $\gamma_l \approx 3 \cdot 10^6 \text{ s}^{-1}$ . Thus, the start-up condition  $\gamma > \gamma_{loss}$  is fulfilled with a sufficient margin.

The carrier density  $n_0$ , which can ensure the energy flow of the charge density wave for generation of terahertz radiation, is determined by the law of conservation:  $P = W_v + W_d$ . For the structures with the above parameters, we have  $n_0 \approx 2 \cdot 10^{12} \text{ cm}^{-2}$ . Then the generation power is 25 mW for plate area S = 1 cm<sup>2</sup>.

The formation and amplification of the charge density wave are taking place in the system of the scattering carriers. Let us denote by *Q* the energy that drifting carriers lose in collisions per unit time:

$$Q = en_0\mu \cdot E_{app}^2 \cdot L_x \cdot L_z$$

The efficiency of the generator can be estimated from the ratio of the useful energy *P* to the total energy *P* + *Q* expended by the electrons both for amplification of electromagnetic waves and for collisions: eff = |P|/(|P| + Q).

For the scheme with the above parameters, the generation efficiency is 1%, and the generation power is 25 mW at frequency of  $\omega = 10^{12} \text{ s}^{-1}$ .

Note that one of the possible ways to improve the output power is to increase the area of the plate. Moreover, the output power can be increased (according to expression (14)) by increasing the average electron concentration in the channel, as well as increasing the electron mobility. However, the mobility cannot be very high, since in the framework of the model described above, condition  $\tau^{-1} > \omega$  must be fulfilled (see conditions for Eq. (11) above). But the generation efficiency for the considered circuit does not depend on the plate area, electron concentration, and mobility.

### 4. Conclusion

Currently, there are many approaches to the problem of terahertz generator creation, and there are working devices. However, the problem is still not solved completely. Now efforts are focused not on the development of a single device with record-breaking parameters, but on devices that are suitable for wide application.

Here we consider the concept of a compact terahertz generator, for which neither low temperatures nor strong magnetic fields are required. So, it may have some advantages compared other terahertz generator.

We propose a terahertz generator scheme, which is an open waveguide with a thin dielectric plate, since in such a waveguide the ohmic losses of electromagnetic waves can be small. Indeed, in such waveguides, ohmic losses are present only in the dielectric plate, while the wave energy is concentrated mainly outside the plate.

The device plate consists of two dielectric layers with different values of permittivity and dielectric interface, periodically corrugated in the transverse direction of the waveguide. The transverse TE wave propagating in the waveguide causes polarization of the dielectric in the zone of the corrugation, and this polarization, in turn, induces an alternating electric field near the corrugated dielectric interface. An electron conducting channel is included in one of the dielectric layers of the

plate close to the corrugated dielectric interface. Electrons drift in the conducting channel in the transverse direction of the waveguide (in the direction perpendicular to the direction of wave propagation). The drifting electrons interact with the inhomogeneous electric field which is induced near the dielectric interface by the TE wave of the waveguide. The corrugation period and the parameters of the electronic system are selected in such a way as to ensure the regime of the most effective interaction of drifting electrons with an electromagnetic wave. The generation and amplification of terahertz waves occurs due to the efficient energy exchange between electrons and the electromagnetic wave of the waveguide [7]. It is important that in the considered scheme, the interaction of the electron flow with the electromagnetic wave is quite effective without slowing down the wave propagating in the waveguide.

One of the advantages of the proposed scheme is its low sensitivity to the spread of heterostructure parameters. Before fabrication the corrugated structure, it is possible to define corrugation parameters, under which the synchronism condition will be satisfied.

We have calculated the induced inhomogeneous electric field of the wave near the corrugated dielectric interface, and we have obtained the optimal values of the corrugation amplitude and period at which the amplitude of the non-uniform electric field takes its maximum.

In the hydrodynamic approximation, we have obtained analytical solutions of the equations taking into account the diffusion and drift of the charge carriers in the quantum well. The solutions describe density wave of charge carriers that interact with the first spatial harmonic wave of an inhomogeneous electric field near the corrugation. We have presented numerical estimates for a structure with a plate of quartz and sapphire and the silicon conductance channel. We have found that it is possible to generate electromagnetic waves at the frequency  $\omega = 10^{12} \text{ s}^{-1}$  with the output power of 25 mW and efficiency 1% in waveguides with plate area 1 cm<sup>2</sup> and the average electron concentration in the channel  $2 \cdot 10^{12} \text{ cm}^{-2}$ .

## **Author details**

Ljudmila Shchurova<sup>1\*</sup> and Vladimir Namiot<sup>2</sup>

1 Division of Solid State Physics, Lebedev Physical Institute, Russian Academy of Science, Moscow, Russia

2 Department of Microelectronics, Scobelthsyn Research Institute of Nuclear Physics, Moscow State University, Moscow, Russia

\*Address all correspondence to: ljusia@gmail.com

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## Edited by Jagannathan Thirumalai and Sergey Ivanovich Pokutnyi

This book, *Condensed Matter and Material Physics*, incorporates the work of multiple authors to enhance the theoretical as well as experimental knowledge of materials. The investigation of crystalline solids is a growing need in the electronics industry. Micro and nano transistors require an in-depth understanding of semiconductors of different groups. Amorphous materials, on the other hand, as non-equilibrium materials are widely applied in sensors and other medical and industrial applications. Superconducting magnets, composite materials, lasers, and many more applications are integral parts of our daily lives. Superfluids, liquid crystals, and polymers are undergoing active research throughout the world. Hence profound information on the nature and application of various materials is in demand. This book bestows on the reader a deep knowledge of physics behind the concepts, perspectives, characteristic properties, and prospects. The book was constructed using 10 contributions from experts in diversified fields of condensed matter and material physics and its technology from over 15 research institutes across the globe.

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